

Silicon Nano-Photonics based Arrayed Waveguide Gratings

Shibnath Pathak

Promotors: Prof. Wim Bogaerts & Prof. Dries Van Thourhout

“a wafer of silicon with oxide cladding”

“the art of playing with light in all its forms”

Silicon Nano-Photonics based Arrayed Waveguide Gratings

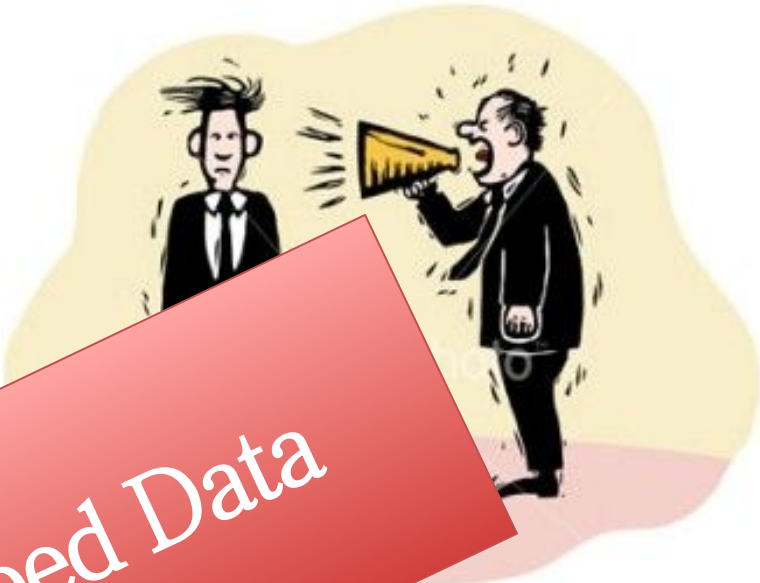
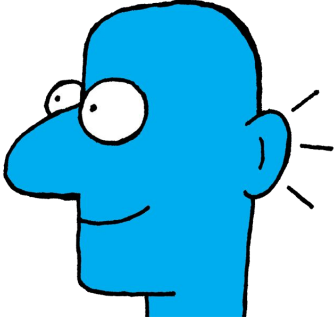
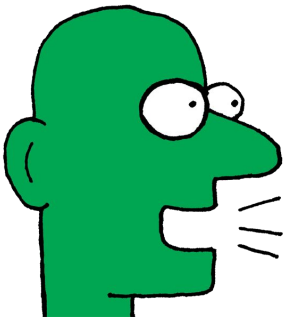
Shibnath Pathak

“Device with nanometer-scale size and accuracy”

“We will talk about rest of the evening”

Promotors: Prof. Wim Bogaerts & Prof. Dries Van Thourhout

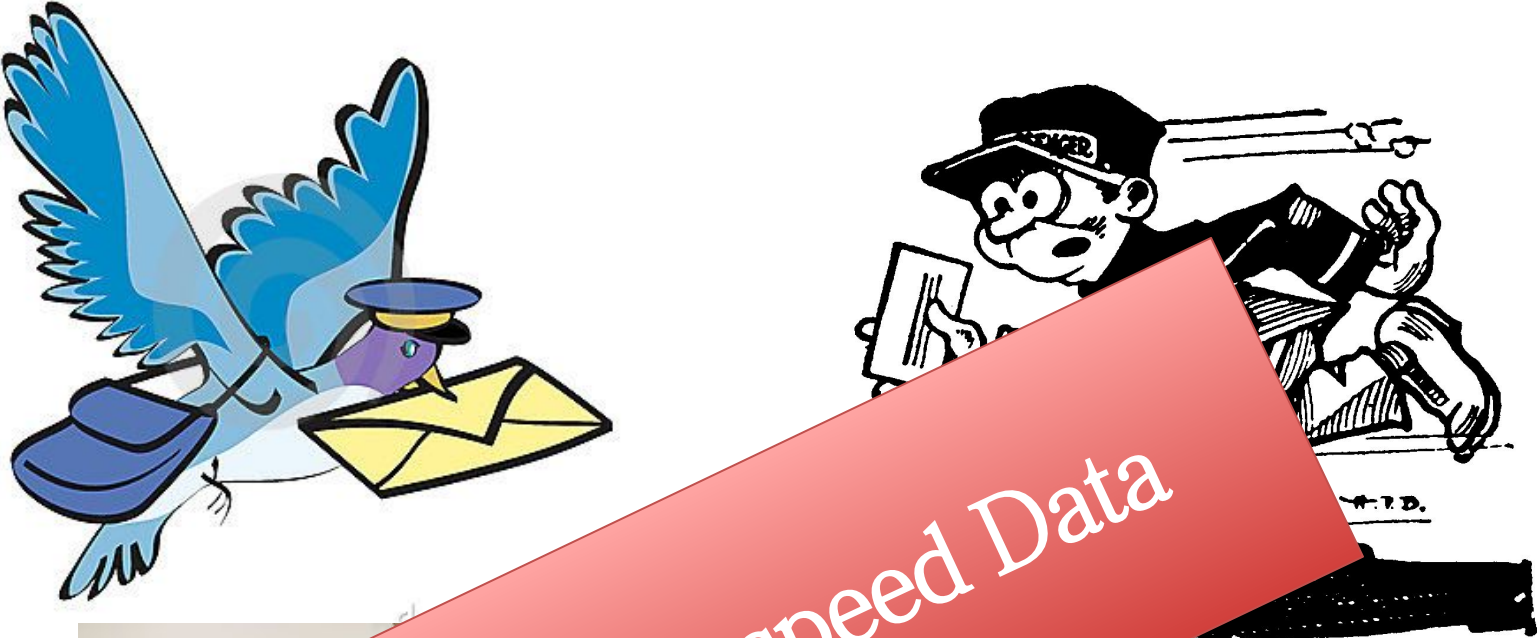
Evolution in Communication



High speed Data



Evolution in Communication



High speed Data



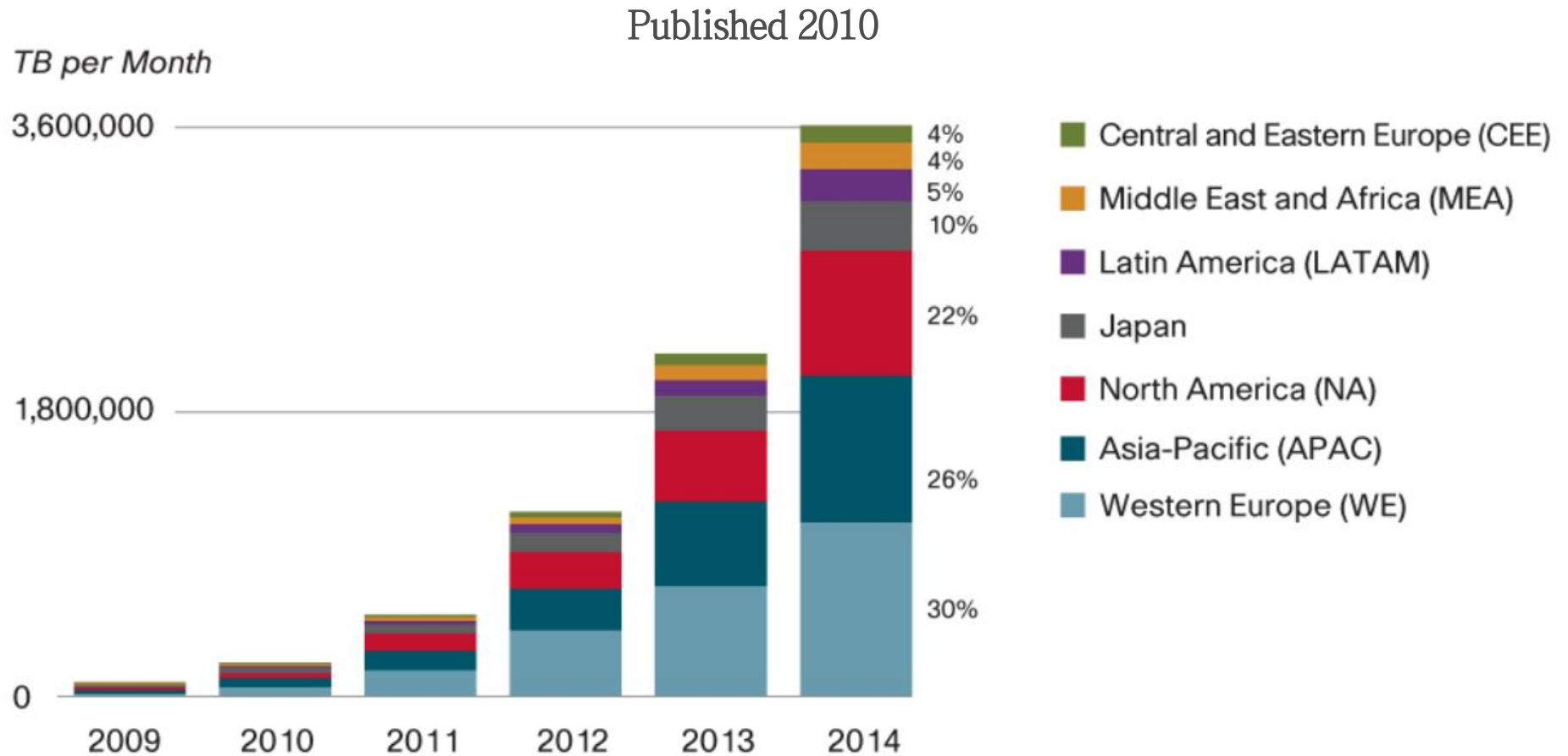
Today's requirements



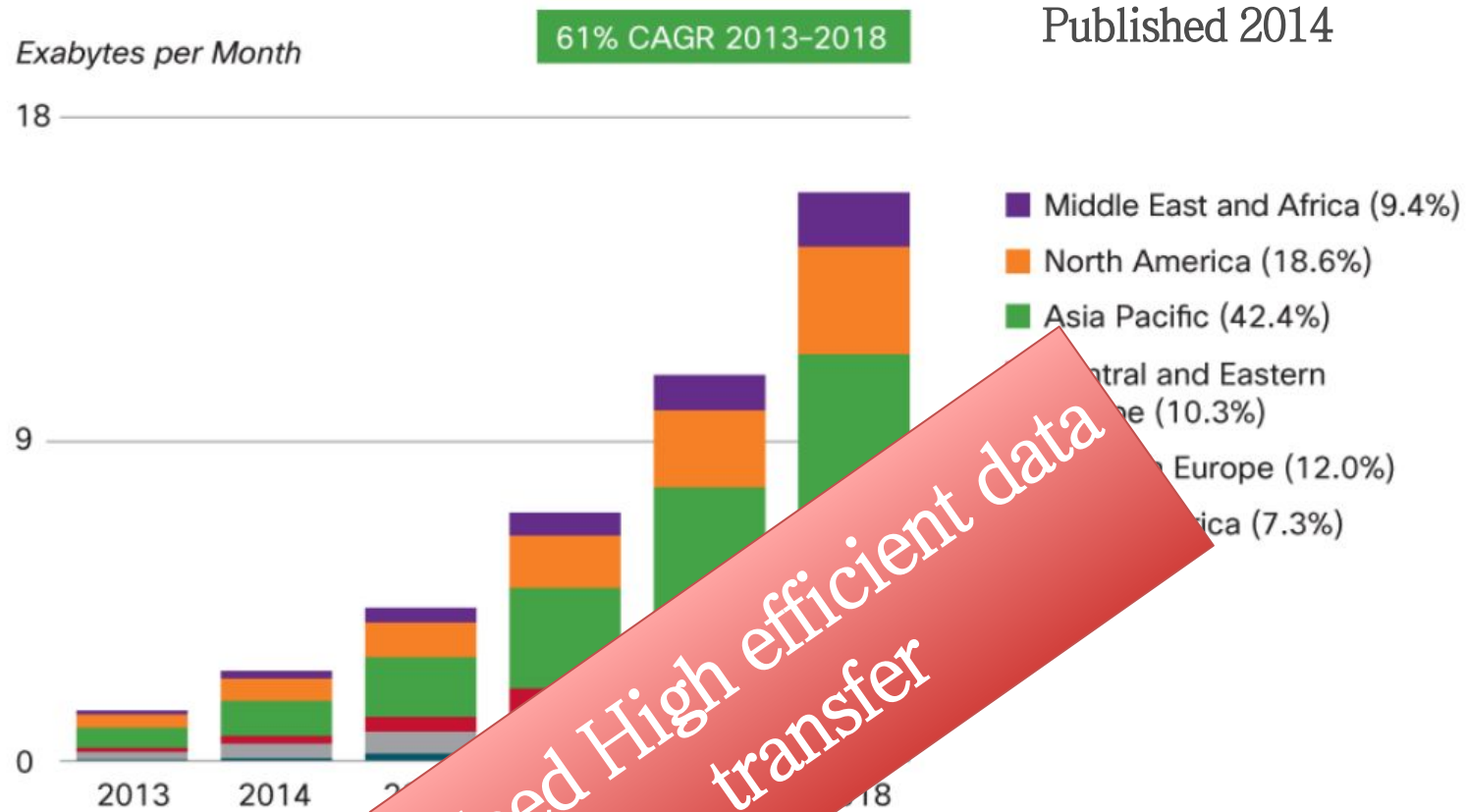
High speed Data



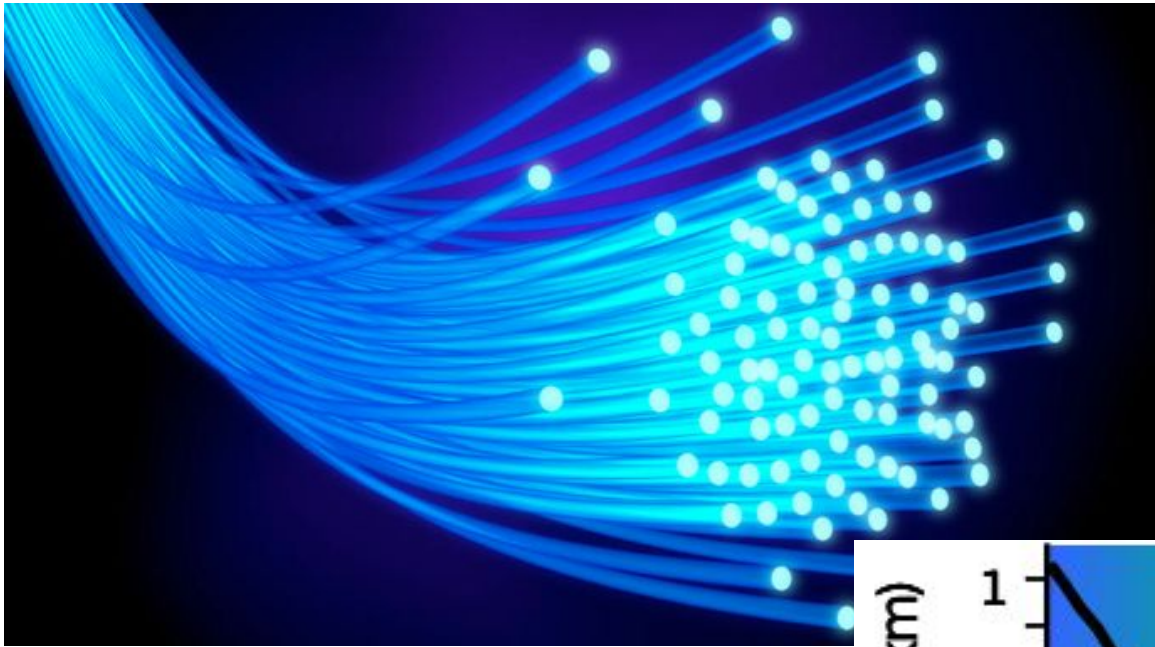
Global Mobile Data Traffic Forecast



Global Mobile Data Traffic Forecast



Optical Fiber

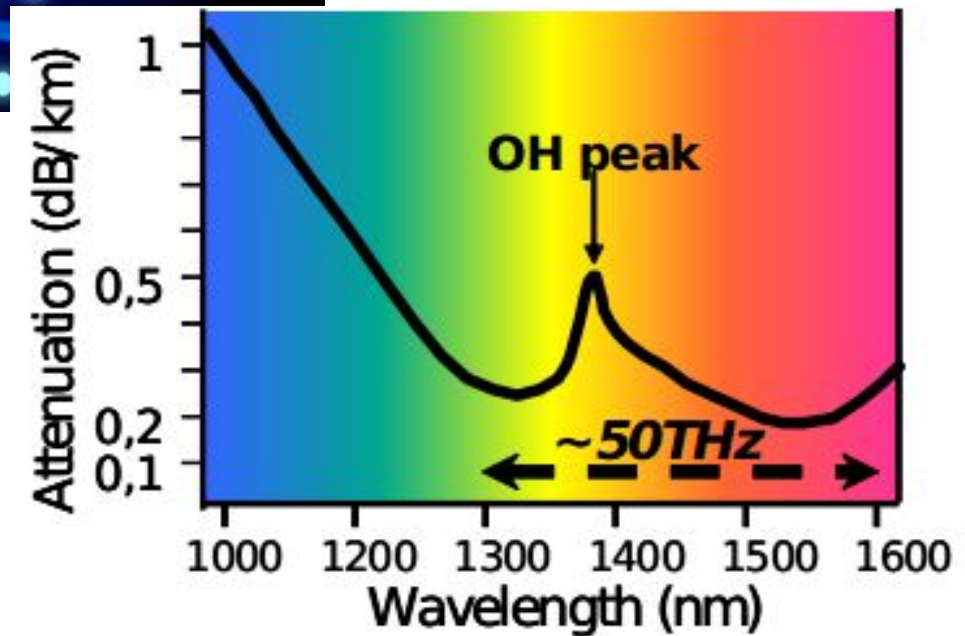


Very low attenuation

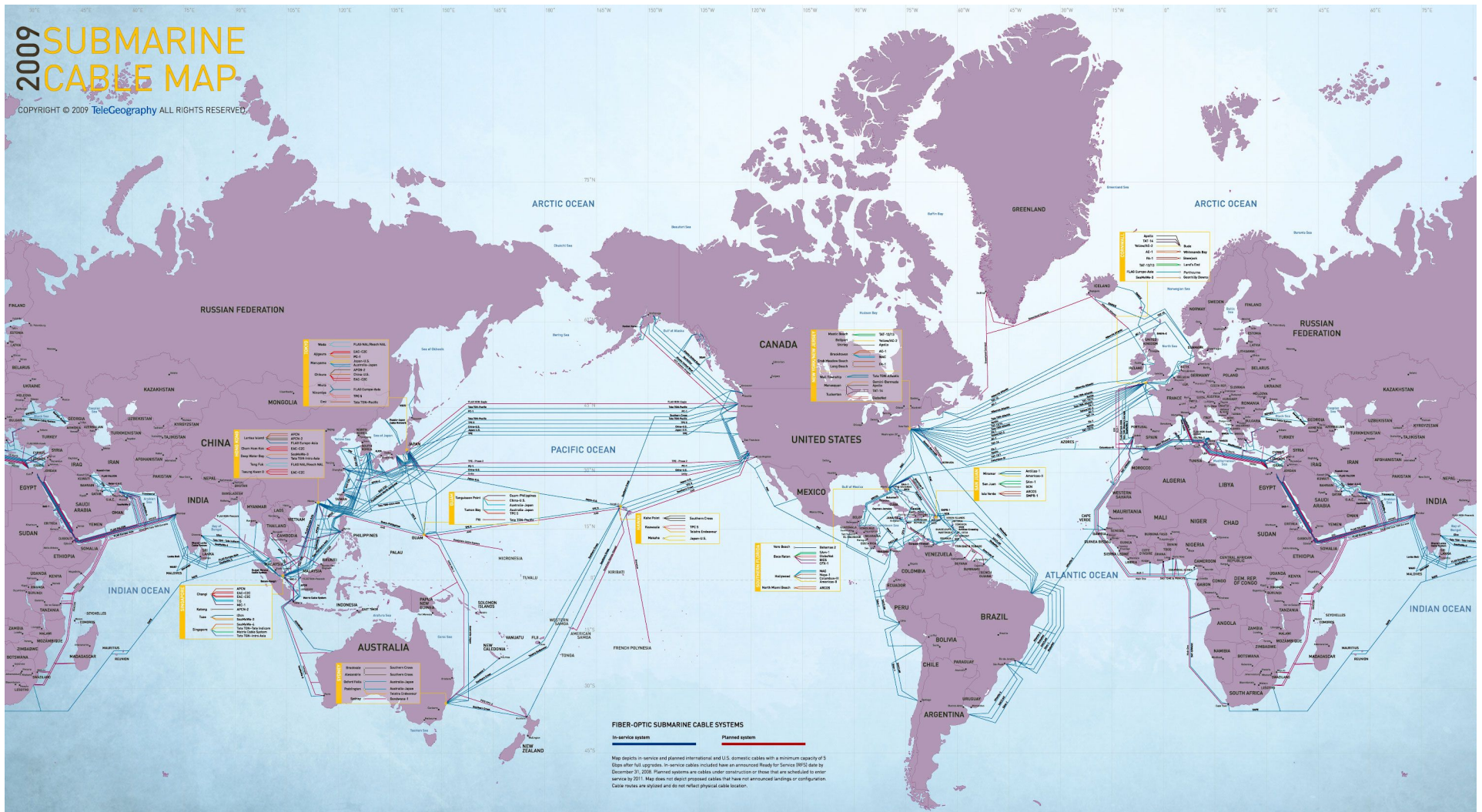
0.3dB/km @ 1310nm

0.2dB/km @ 1550nm

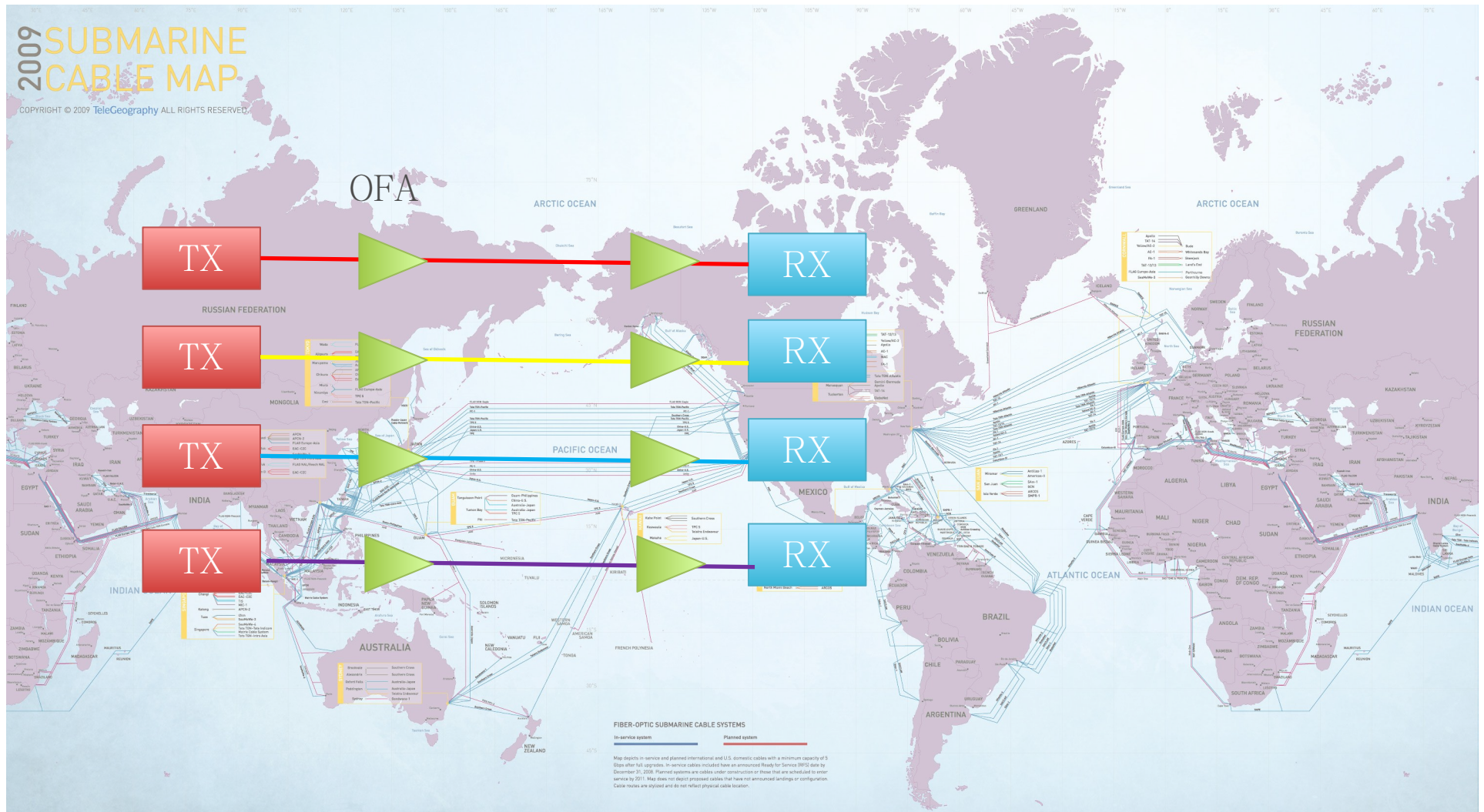
Huge available bandwidth Virtually 50THz



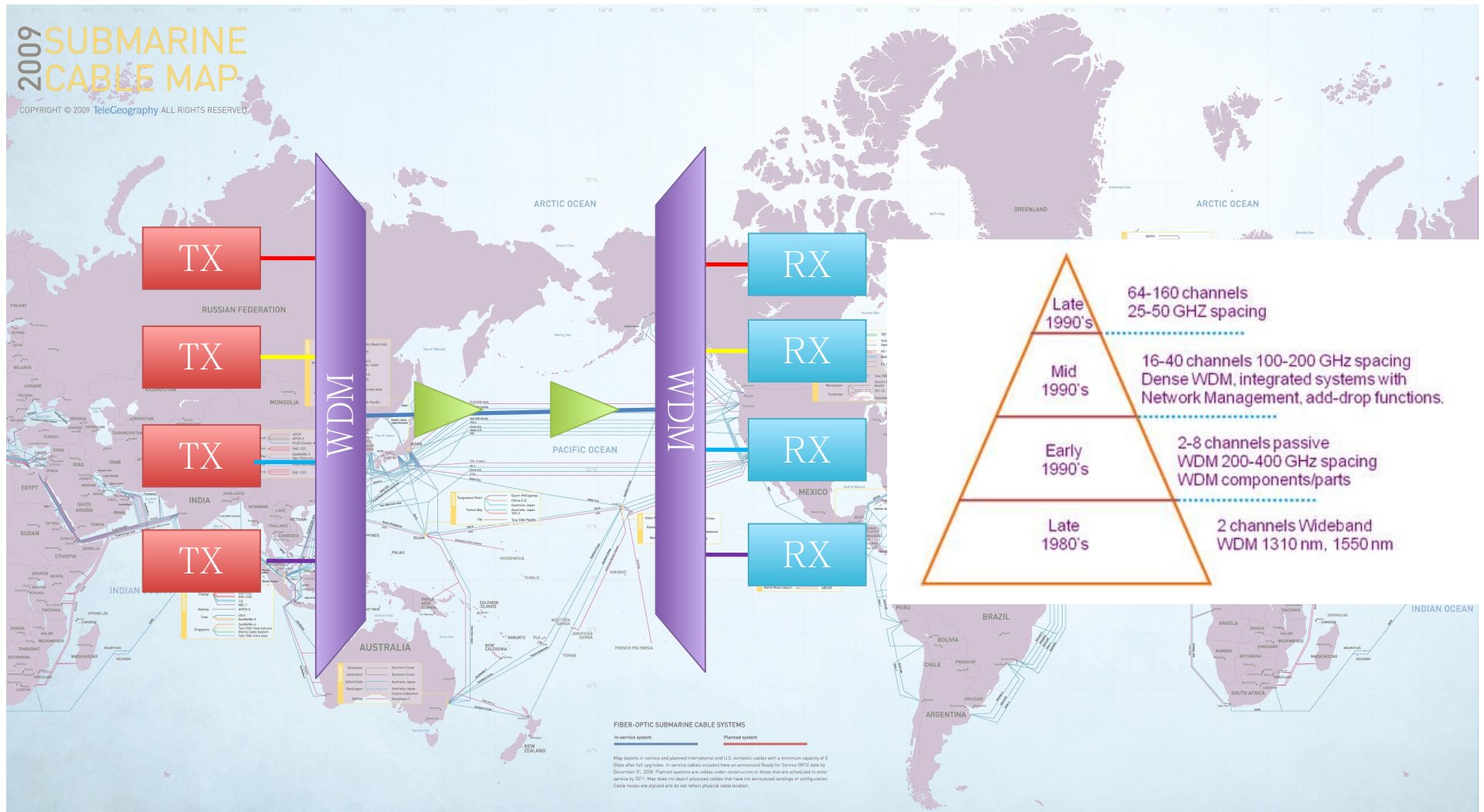
Optical Fiber



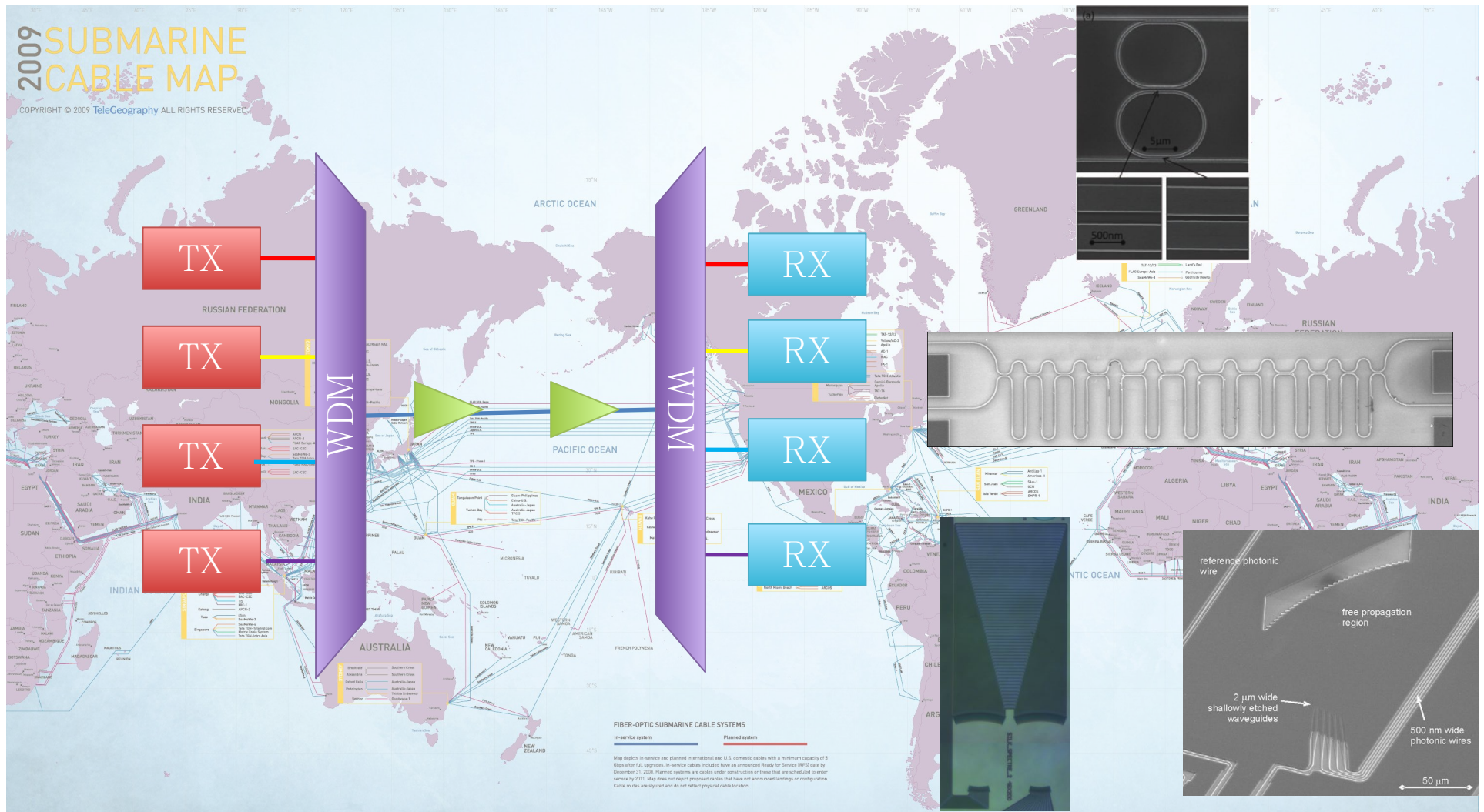
Optical Fiber



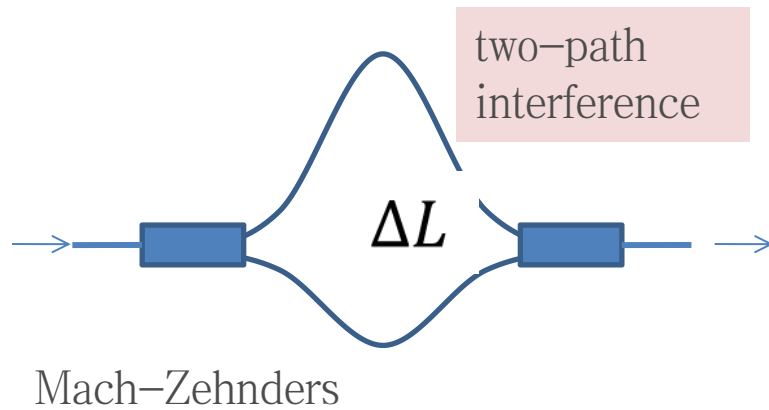
Wavelength Division Multiplexing (WDM)



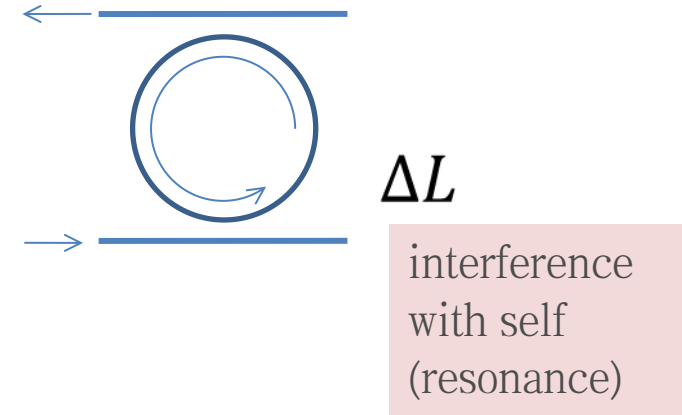
Wavelength Division Multiplexing (WDM)



WDM: Optical delay



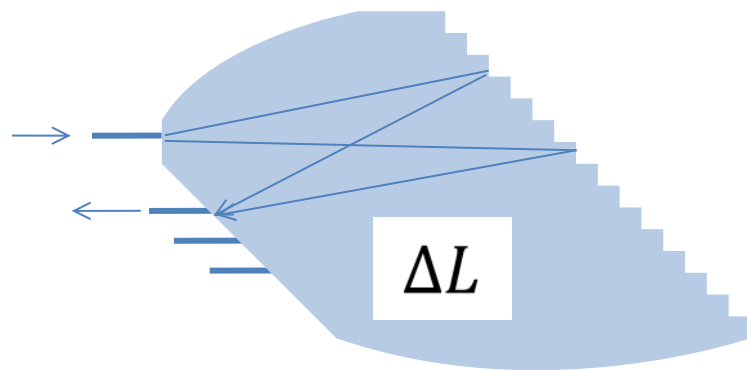
Ring resonators



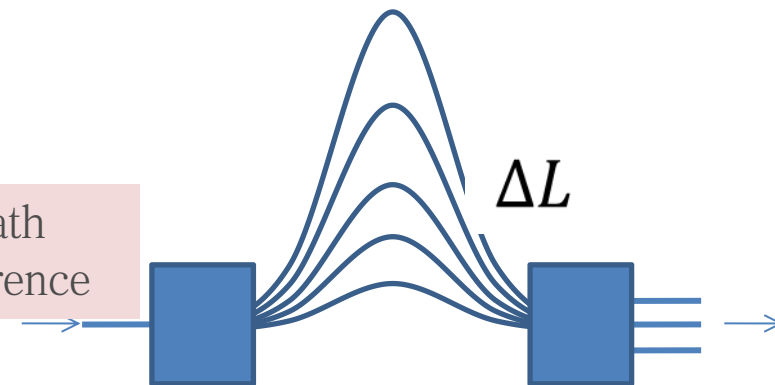
wavelength filter condition

$$m \cdot \lambda = \Delta L \cdot n_{eff}$$

Echelle gratings



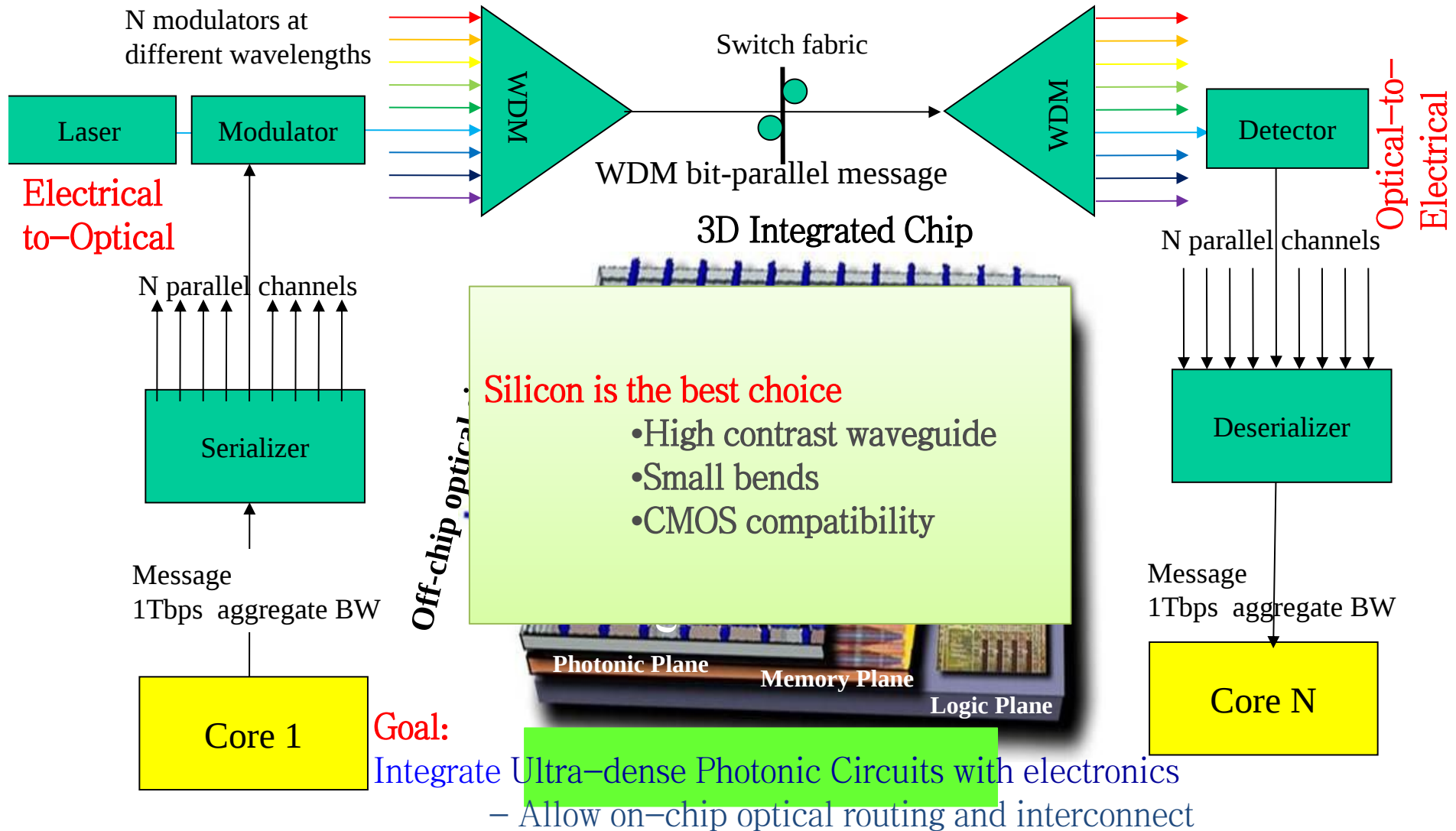
multipath interference



Arrayed waveguide gratings

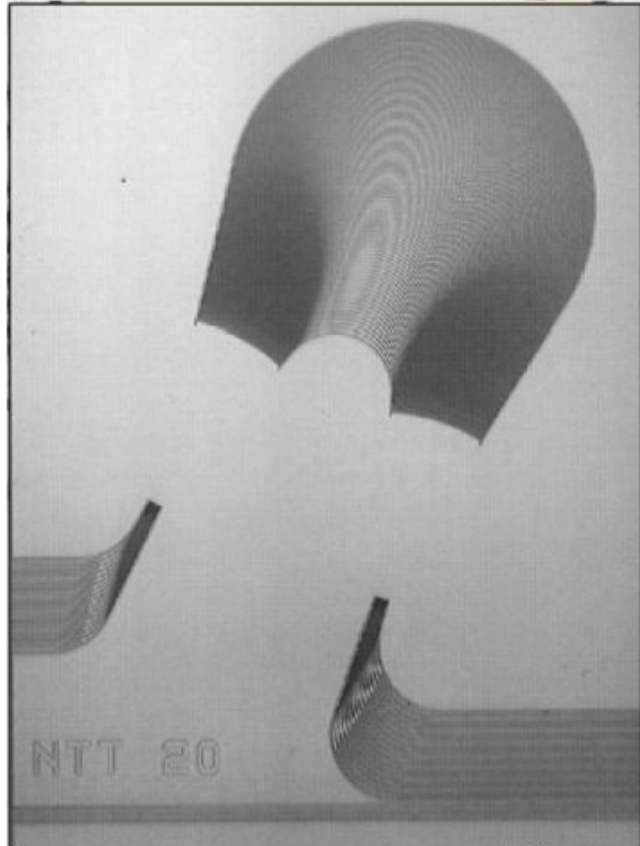
IBM Vision for 2020: On-chip interconnect

Nano-photonics for Optically connected 3-D Supercomputer Chip



Silicon AWG

40 X 100 GHz Silica AWG



Bend Radius 1mm
Core $3.5 \times 3.5 \mu\text{m}^2$
Device Size $9 \times 12 \text{ mm}^2$
 $n_{\text{core}} = 1.482$ $n_{\text{clad}} = 1.44$

64 X 50 GHz InP AWG



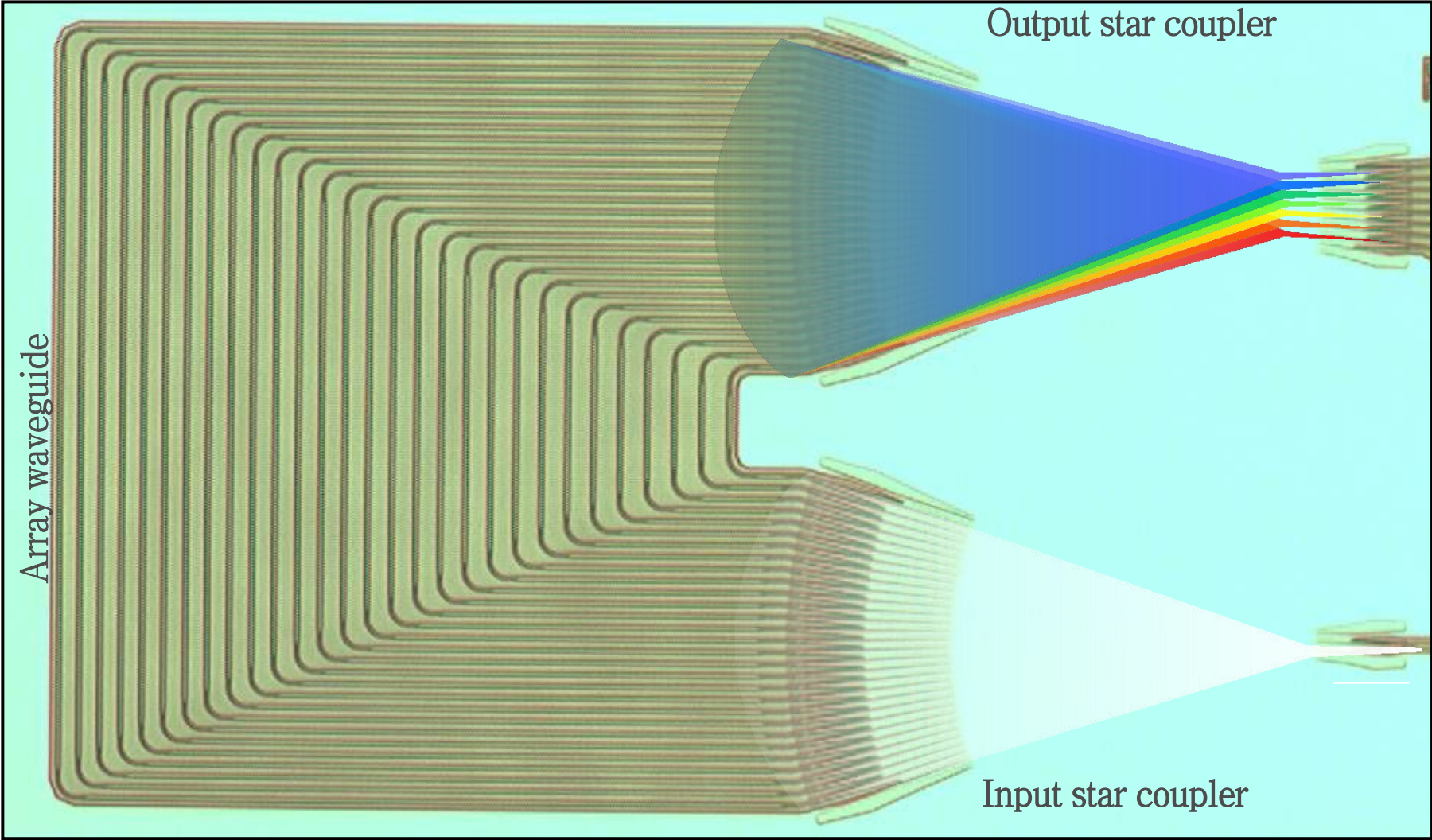
Bend Radius 0.5mm
Core $2.0 \times 0.5 \mu\text{m}^2$
Device Size $3.6 \times 7 \text{ mm}^2$
 $n_{\text{core}} = 3.3$ $n_{\text{clad}} = 1.7$

16 X 200 GHz Silicon AWG

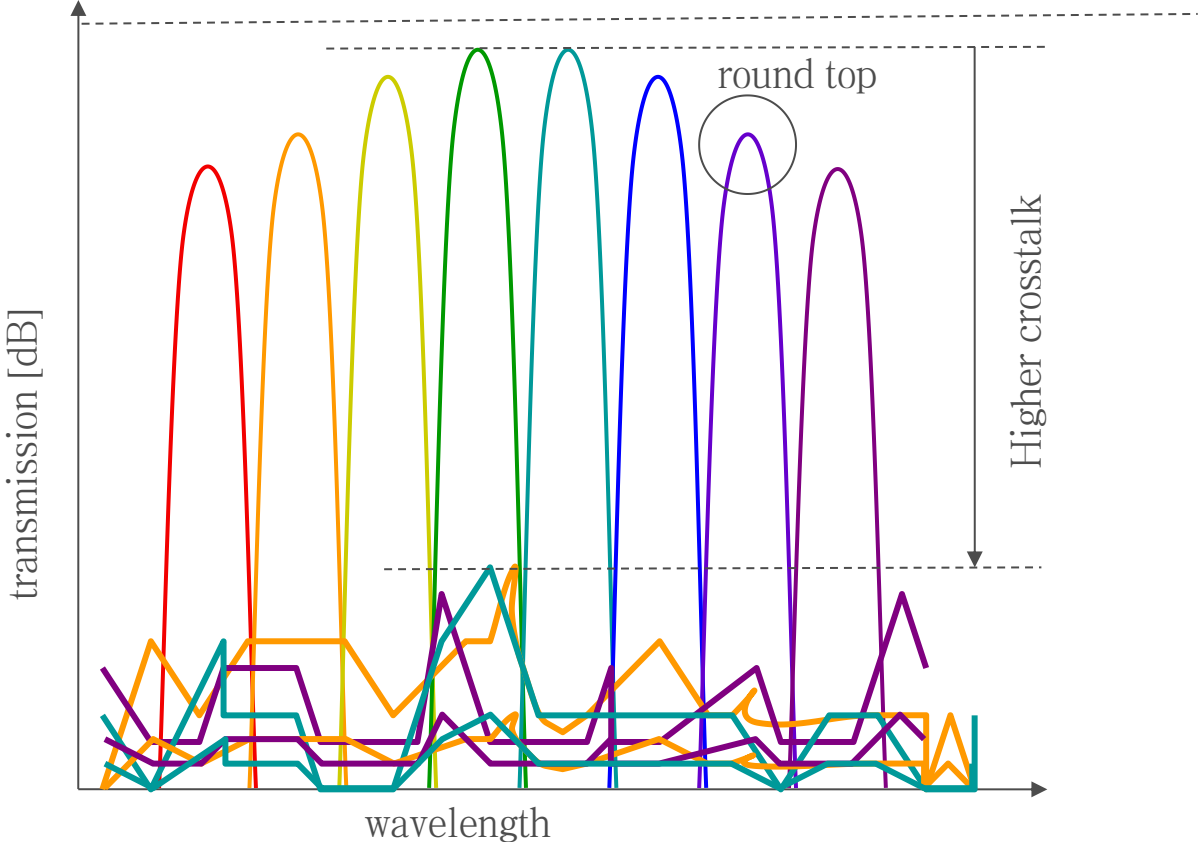


Bend Radius 0.005mm
Core $0.8 \times 0.22 \mu\text{m}^2$
Device Size $0.850 \times 0.340 \text{ mm}^2$
 $n_{\text{core}} = 3.48$ $n_{\text{clad}} = 1.44$

Arrayed Waveguide Grating (AWG)



Problems in Silicon AWG



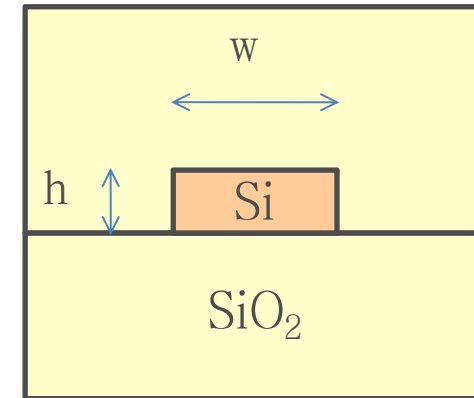
- High Insertion Loss
- High Crosstalk
- Channel Spacing Mismatch
- Round Top

High Sensitivity

wire width $\frac{\partial \lambda}{\partial w} \approx 1 \text{ nm/nm}$

wire height $\frac{\partial \lambda}{\partial h} \approx 2 \text{ nm/nm}$

temperature $\frac{\partial \lambda}{\partial T} \approx 0.08 \text{ nm/K}$



Good geometry control is required

Structure the outline

- + Our approach
- + Our results
- + Conclusions

Structure the outline

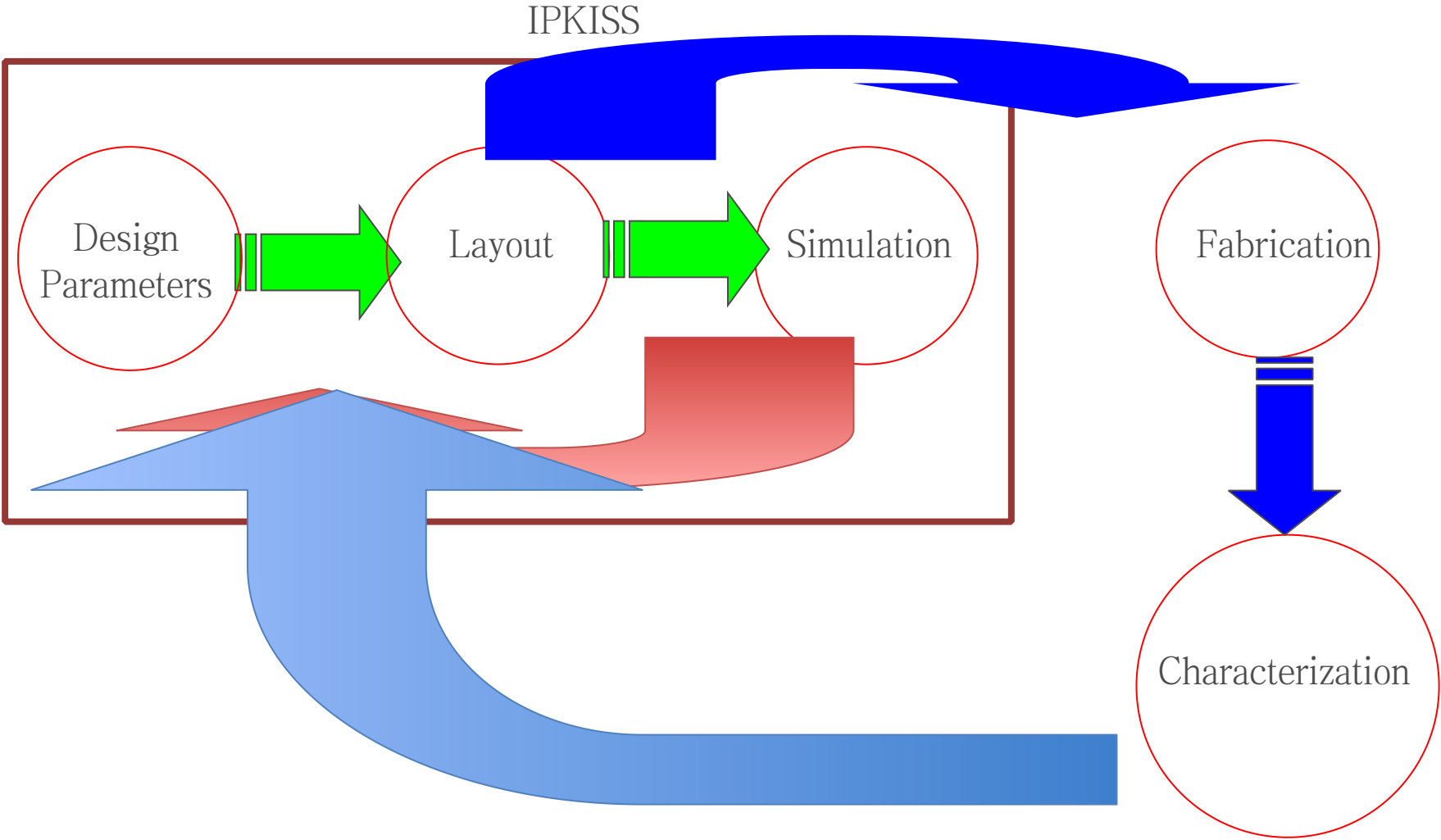
– Our approach

- Design
- Simulation
- Fabrication
- Measurement

+ Our results

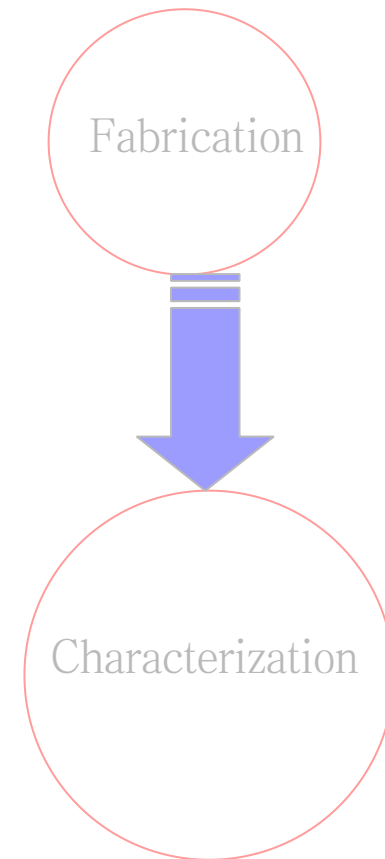
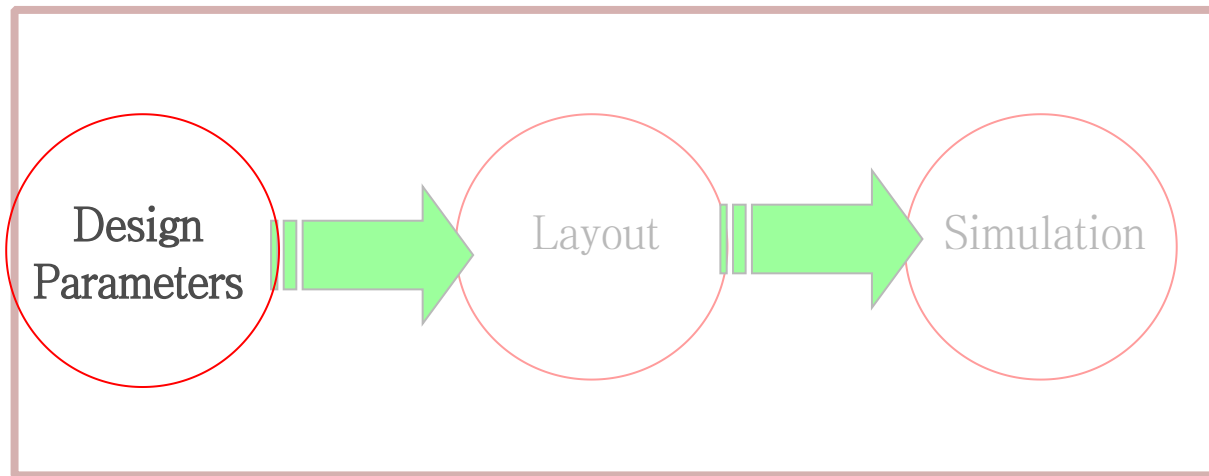
+ Conclusions

Framework



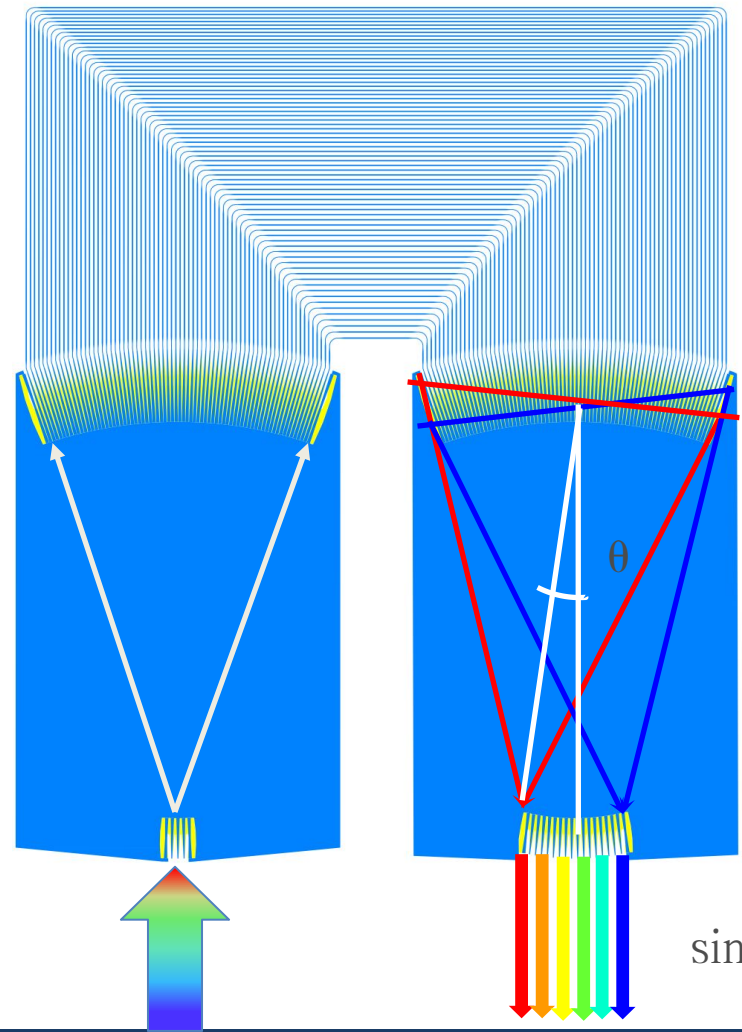
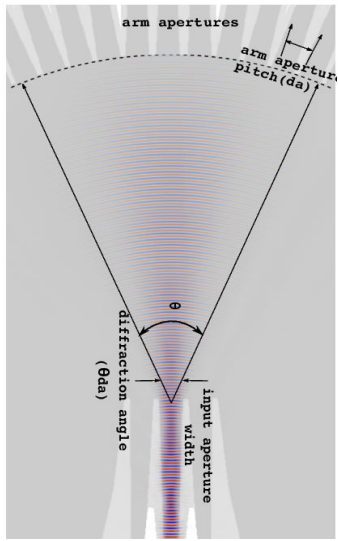
Framework

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Design Parameters

$$Ra = \frac{d_a \cdot N_{arms}}{\theta_{da}}$$



$$L = m \cdot \lambda_c / n_{wg}(\lambda_c)$$

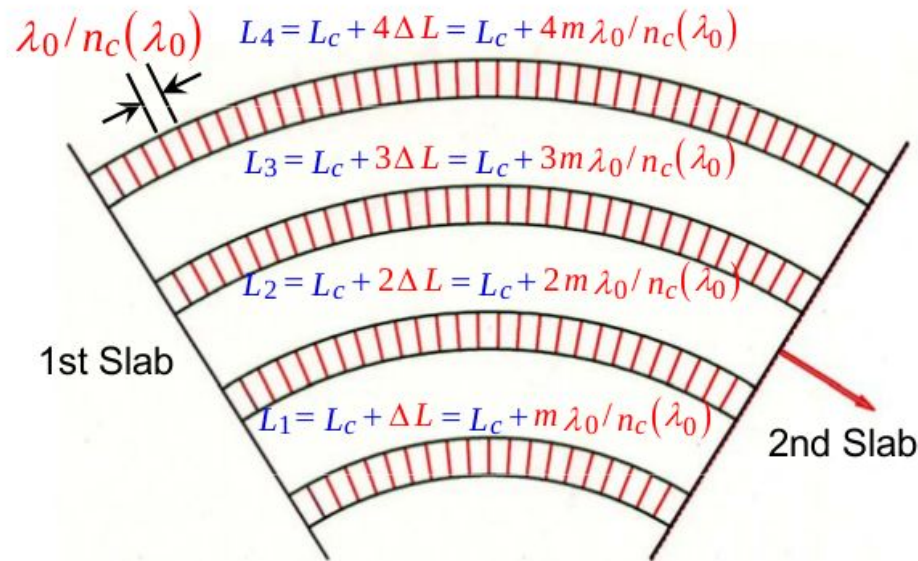
$$\sin \theta = \frac{n_{wg}(\lambda) \cdot \lambda_c}{(\lambda_c) \cdot \lambda} = \frac{m \cdot n_{wg}(\lambda_c) \cdot n_{slab}(\lambda) \cdot d_a}{(\lambda_c) \cdot \lambda}$$

Phase Fronts in Array waveguides

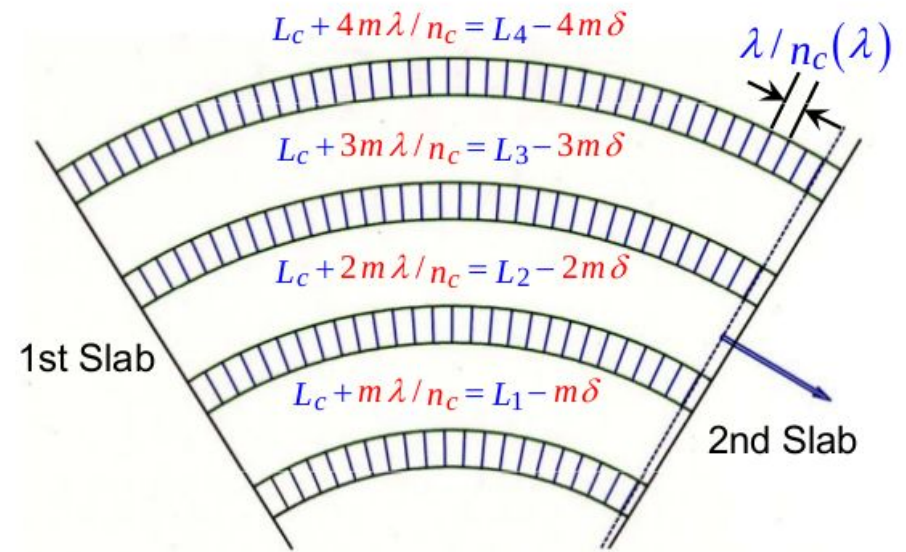
$$\underline{\lambda = \lambda_0}$$

$$\Delta L = m \frac{\lambda_0}{n_c(\lambda_0)} \Rightarrow \lambda_0 = \frac{n_c \Delta L}{m}$$

$$\underline{\lambda < \lambda_0}$$



(a) Phase relation for $\lambda = \lambda_0$

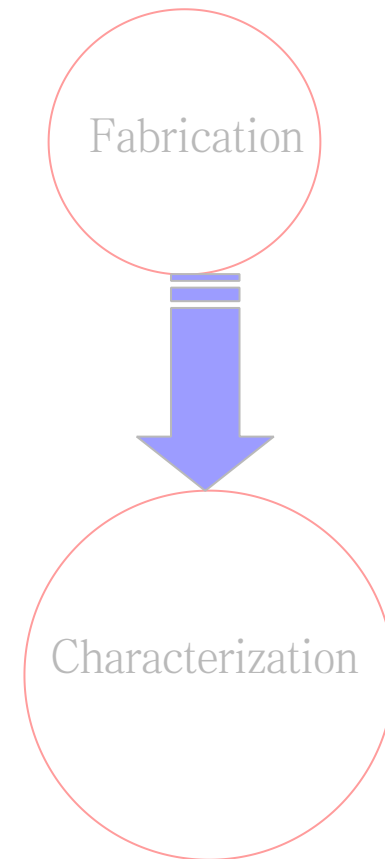
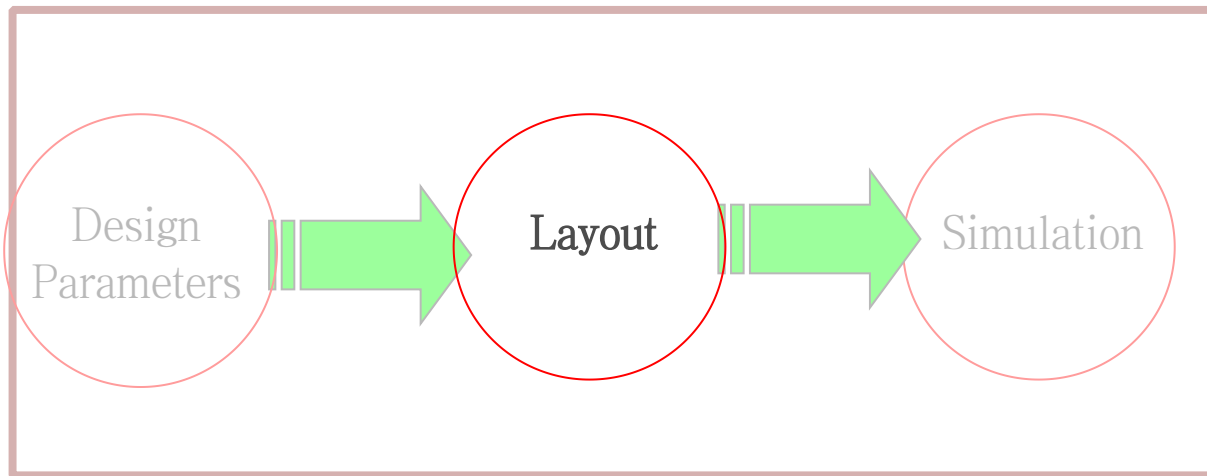


$$\delta = \frac{\lambda_0}{n_c(\lambda_0)} - \frac{\lambda}{n_c(\lambda)}$$

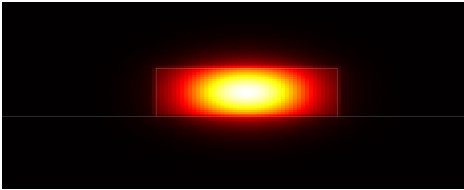
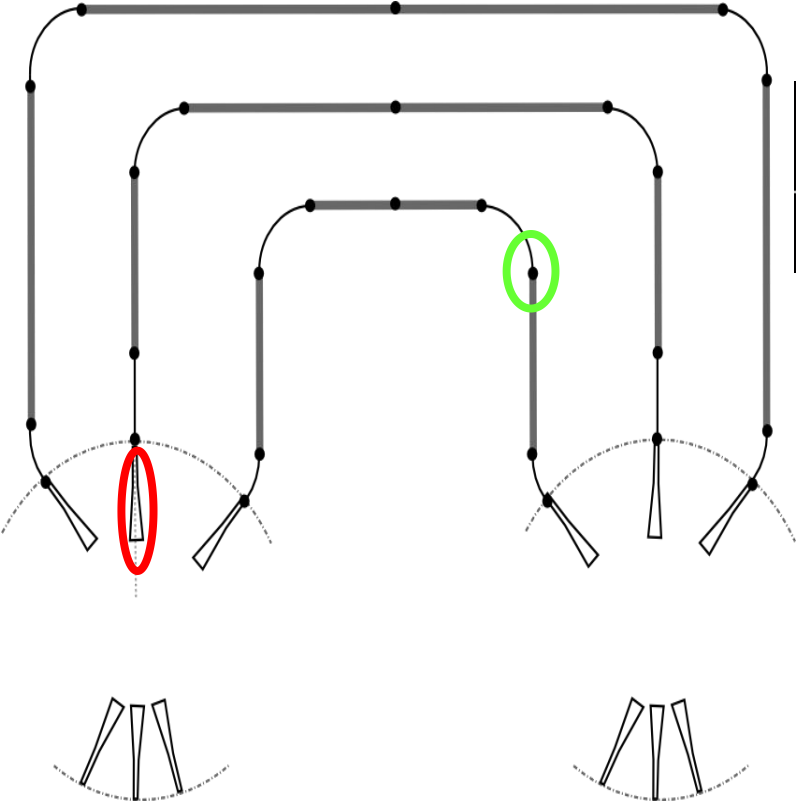
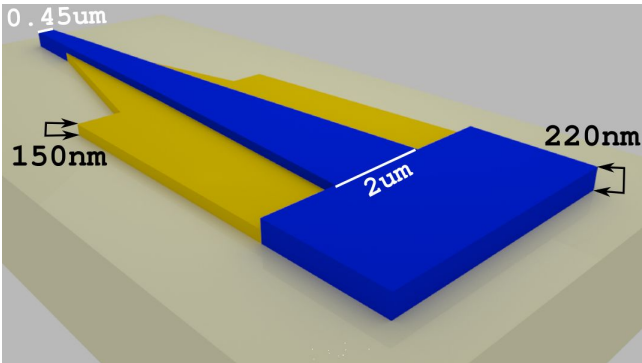
(b) Phase relation for $\lambda < \lambda_0$

Framework

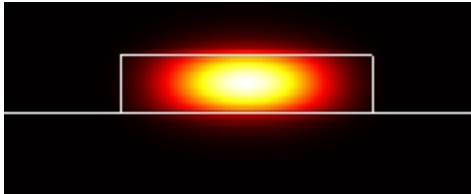
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Design of Silicon AWG

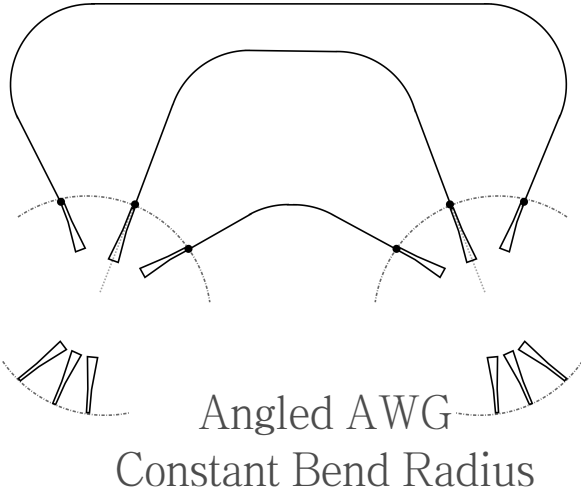
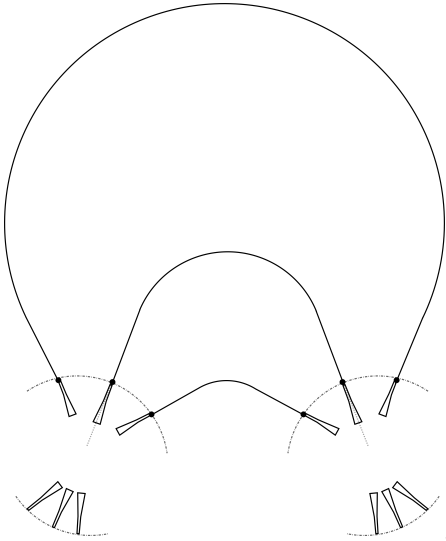
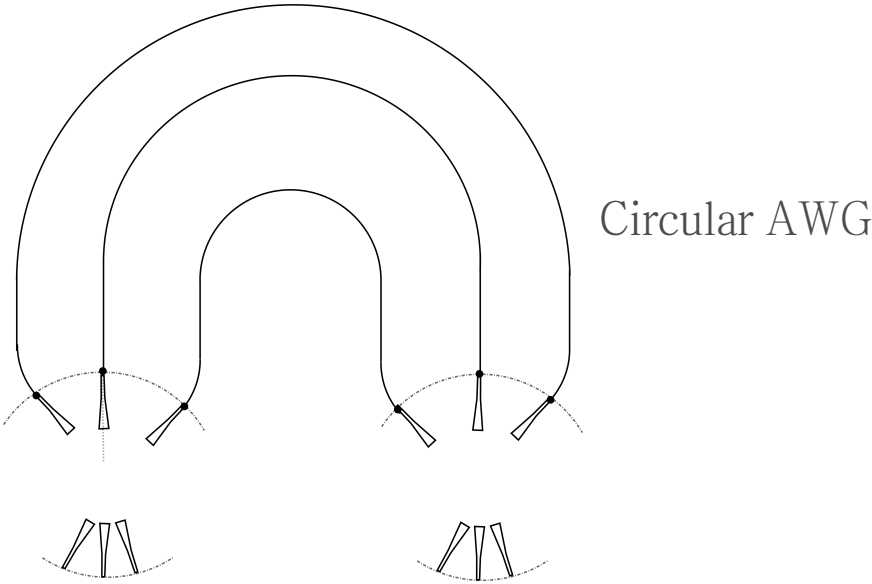
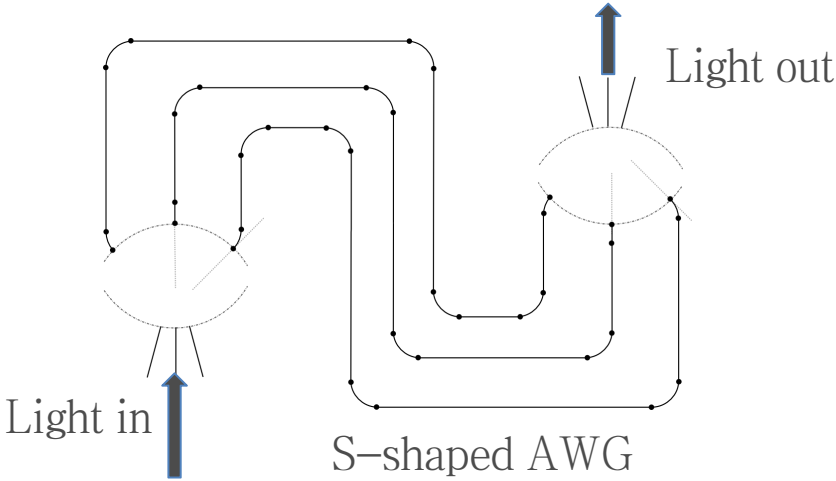


450 nm WG



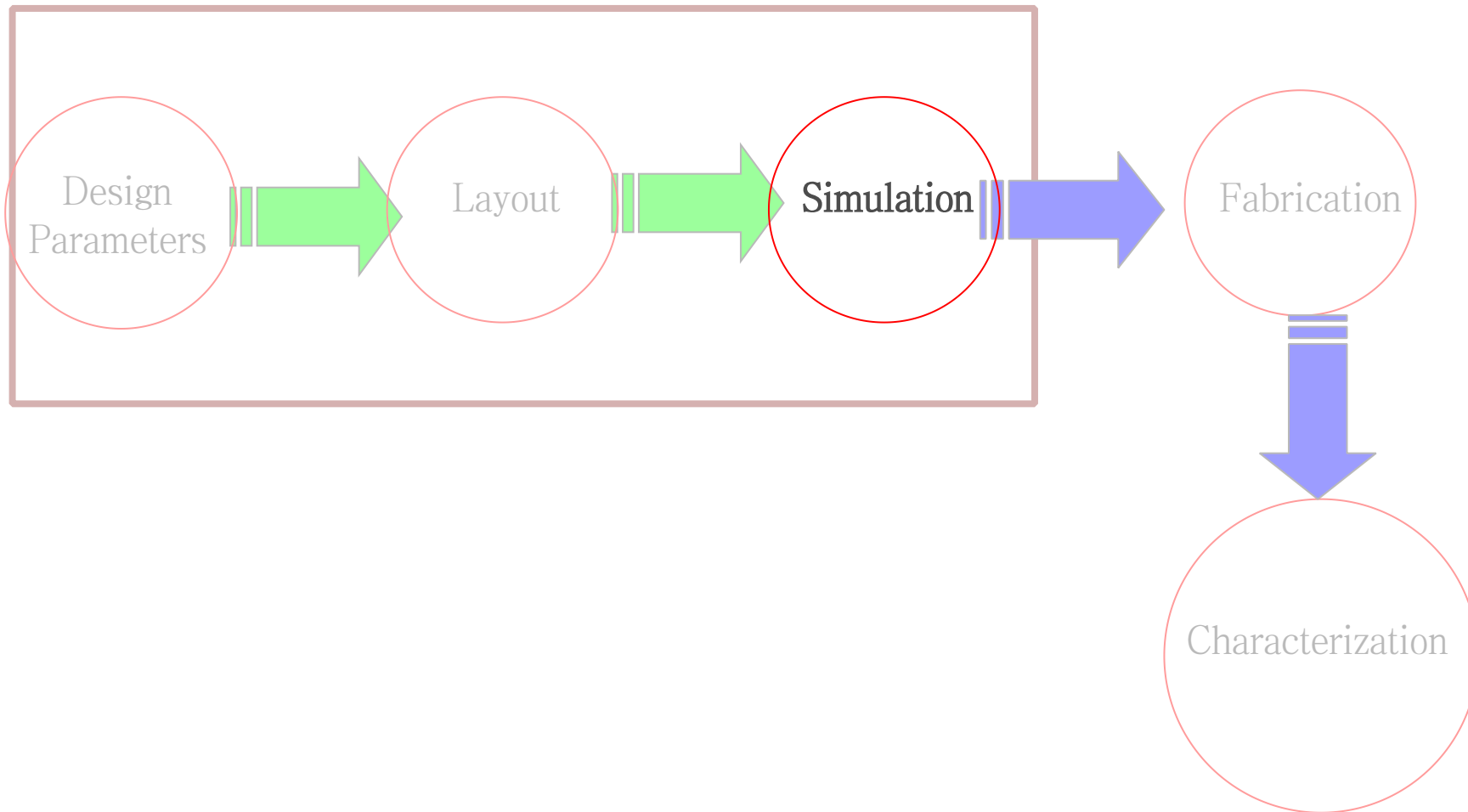
800 nm WG

Different shaped AWGs

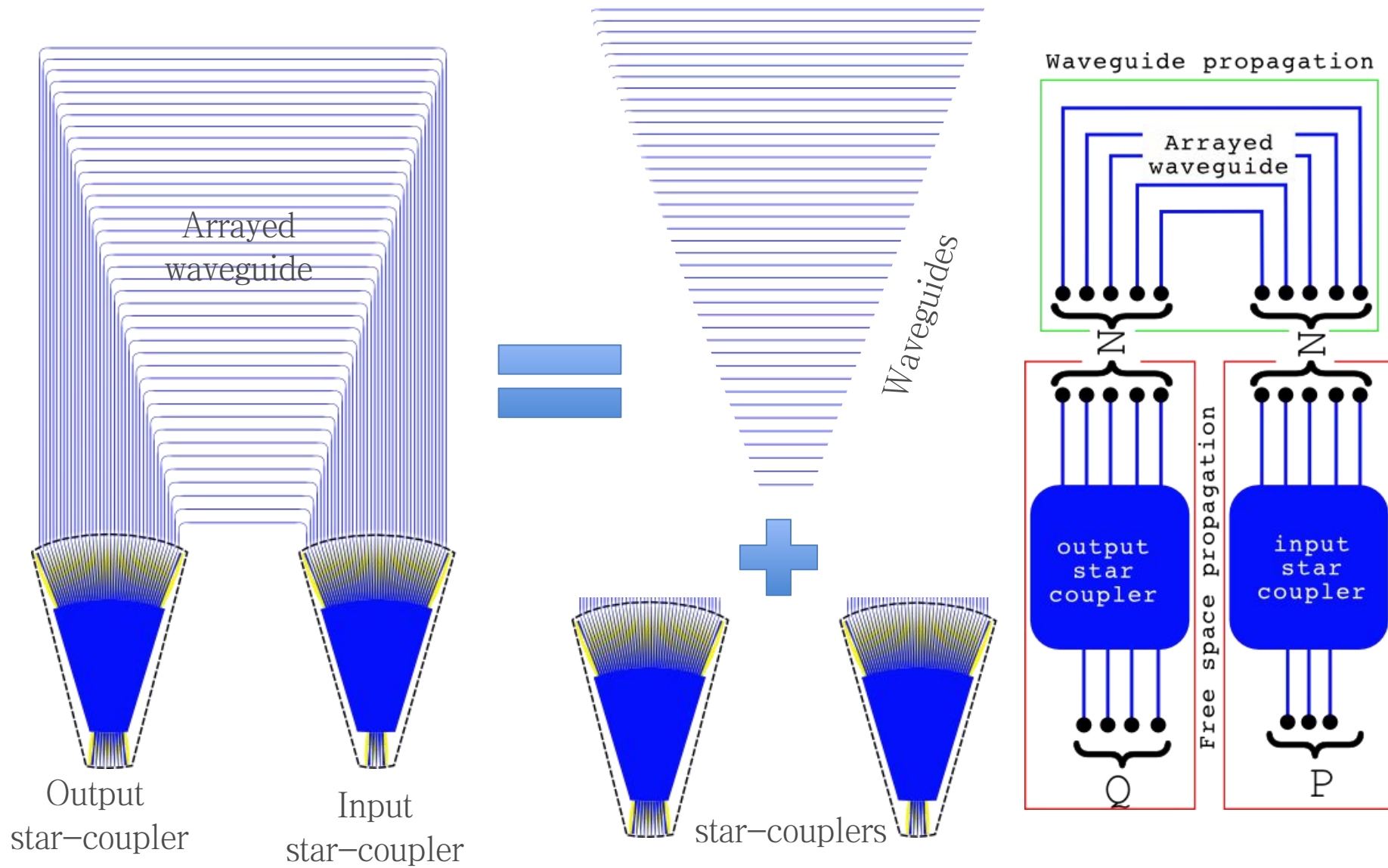


Framework

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Simulation of the AWG: Decomposition

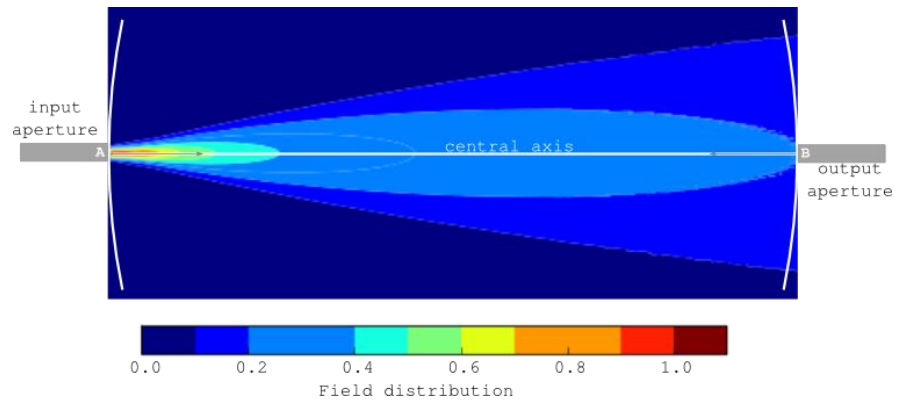
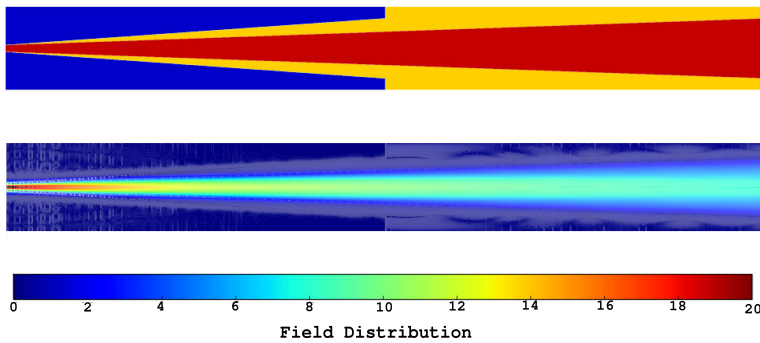


Simulation of the AWG: Slab Engine

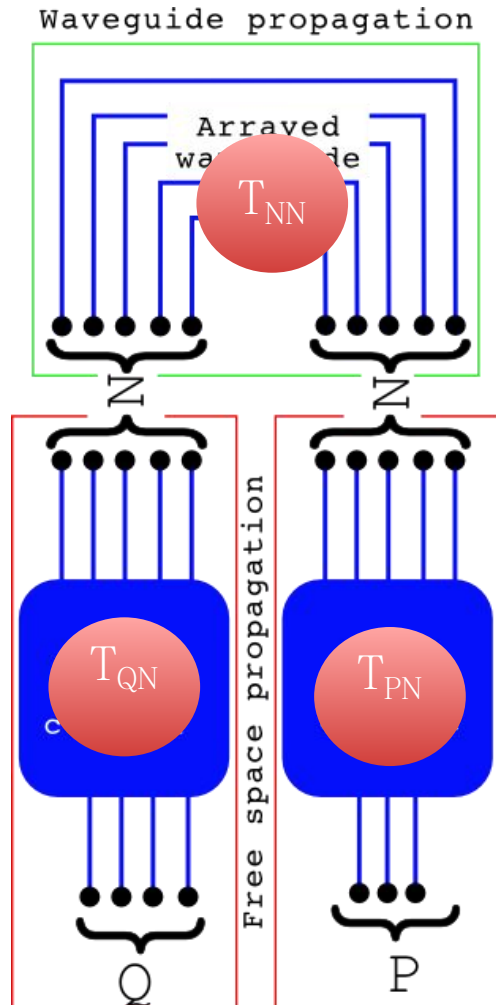


Material stacks

Air	Air	Air
Si 220nm	Si 150nm	
SiO ₂ 2μm	SiO ₂ 2μm	SiO ₂ 2μm

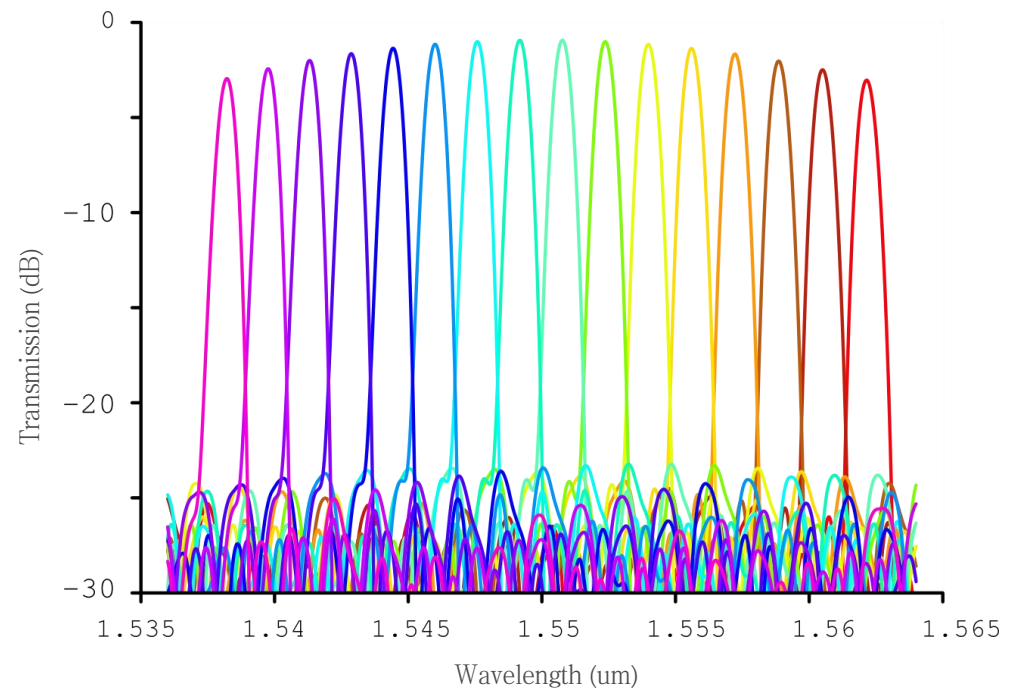


Simulation of the AWG

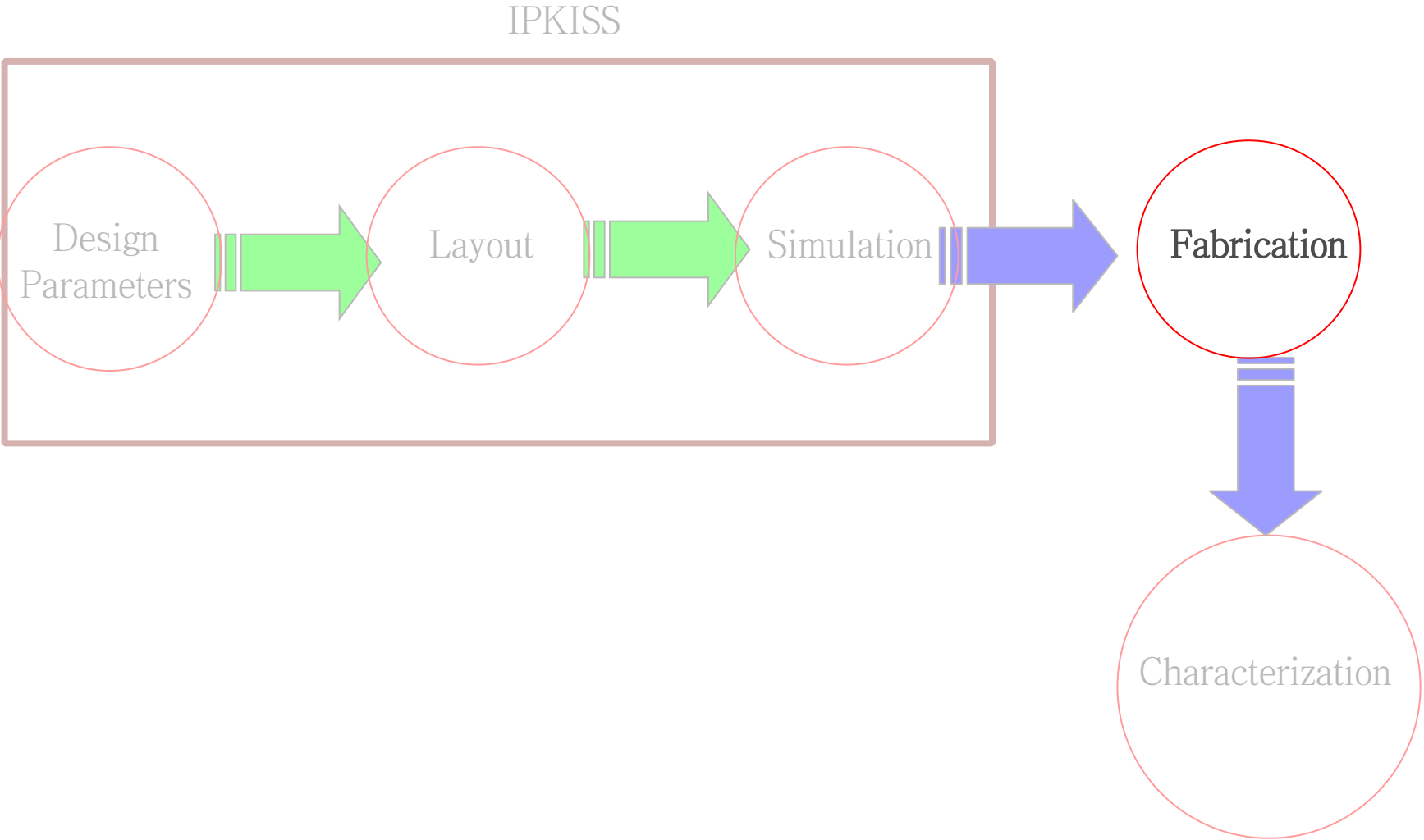


$$T_{QP} = T_{QN} \cdot T_{NN} \cdot T_{PN}^T$$

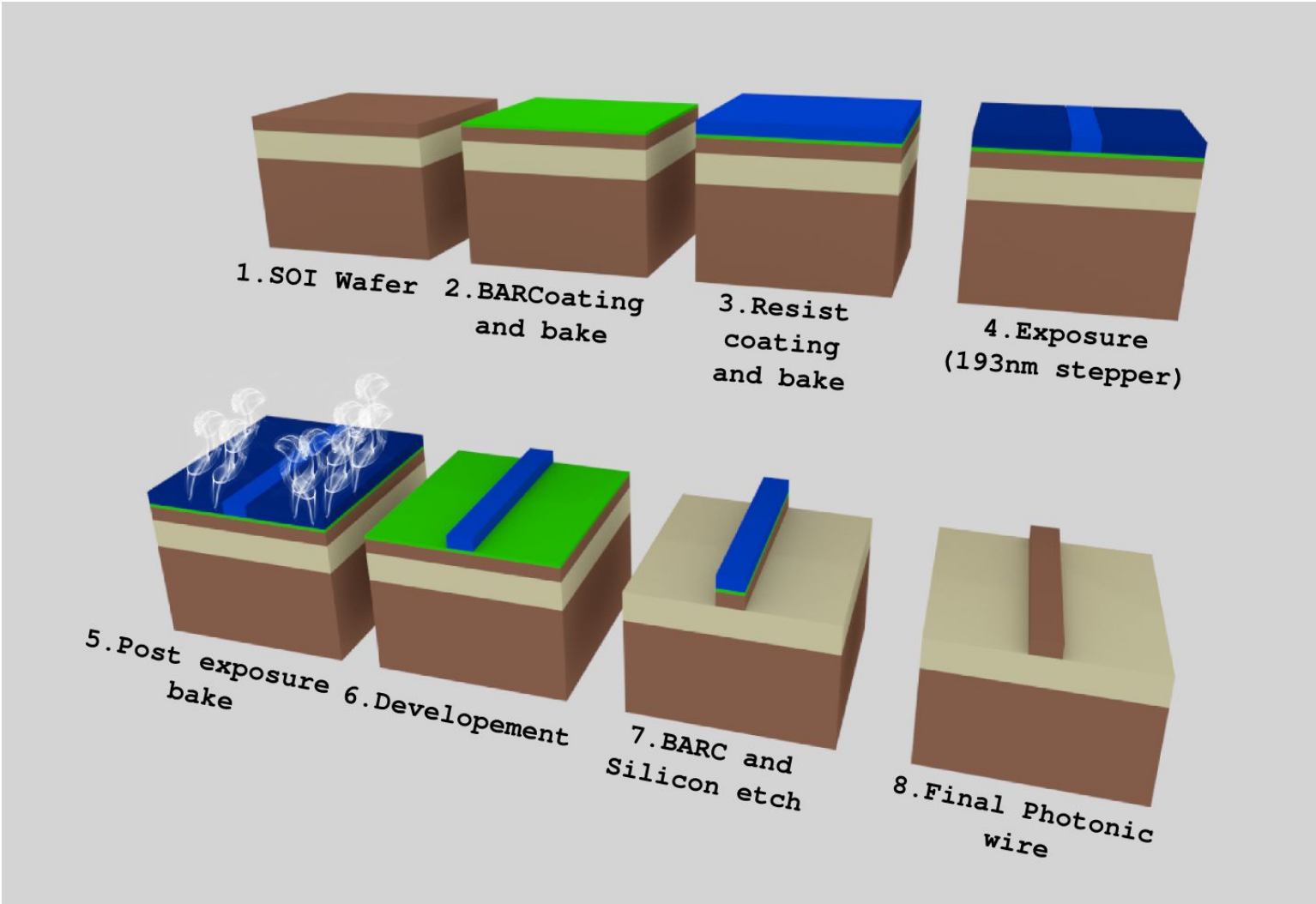
Simulation 16x200 GHz AWG



Framework

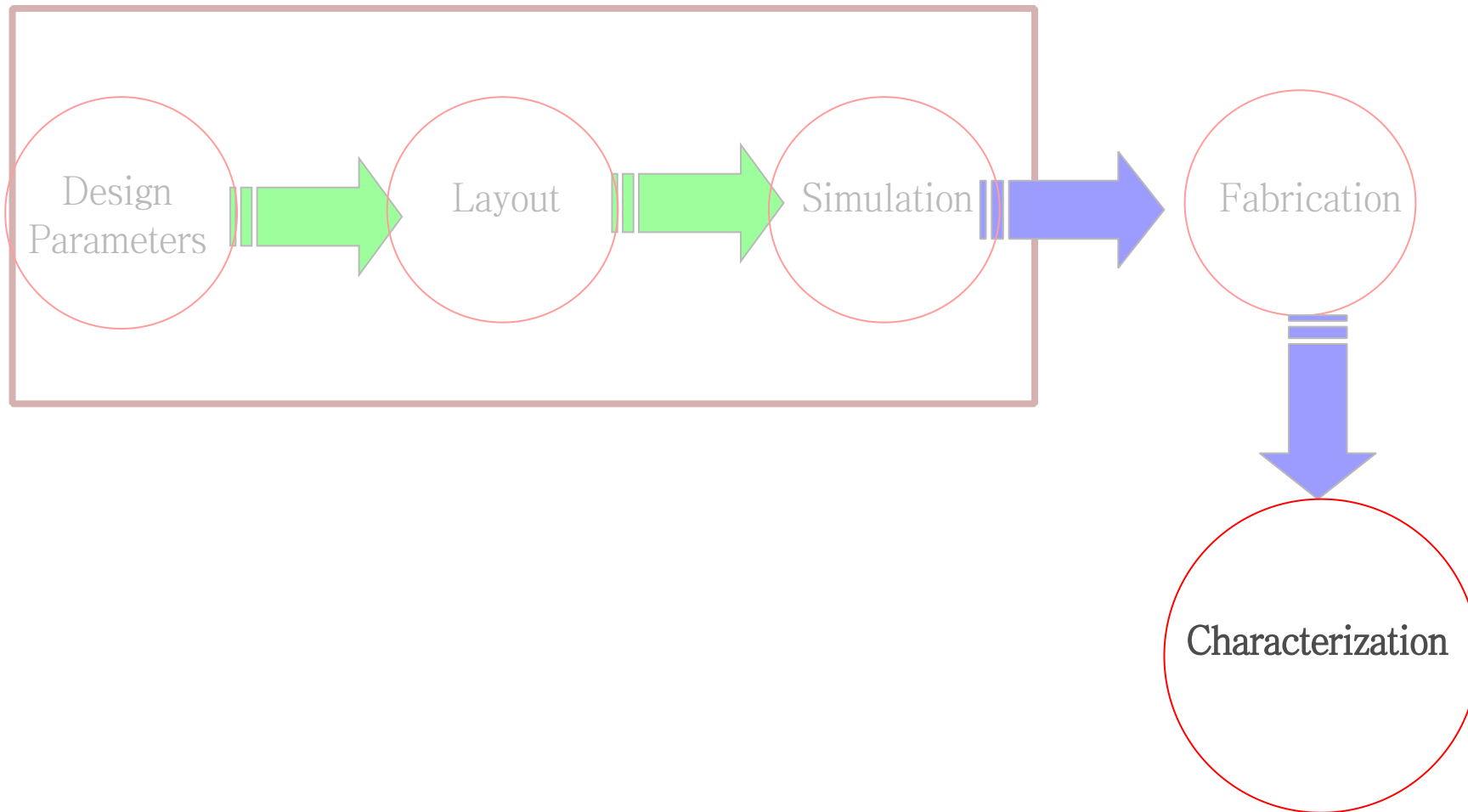


Fabrication

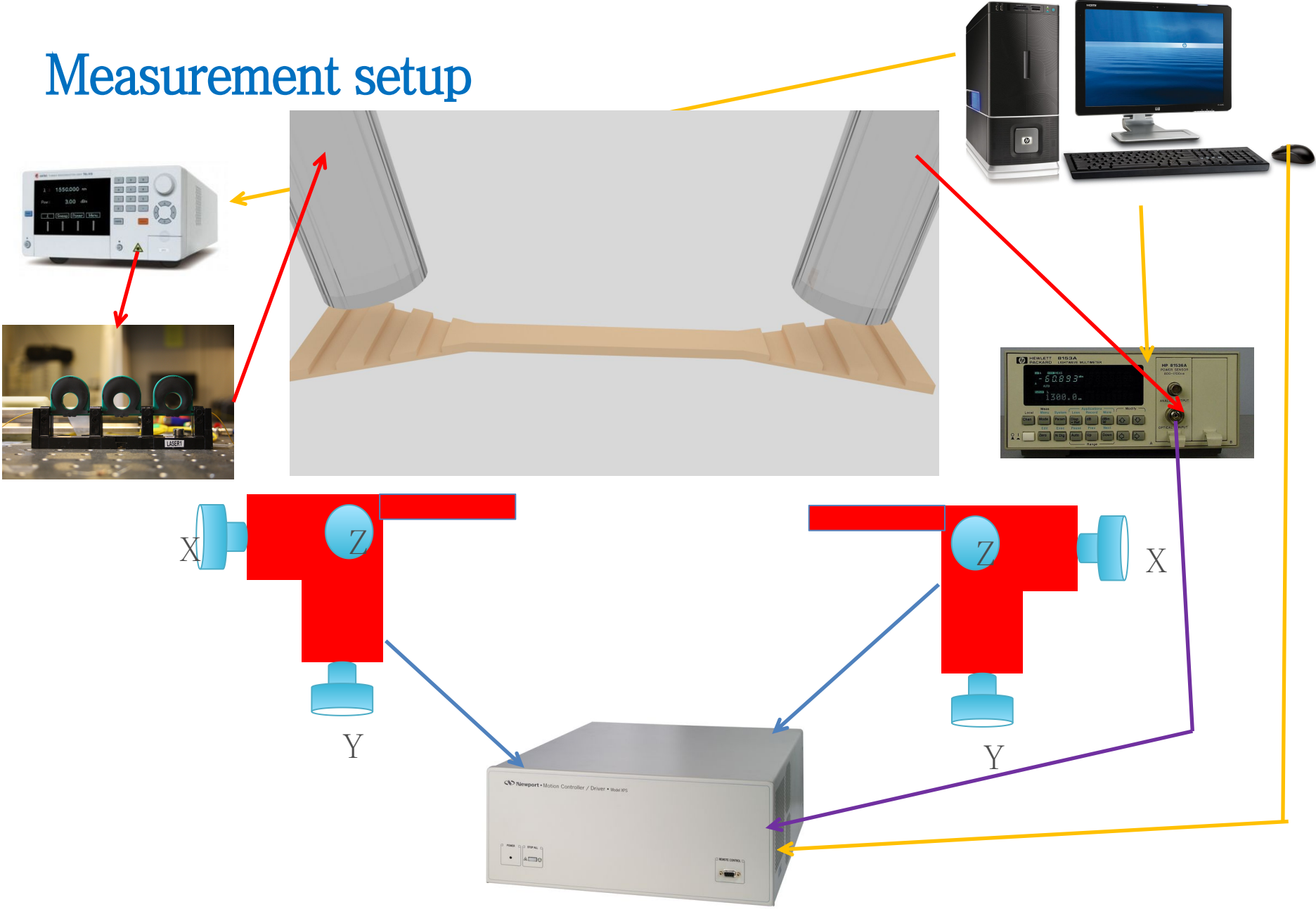


Framework

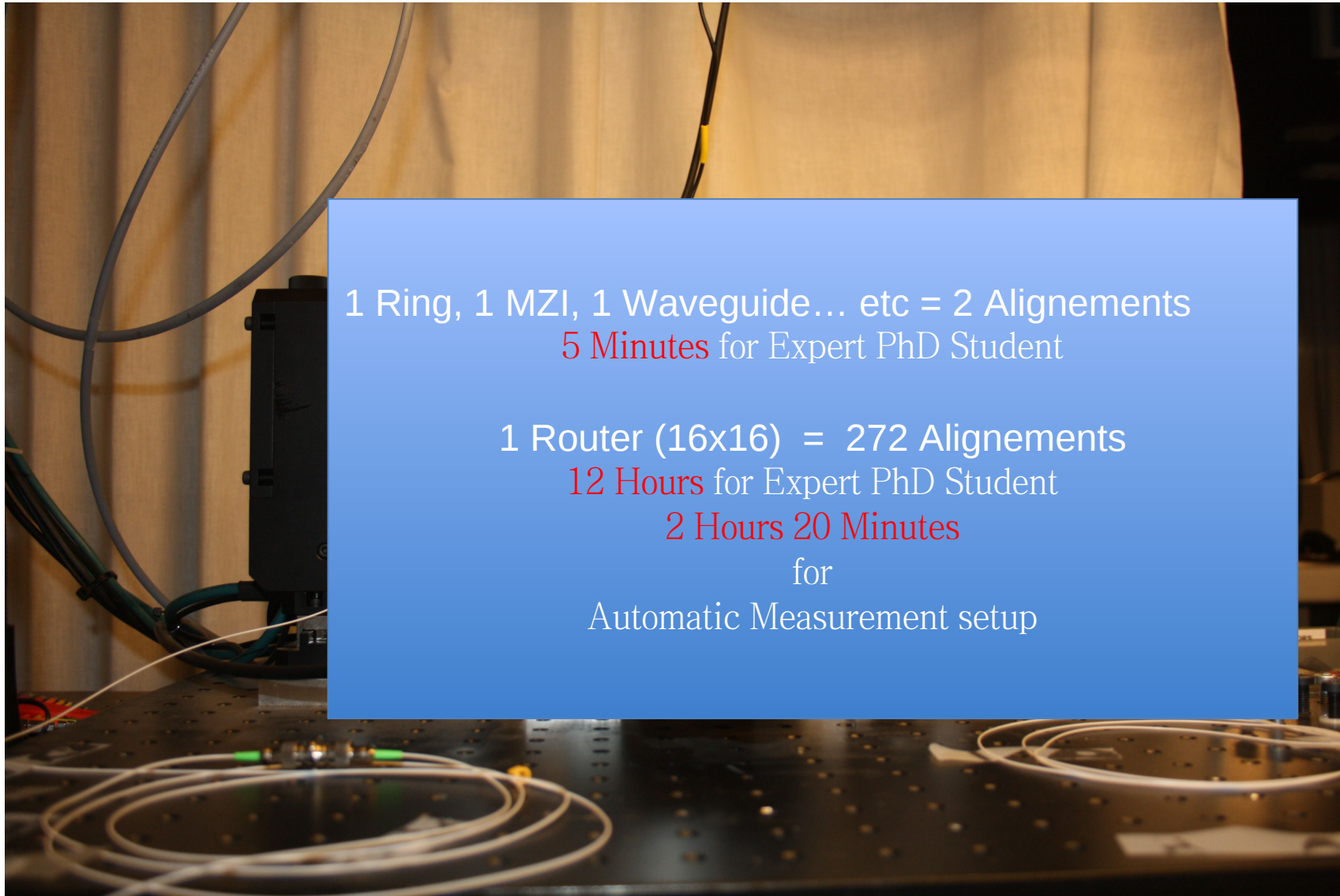
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Measurement setup

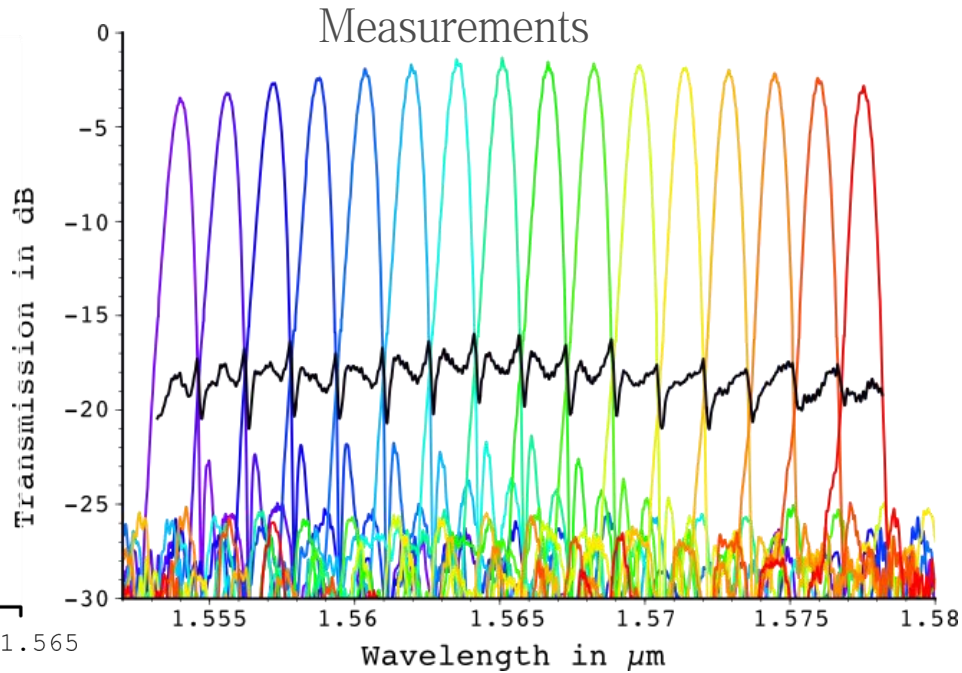
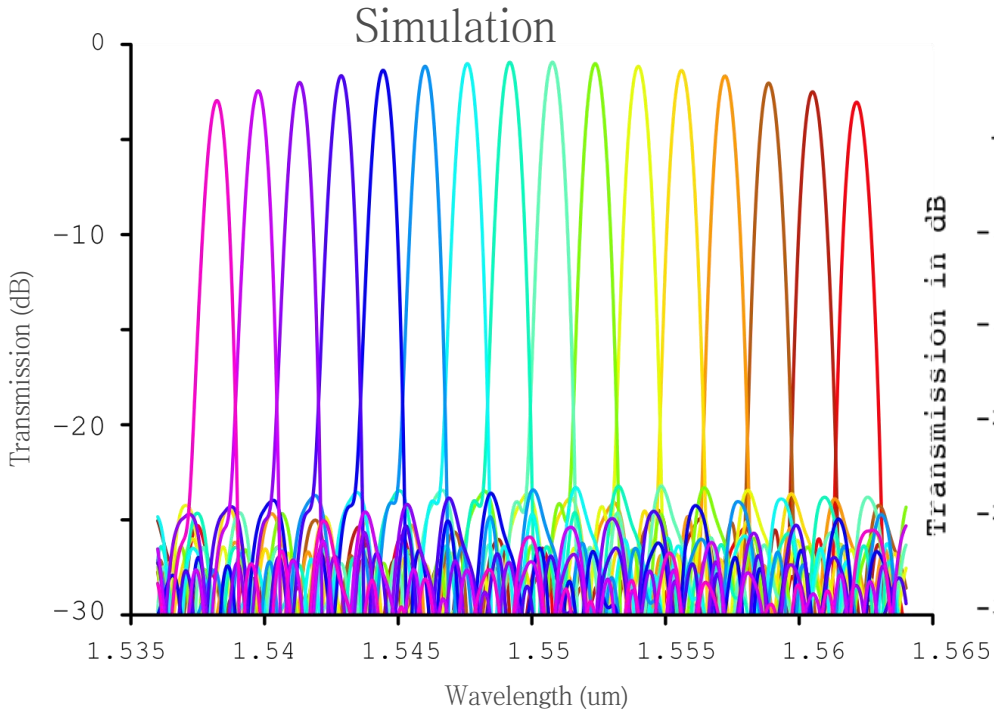
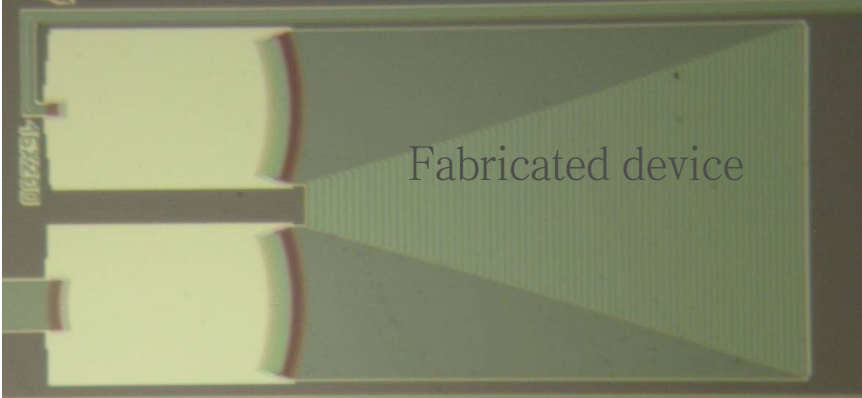
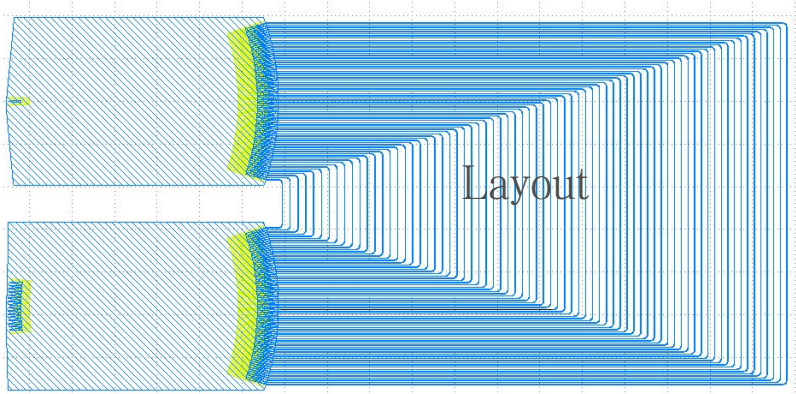


Automatic Setup



Layout – Simulation

Fabrication– Measurements (16x200 GHz AWG)



Structure the outline

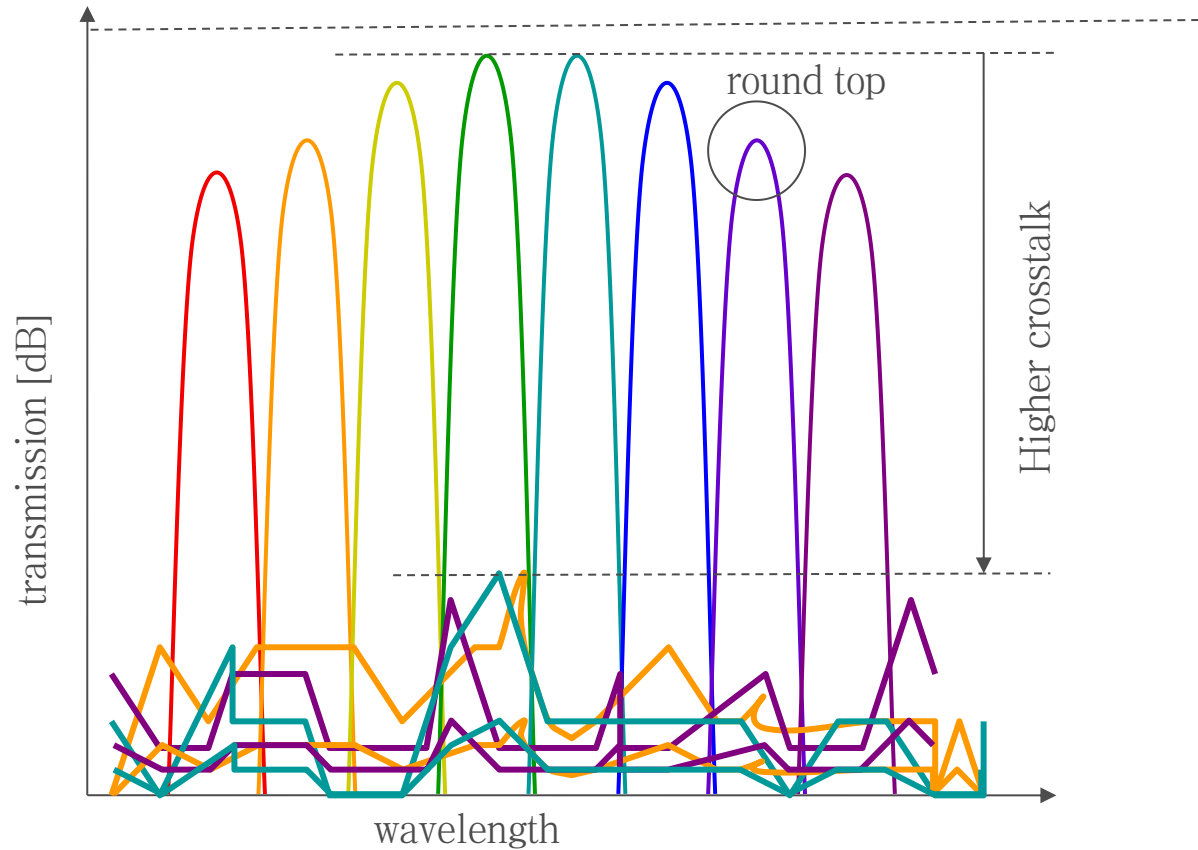
+ Our approach

– Our results

- Insertion Loss and Non–uniformity
- Crosstalk
- Channel mismatch
- Round top to flattop
- Switch

+ Conclusions

Problems in Silicon AWG



- High Insertion Loss
- High Crosstalk
- Channel Spacing Mismatch
- Round Top

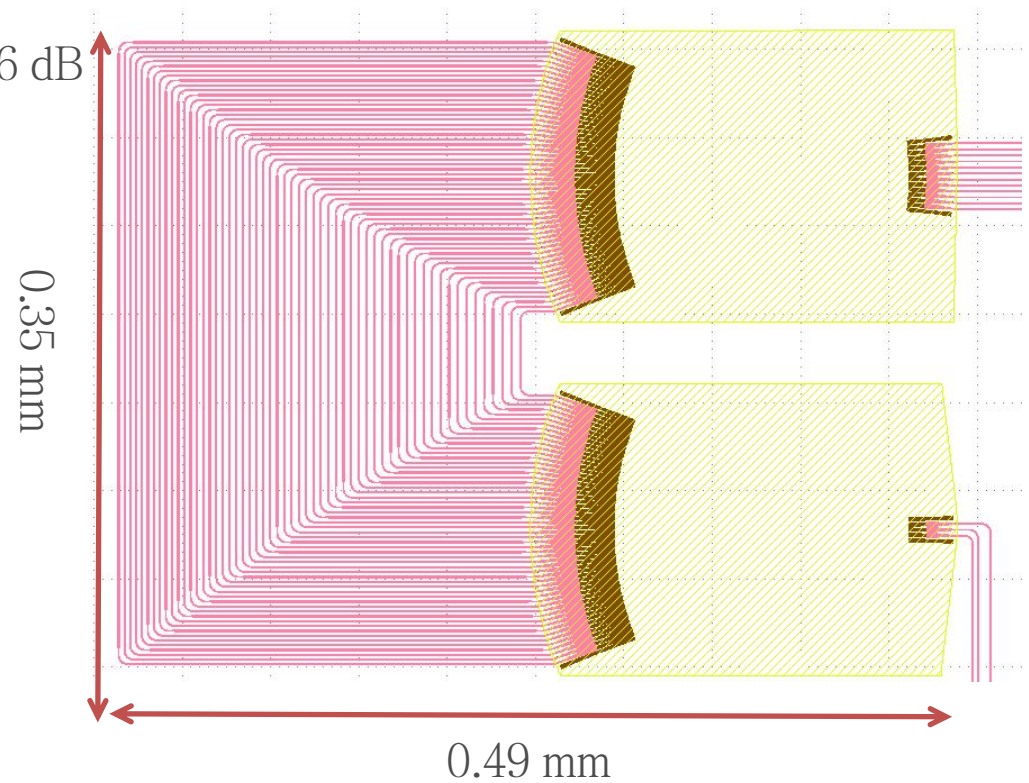
Insertion Loss of AWG

Propagation loss of a Si wire: 2dB/cm

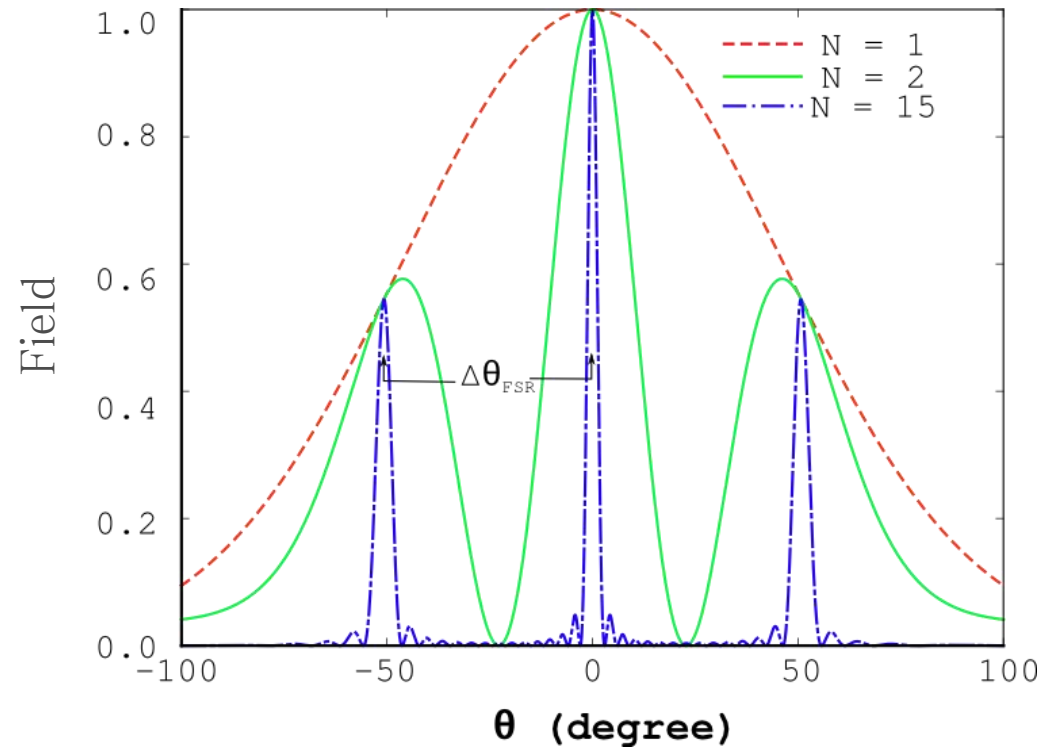
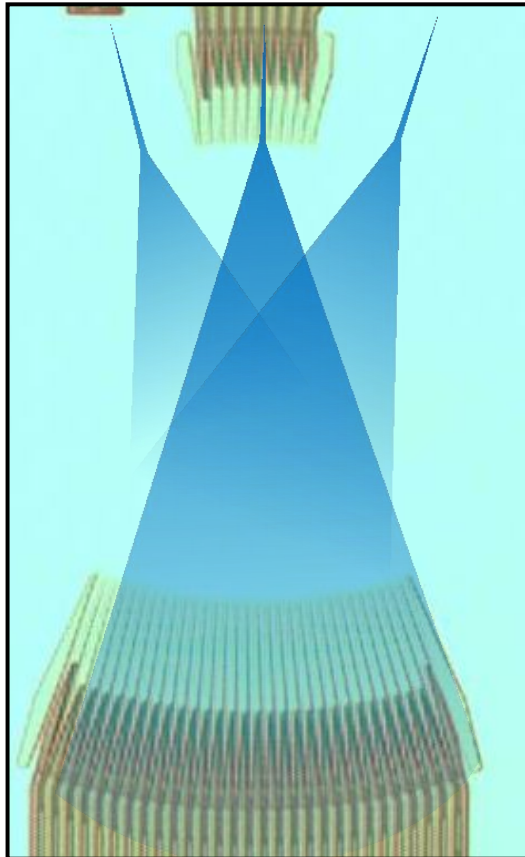
For a 12X400 GHz AWG Path travel by the Light is: ~ 1 mm

But Insertion Loss of the AWG is: -1.336 dB

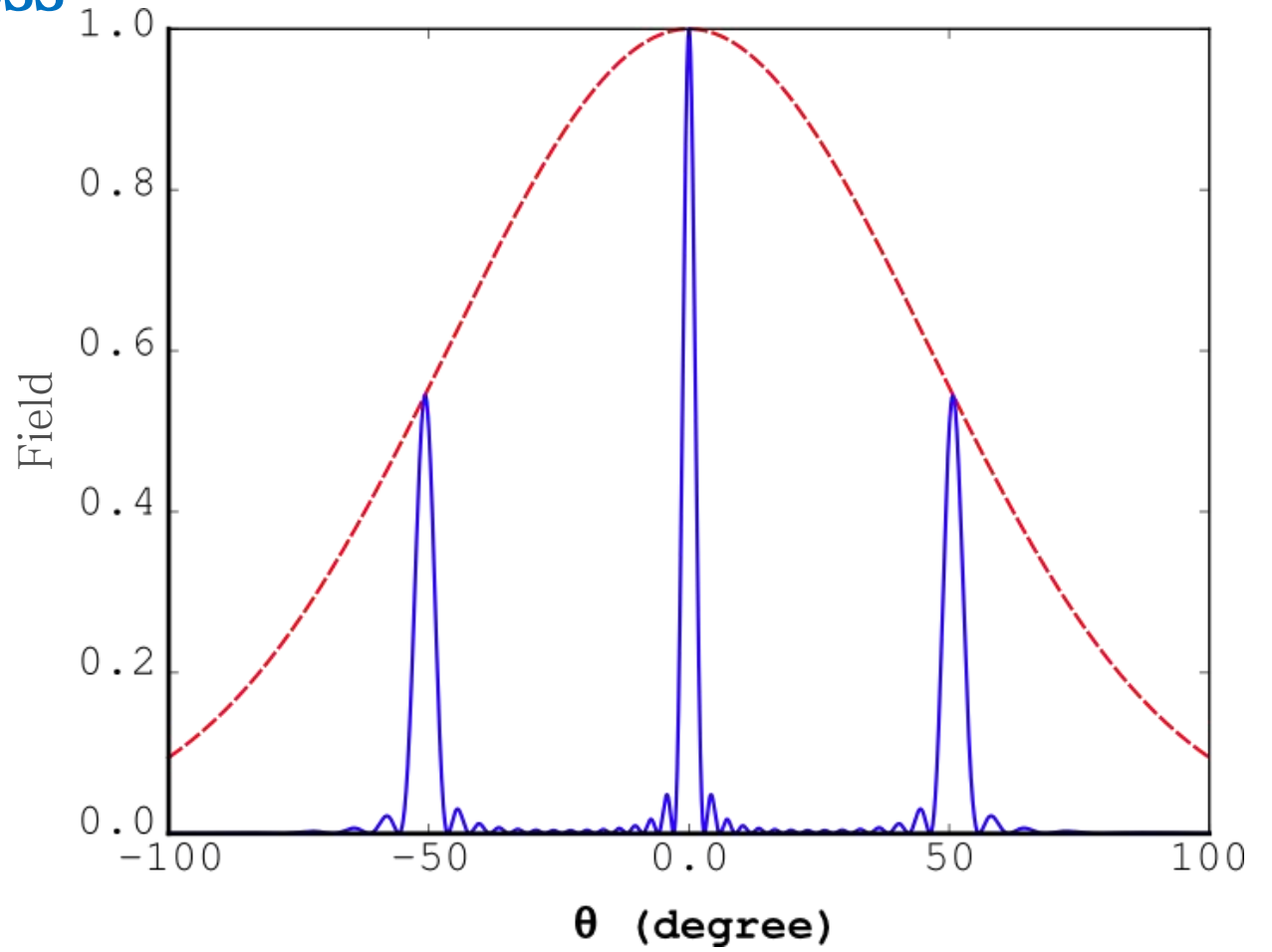
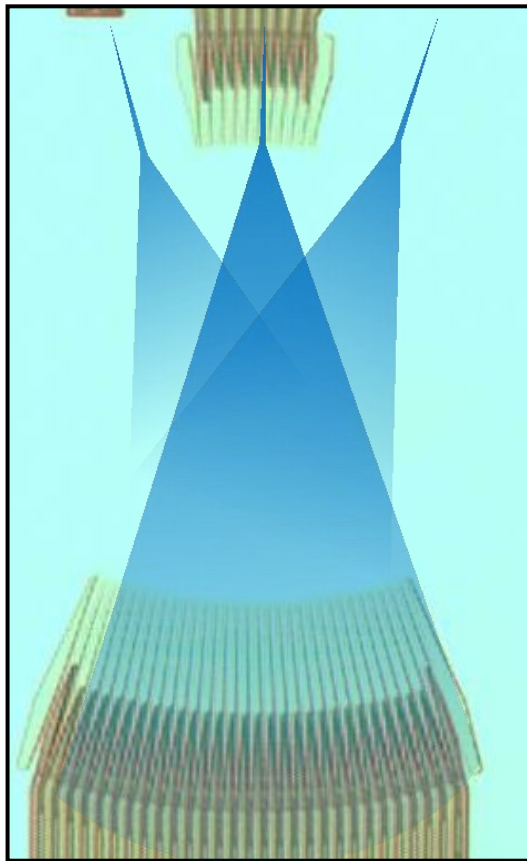
Possibility in Design



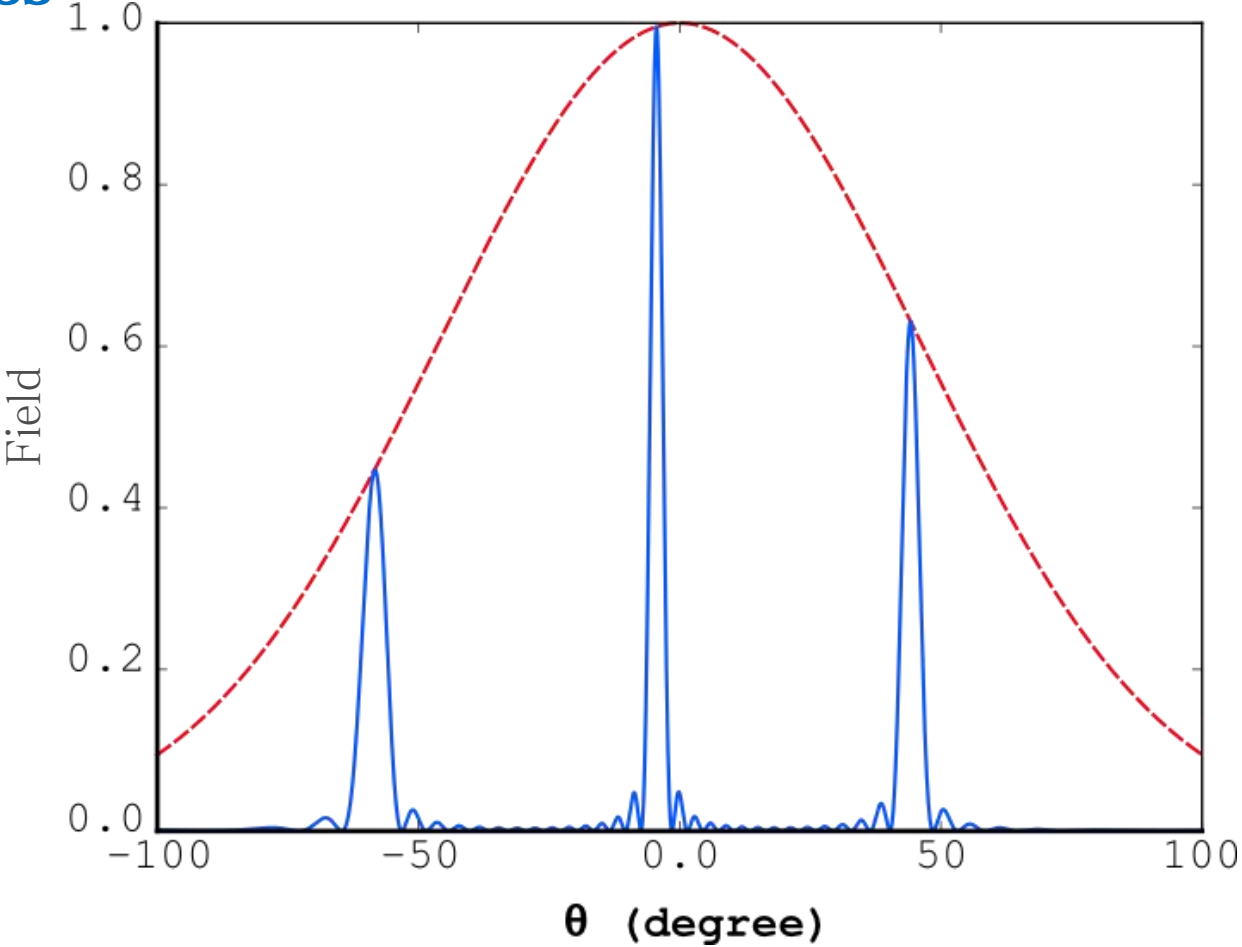
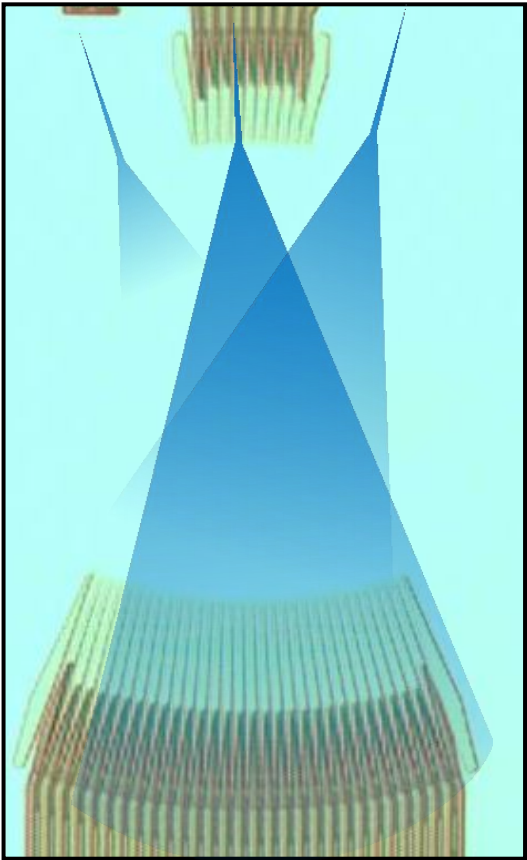
Insertion Loss of AWG: Design improvement



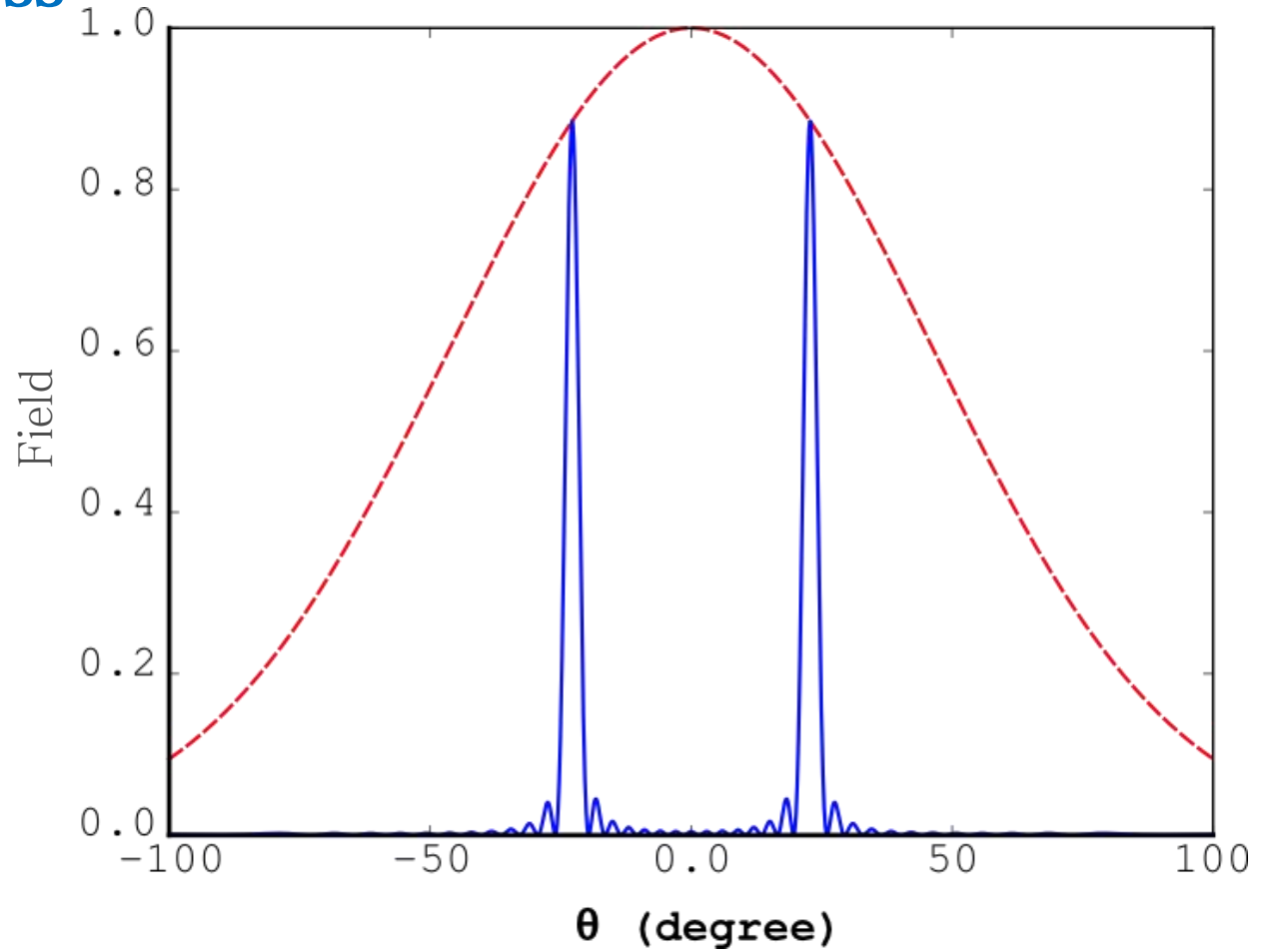
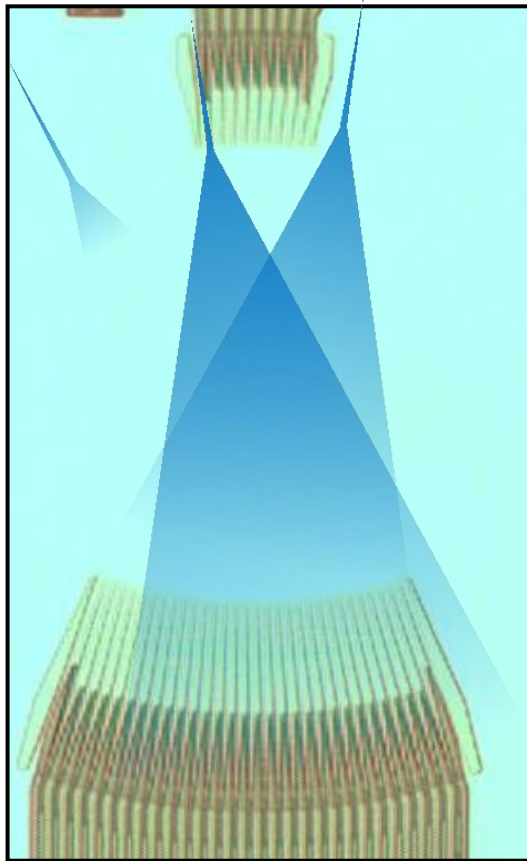
Non-uniformity loss



Non-uniformity loss

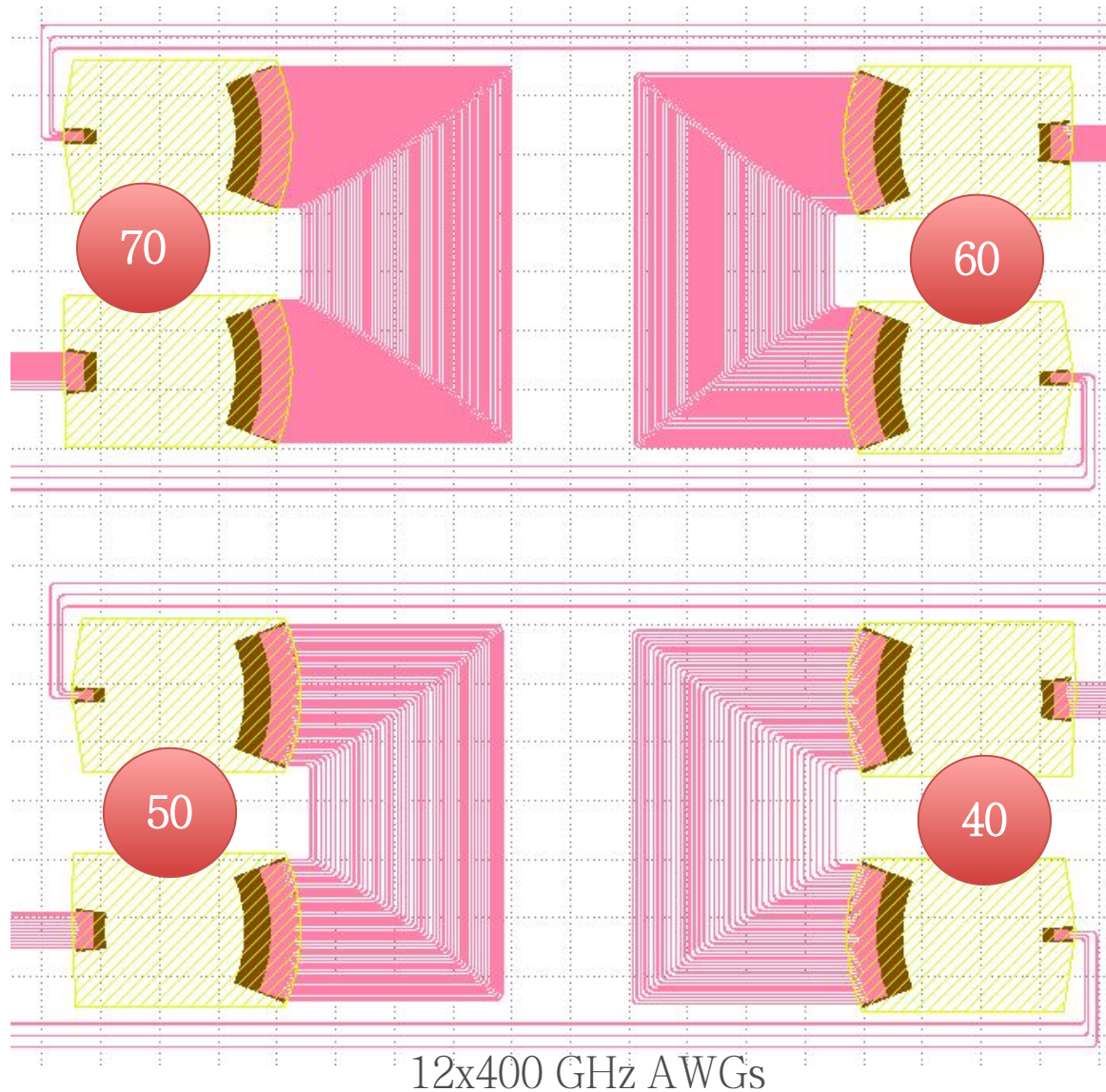


Non-uniformity loss



Side channel will have 3dB extra loss compare to the Center Channel

Insertion Loss and non-uniformity



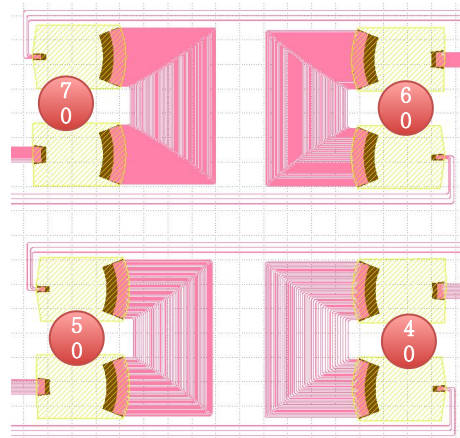
Add more waveguides

Narrow down the arm apertures

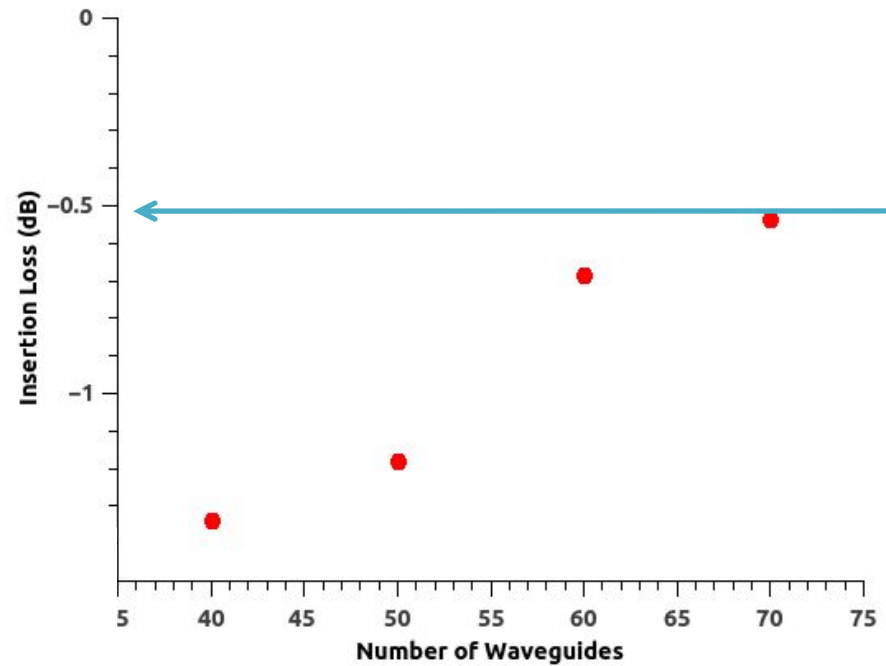
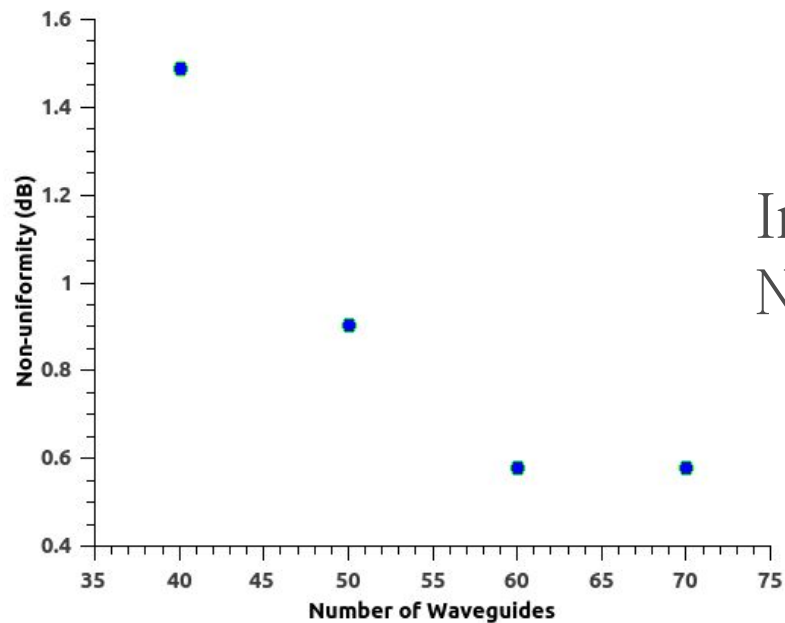
Constant focus

Non-uniformity should improve

Insertion Loss and non-uniformity



12x400 GHz AWGs



Insertion Loss improve to **-0.5 dB**

Non-uniformity improve to **0.6 dB**

Structure the outline

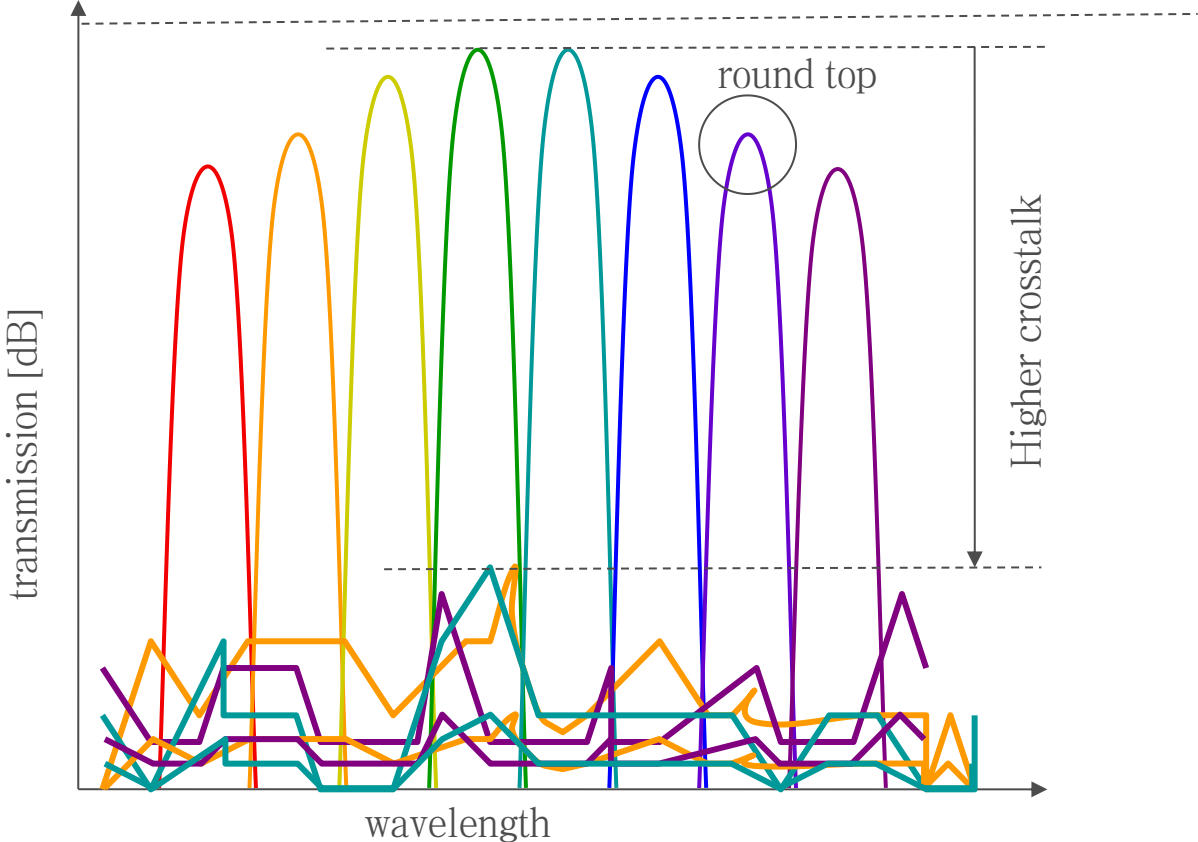
+ Our approach

– Our results

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- Round top to flattop
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+ Conclusions

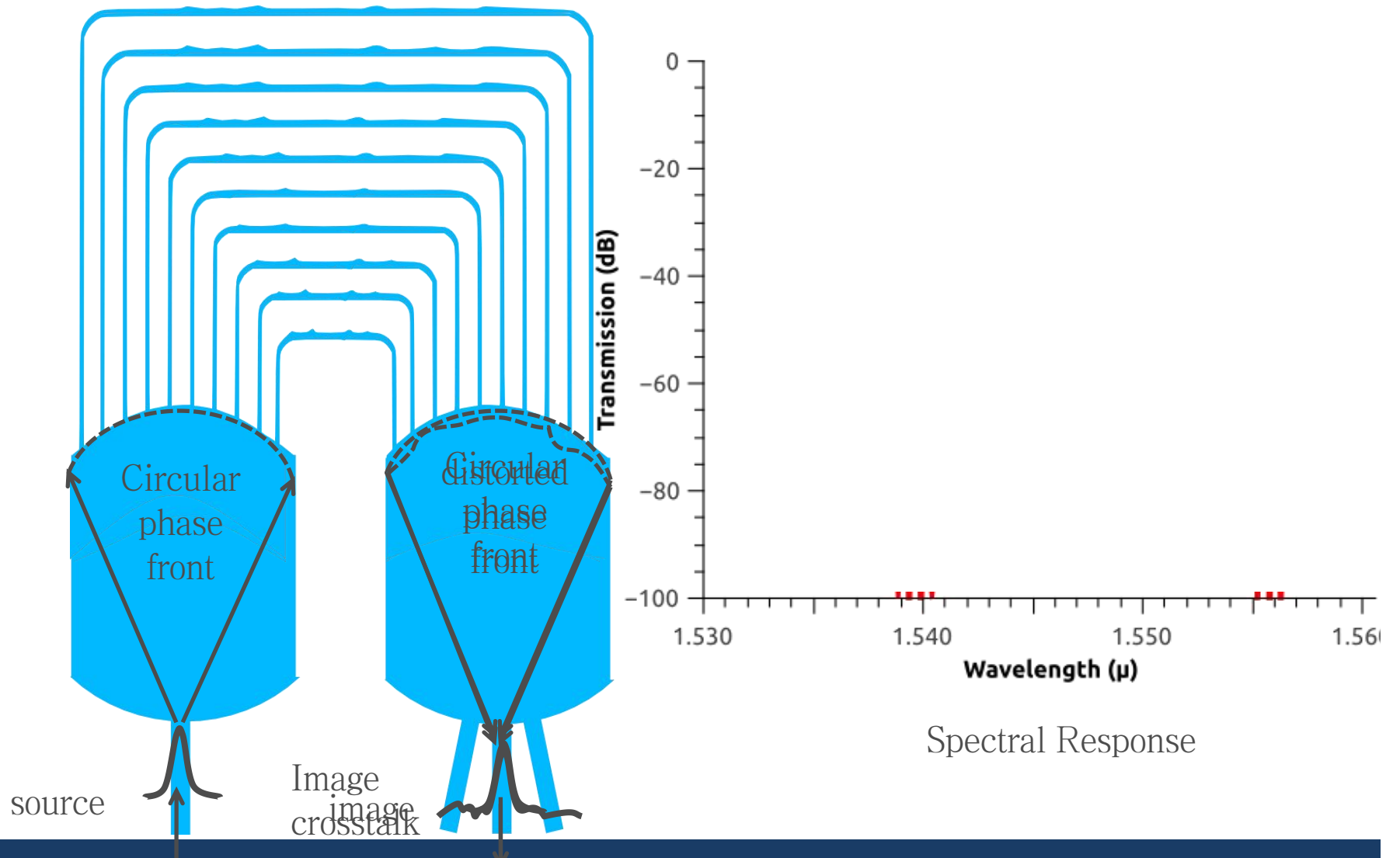
Problems in Silicon AWG



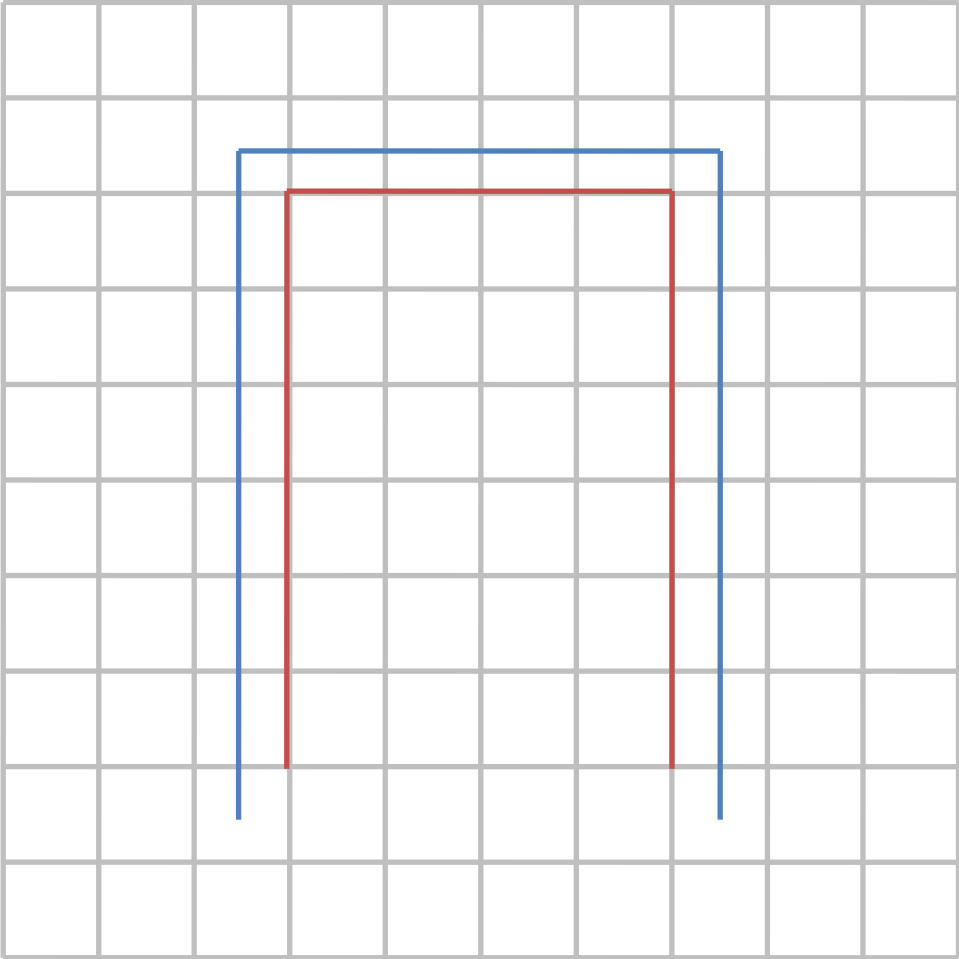
- ~~High Insertion Loss~~
- High Crosstalk
- Channel Spacing Mismatch
- Round Top

Crosstalk: Phase error

perfectly controlled delay phase contributions on the output in phase



Crosstalk of AWG: mask grid

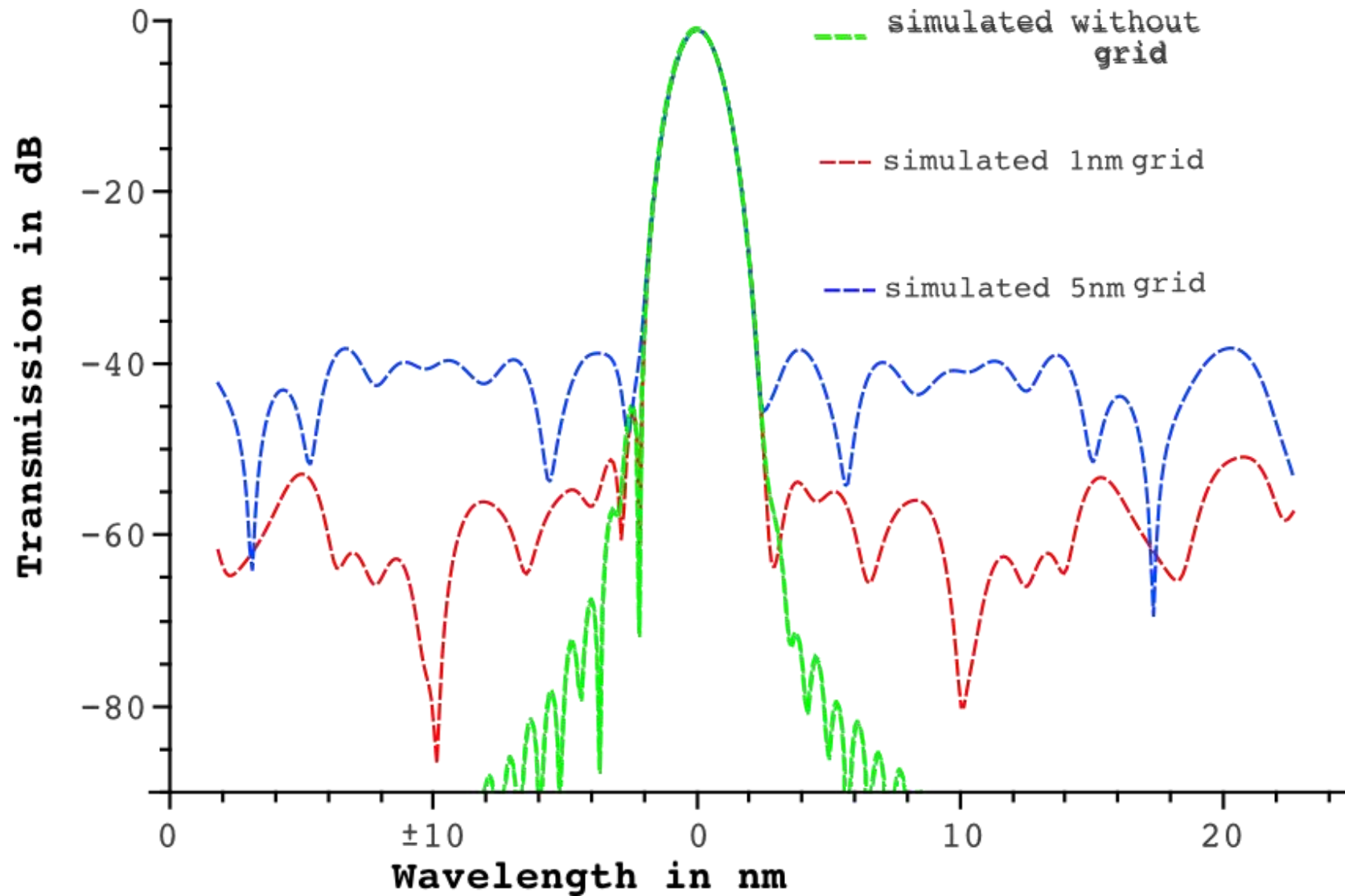


Length deviation

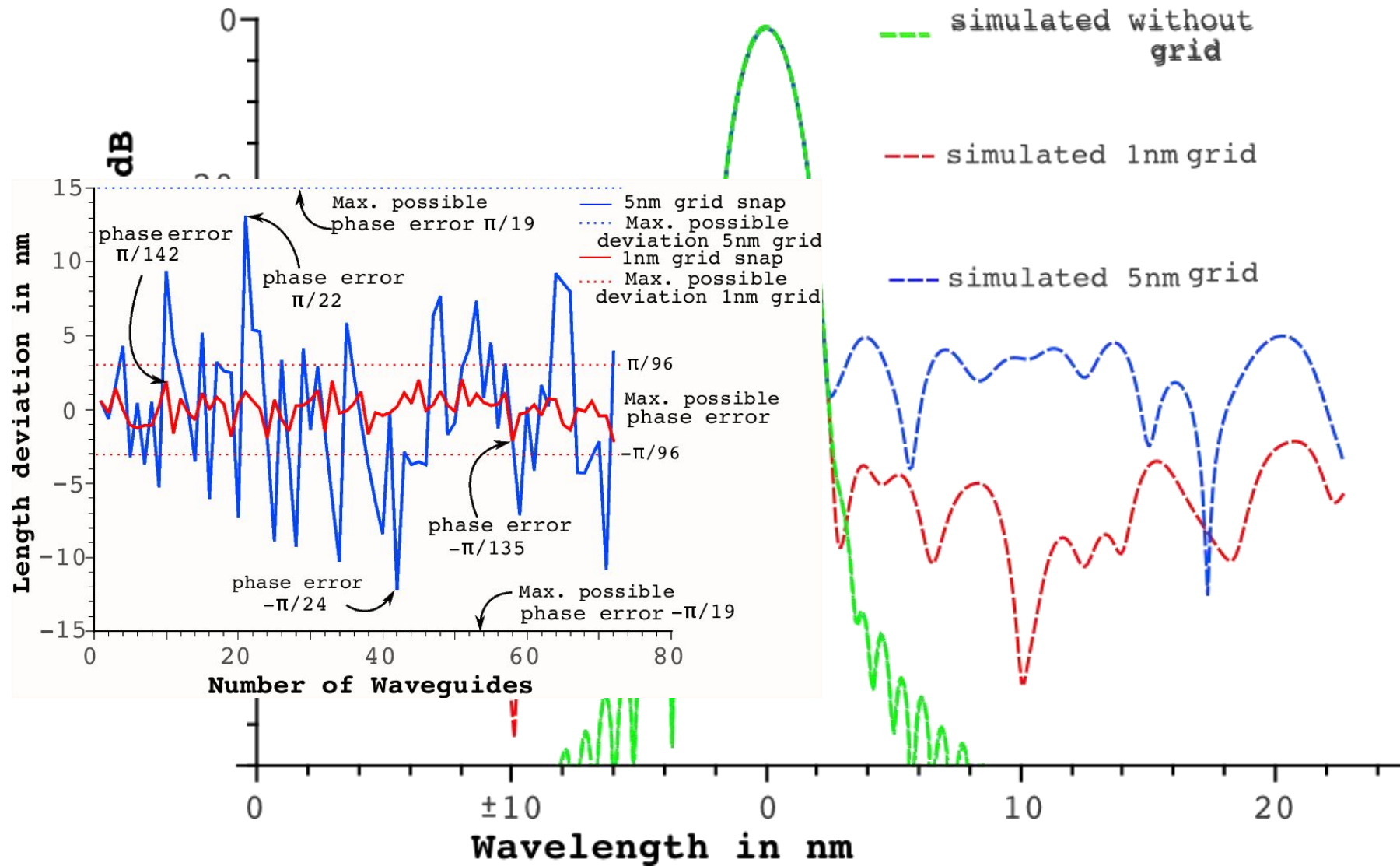
$$\frac{1}{2} a$$

a is mask grid width

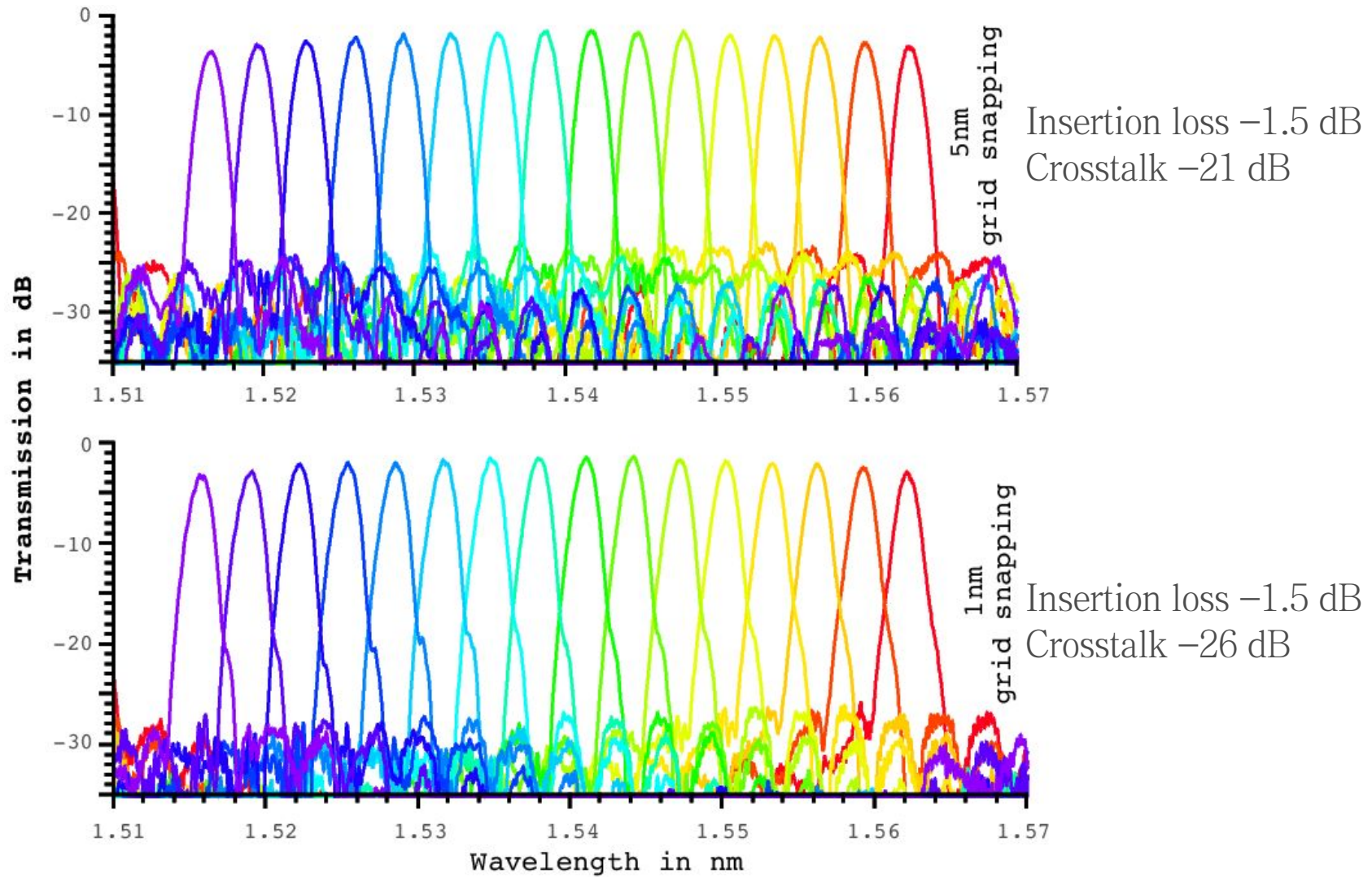
Crosstalk of AWG: Simulation 16X400 GHz AWGs



Crosstalk of AWG: Simulation 16X400 GHz AWGs



Crosstalk of AWG: Measured 16X400 GHz AWGs



Structure the outline

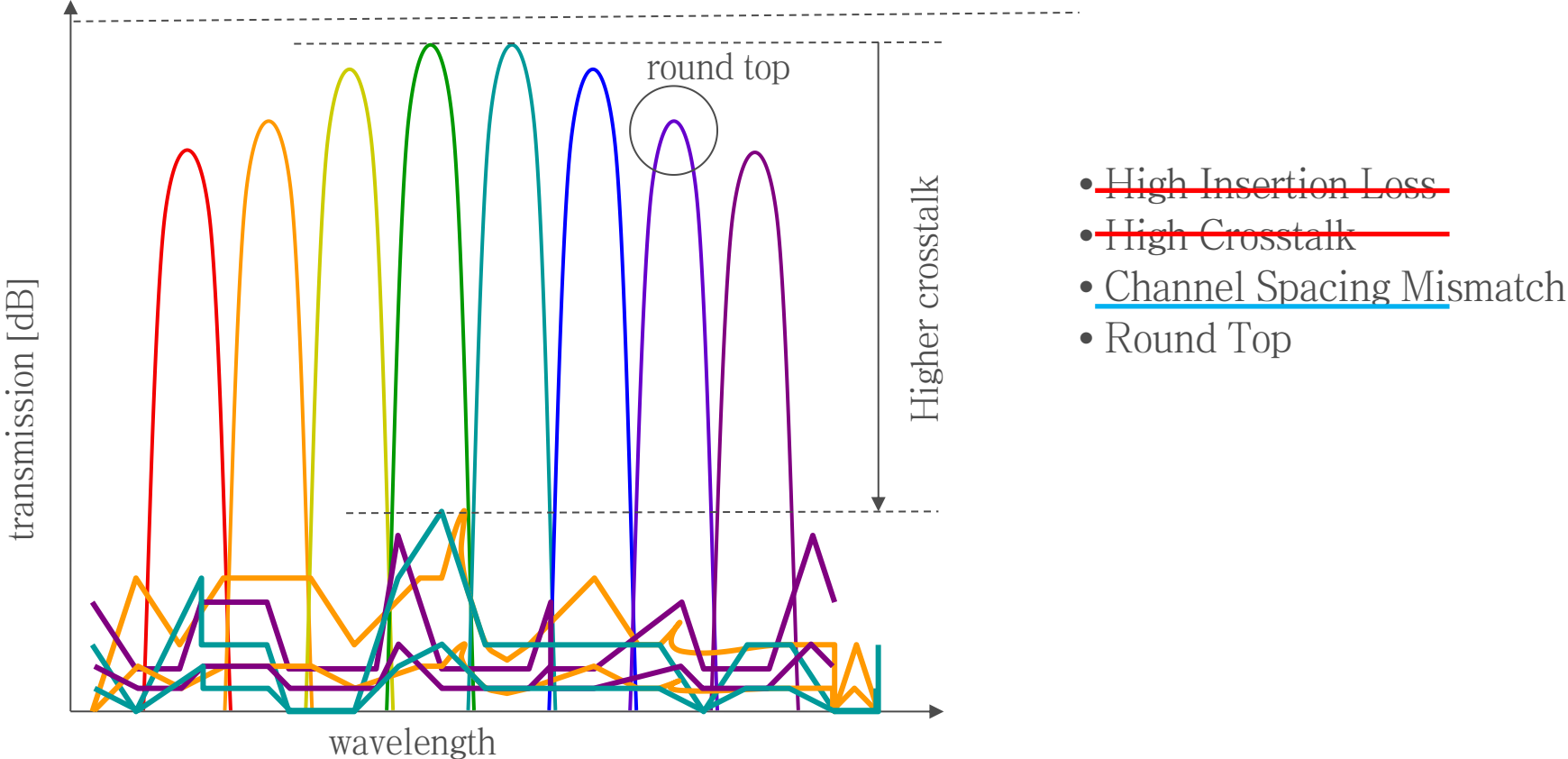
+ Our approach

– Our results

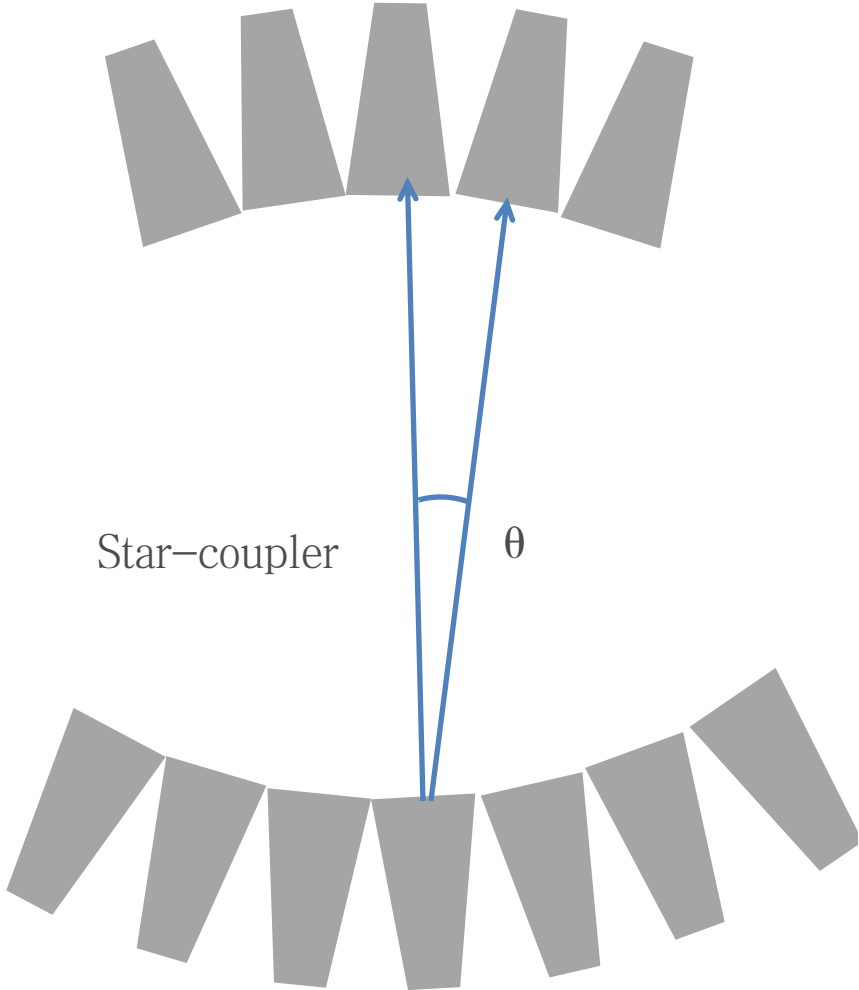
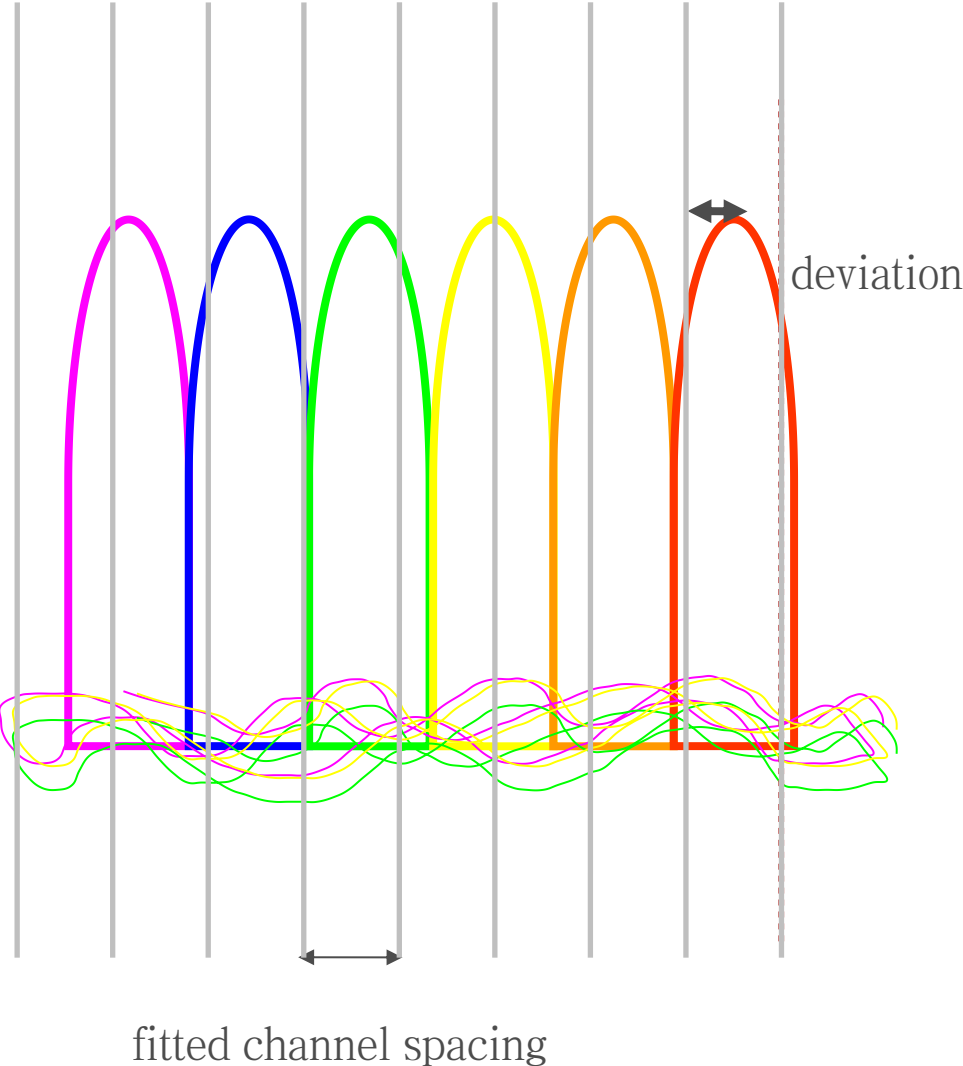
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+ Conclusions

Problems in Silicon AWG



Channel spacing mismatch



Formula for output position

Formula 1

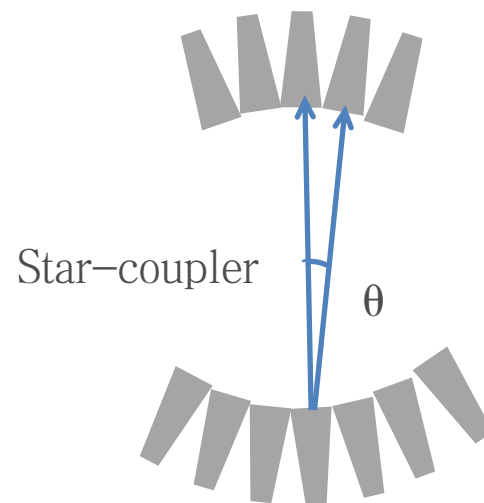
$$\sin\theta = m \cdot \frac{n_{wg}(\lambda) \cdot \lambda_c - n_{wg}(\lambda_c) \cdot \lambda}{n_{wg}(\lambda_c) \cdot n_{slab}(\lambda) \cdot d_a}$$

Theoretically more accurate formula
but need accurate n_{wg} for all
wavelengths

Formula 2

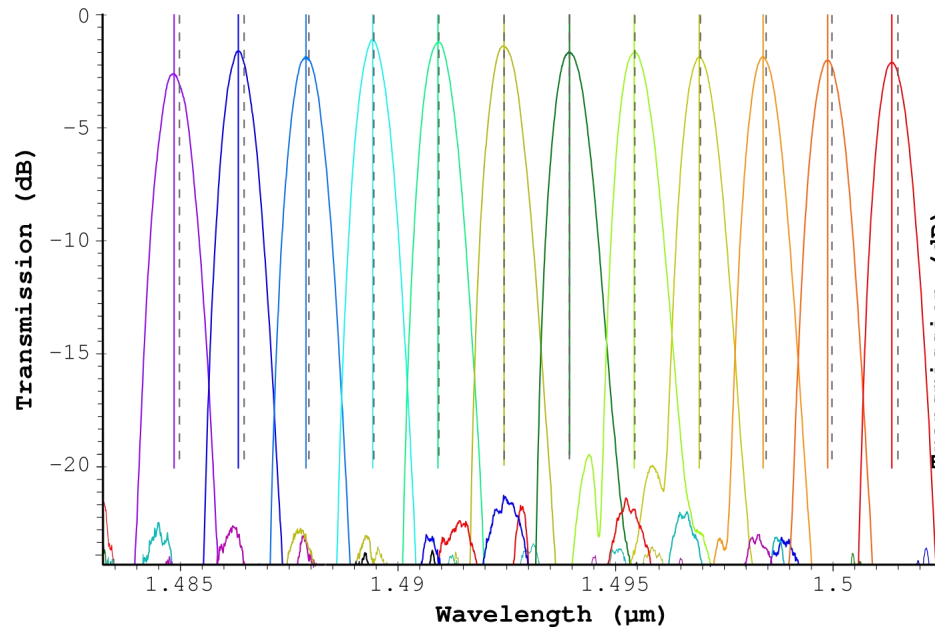
$$\frac{d\theta}{d\nu} = - \frac{m\lambda_c^2 n_{g,wg}}{n_{slab} n_{wg}(\lambda_c) d_a c}$$

Theoretically less accurate formula
but need accurate n_{wg} for center
wavelength and accurate n_{group}

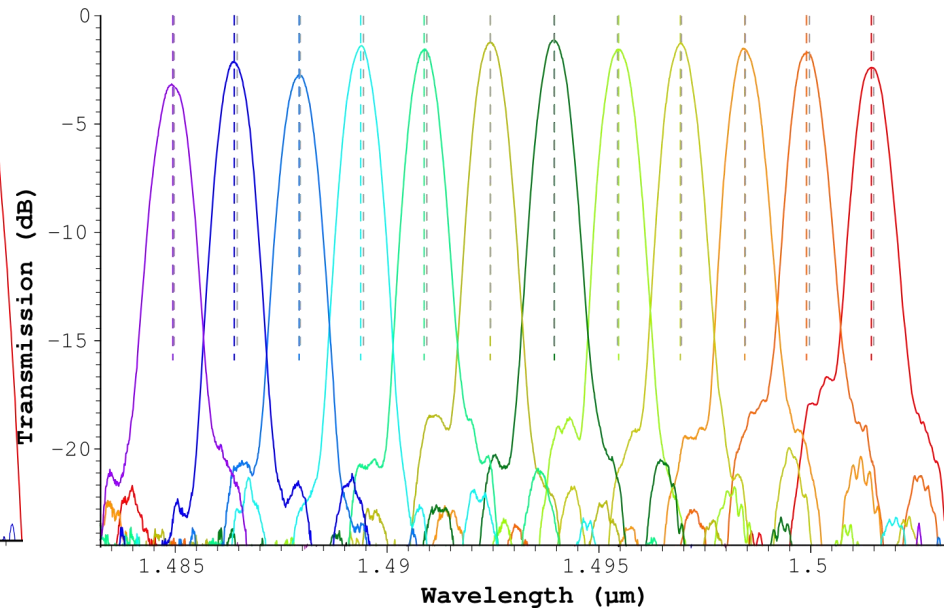


Improvement in channel spacing: 12x200 GHz AWG

Formula 1



Formula 2



Best fitted channel spacing 201.9 GHz

Maximum deviation 19.0 GHz

Maximum deviation 12.9 GHz

Structure the outline

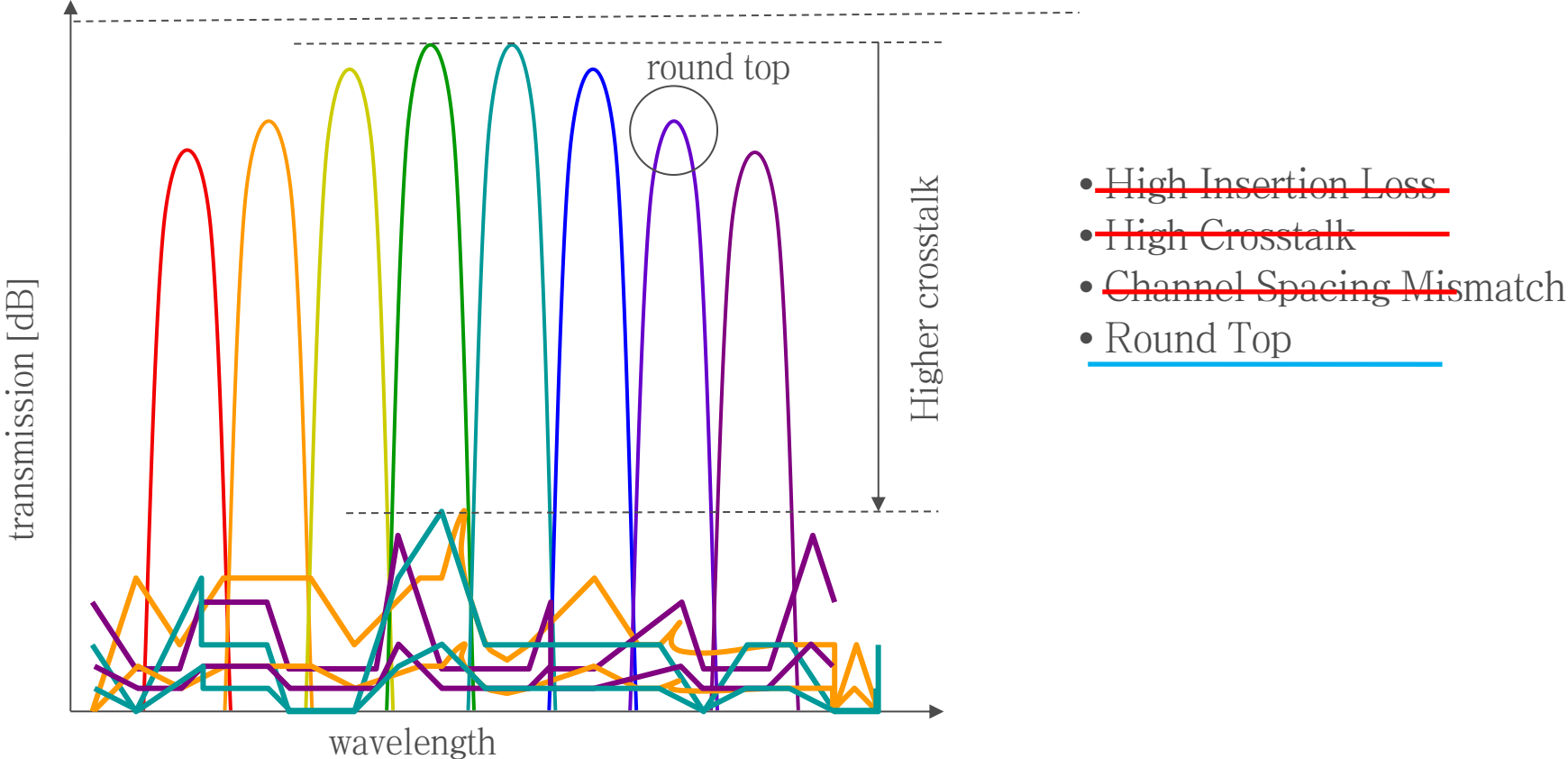
+ Our approach

– Our results

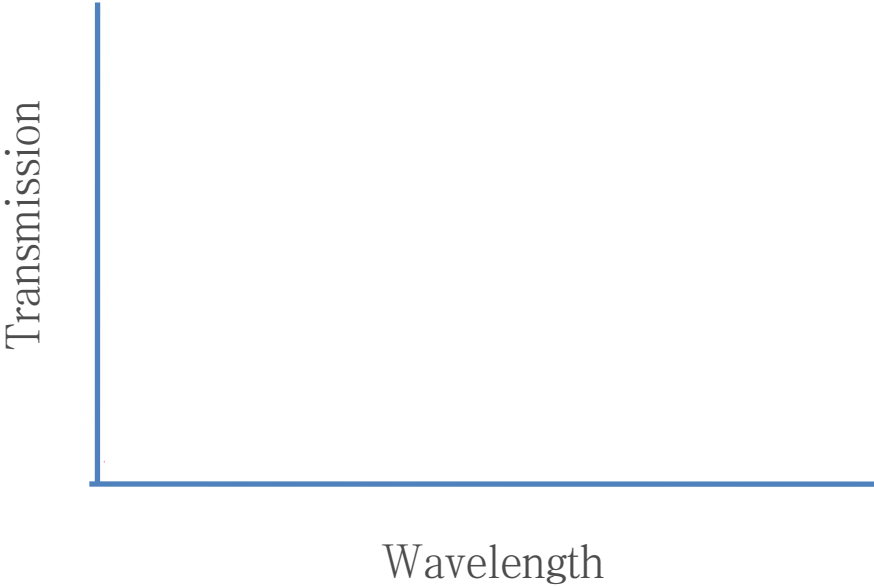
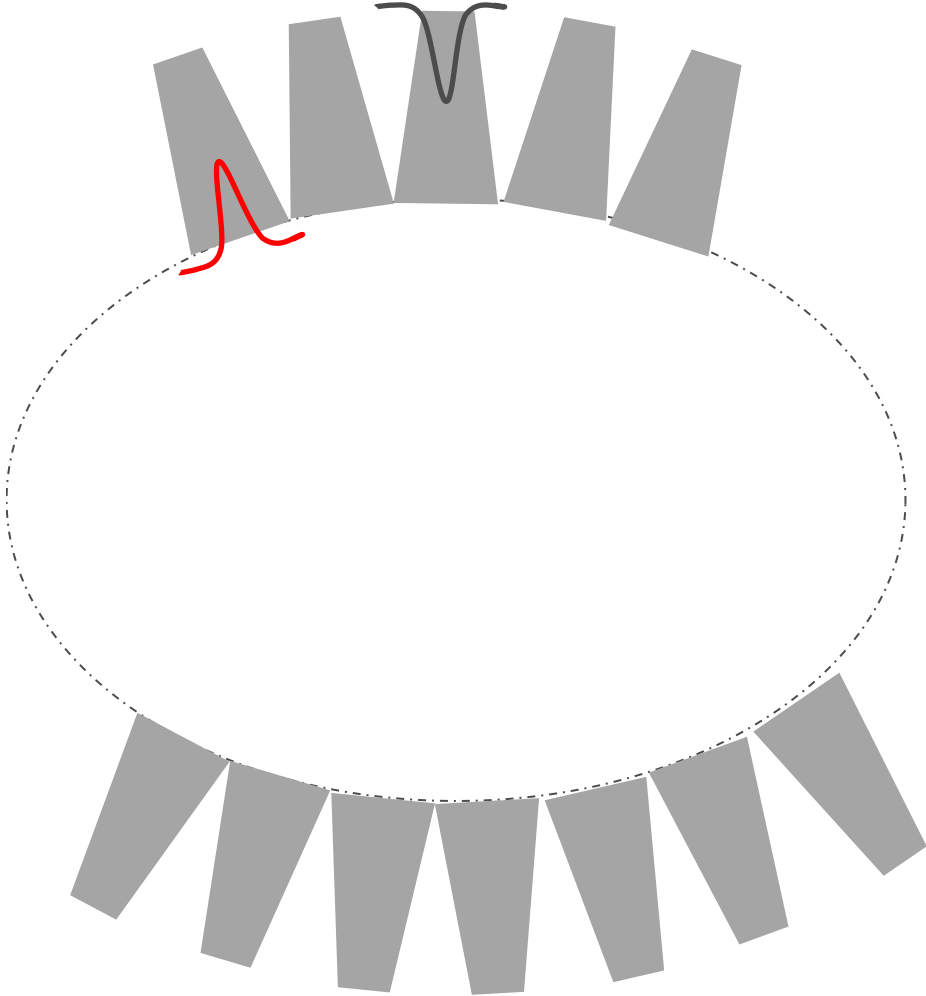
- Insertion Loss and Non–uniformity
- Crosstalk
- Channel mismatch
- Round top to flattop
- Switch

+ Conclusions

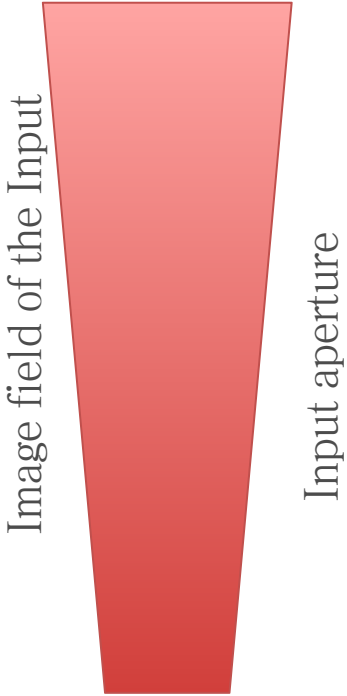
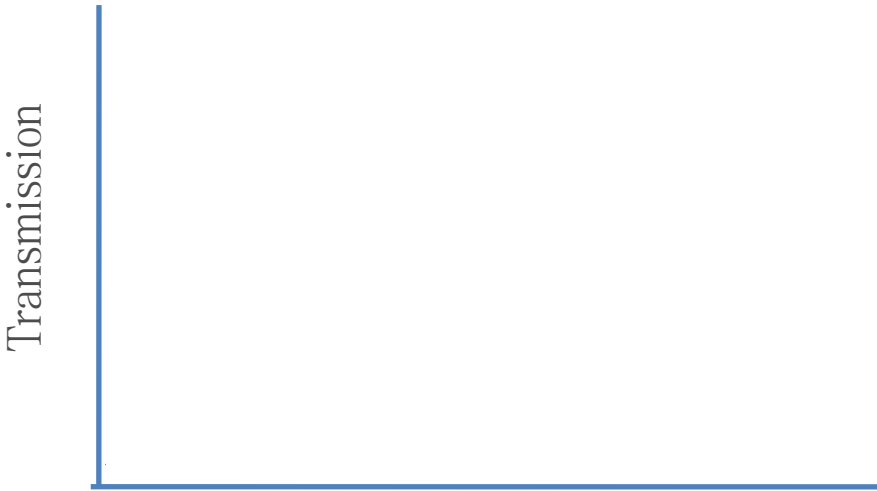
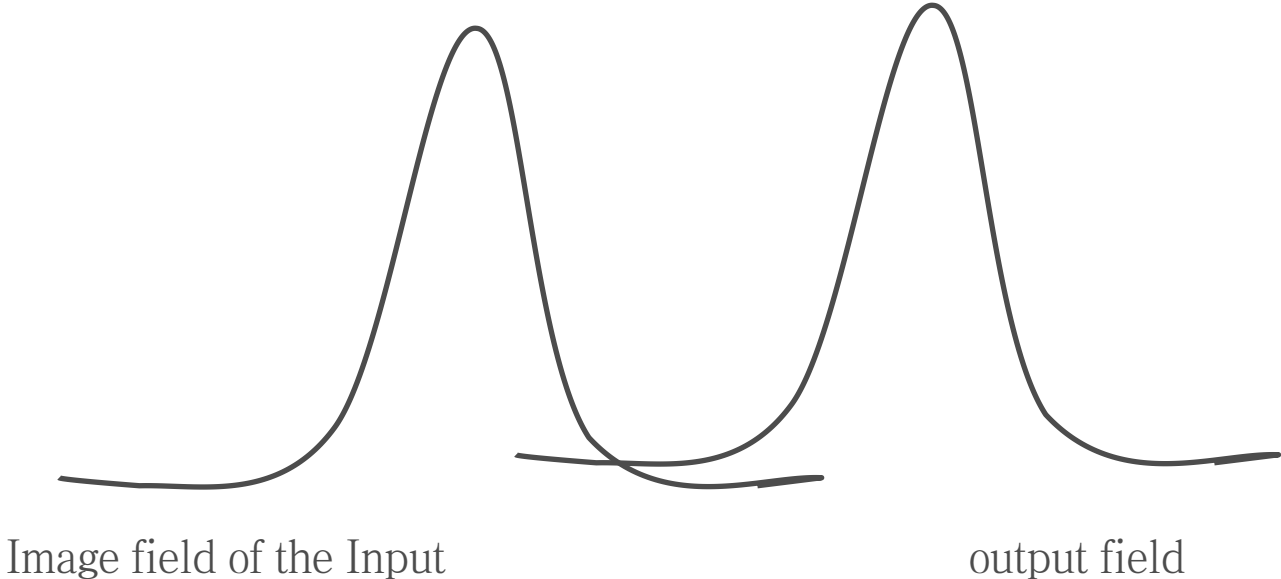
Problems in Silicon AWG



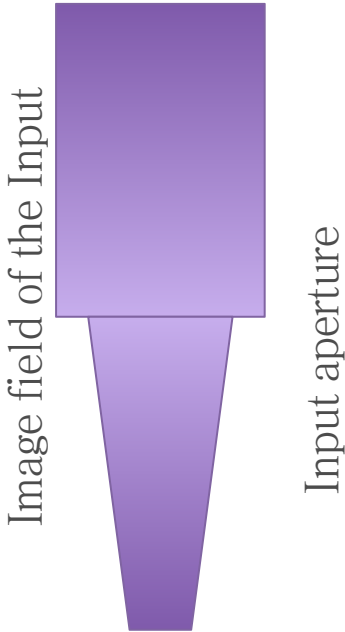
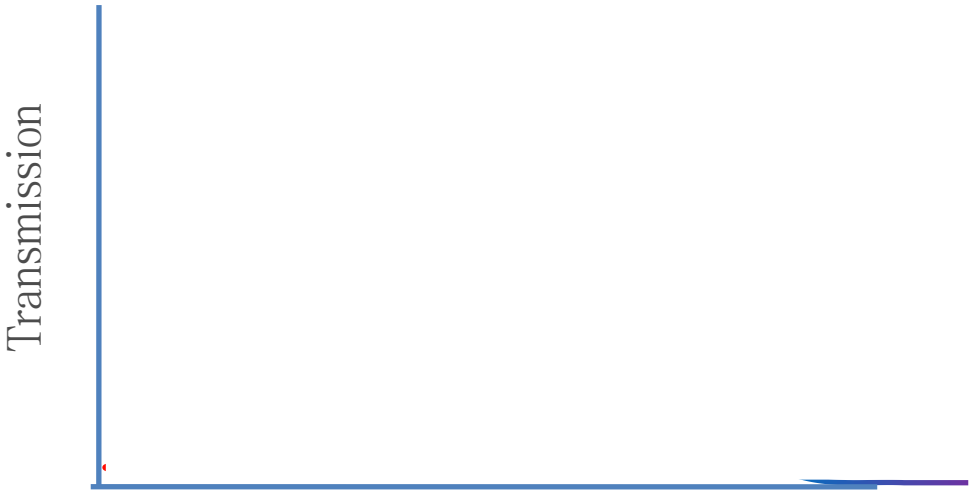
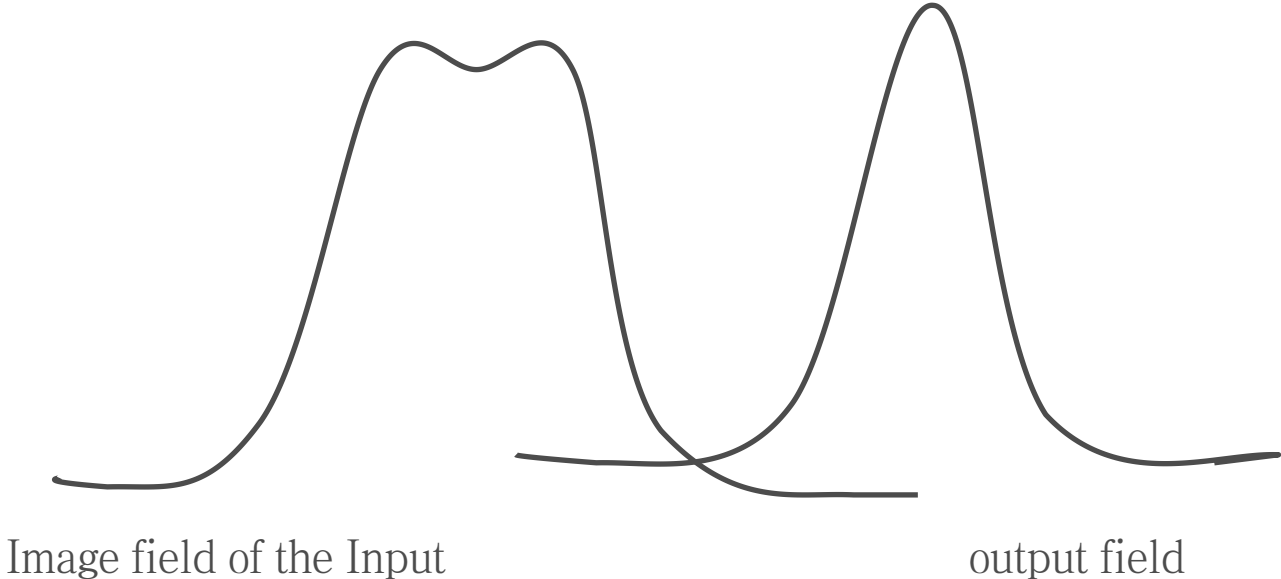
Second Star-coupler: Round Top



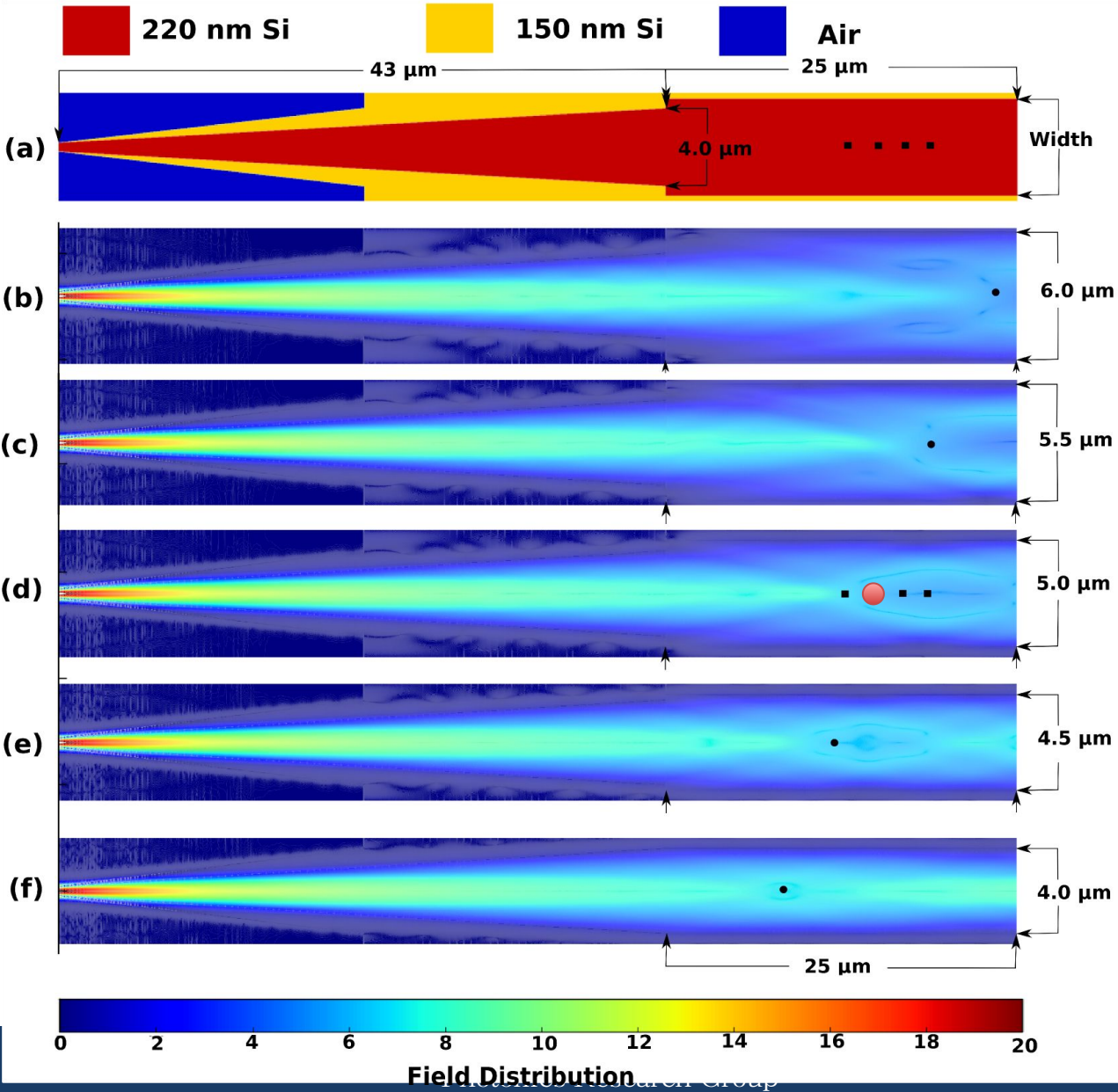
Second Star-coupler: Convolution



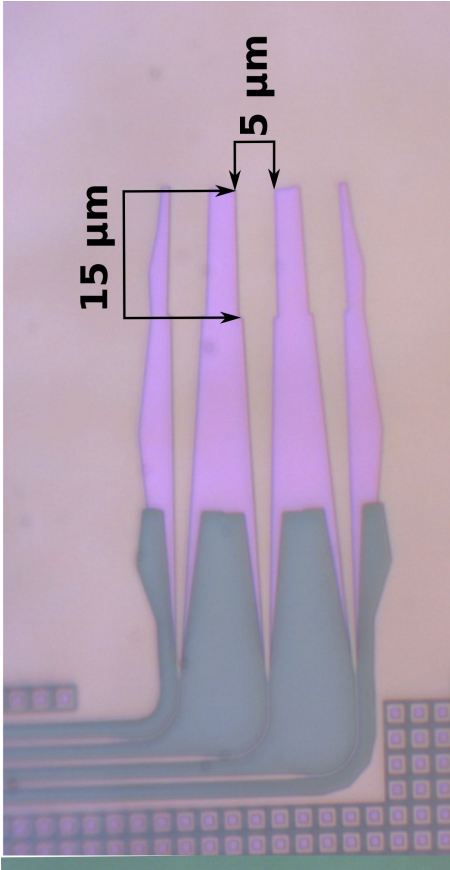
Second Star-coupler: Convolution



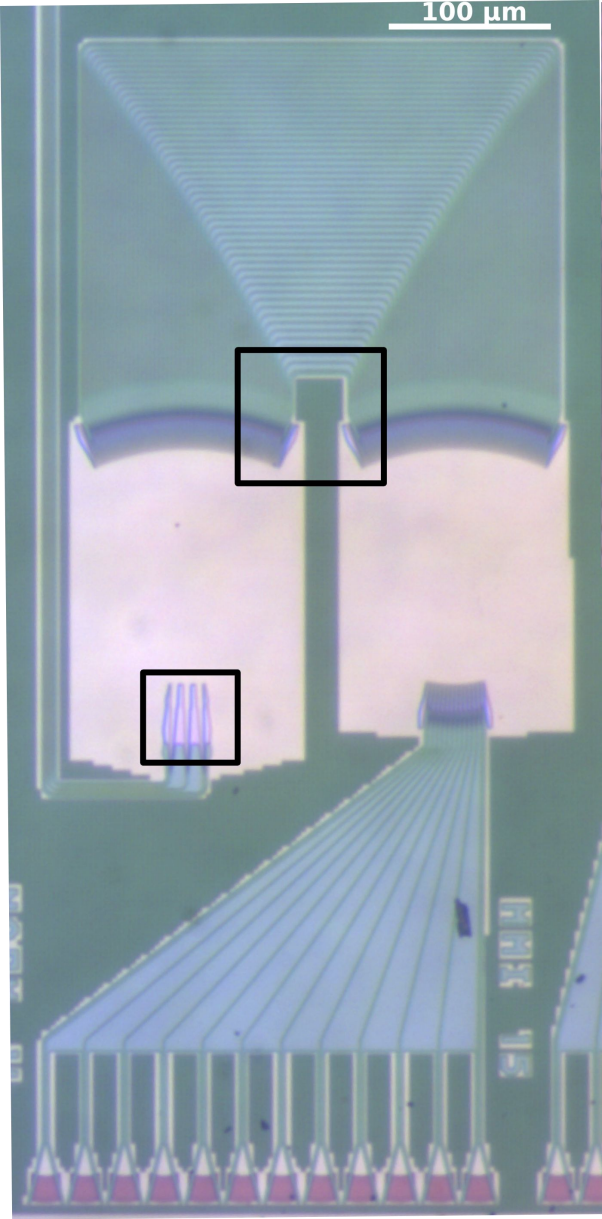
MMI aperture: Simulation



Fabricated MMI-AWG

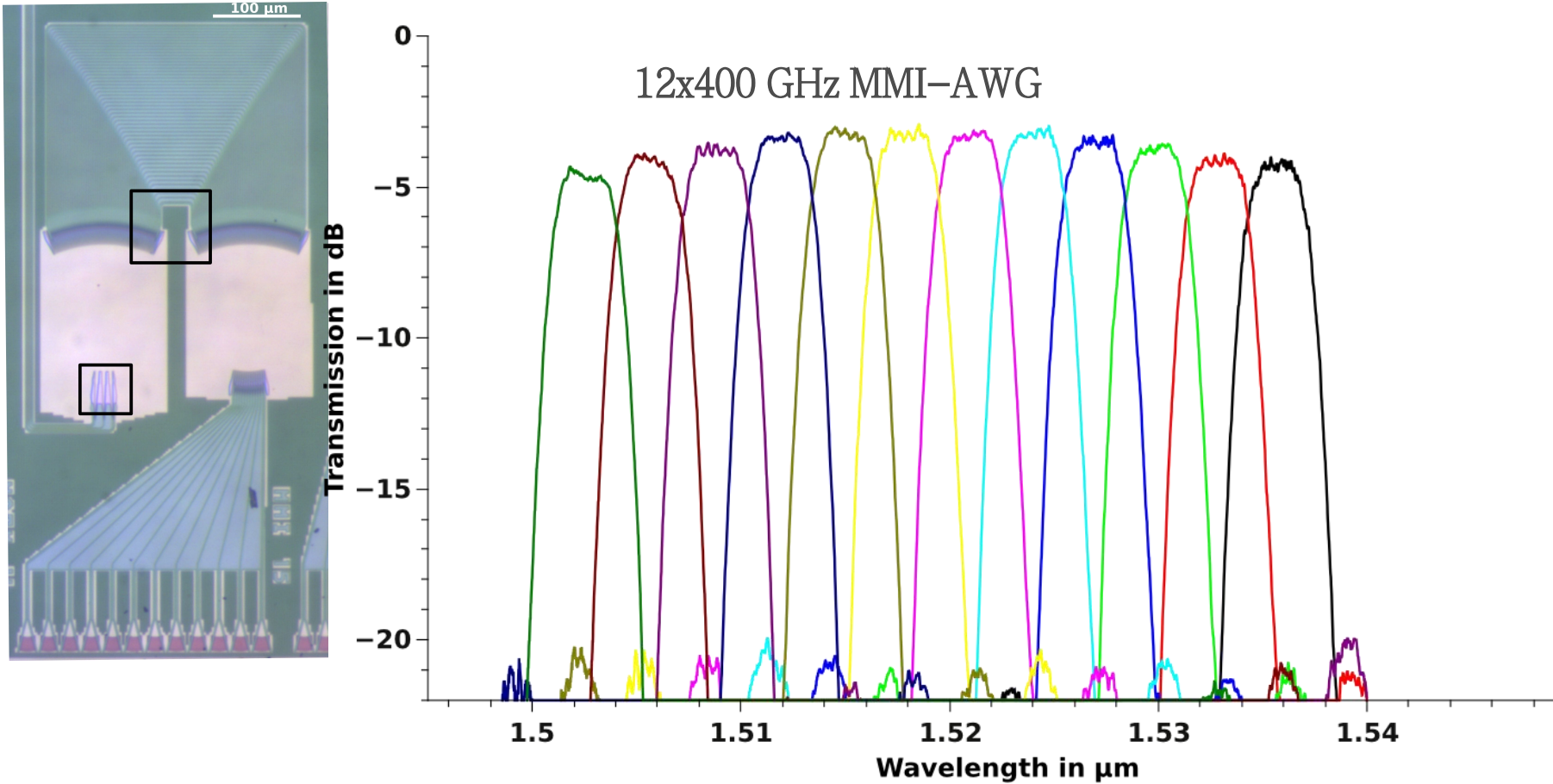


MMI aperture



12x400 GHz MMI-AWG

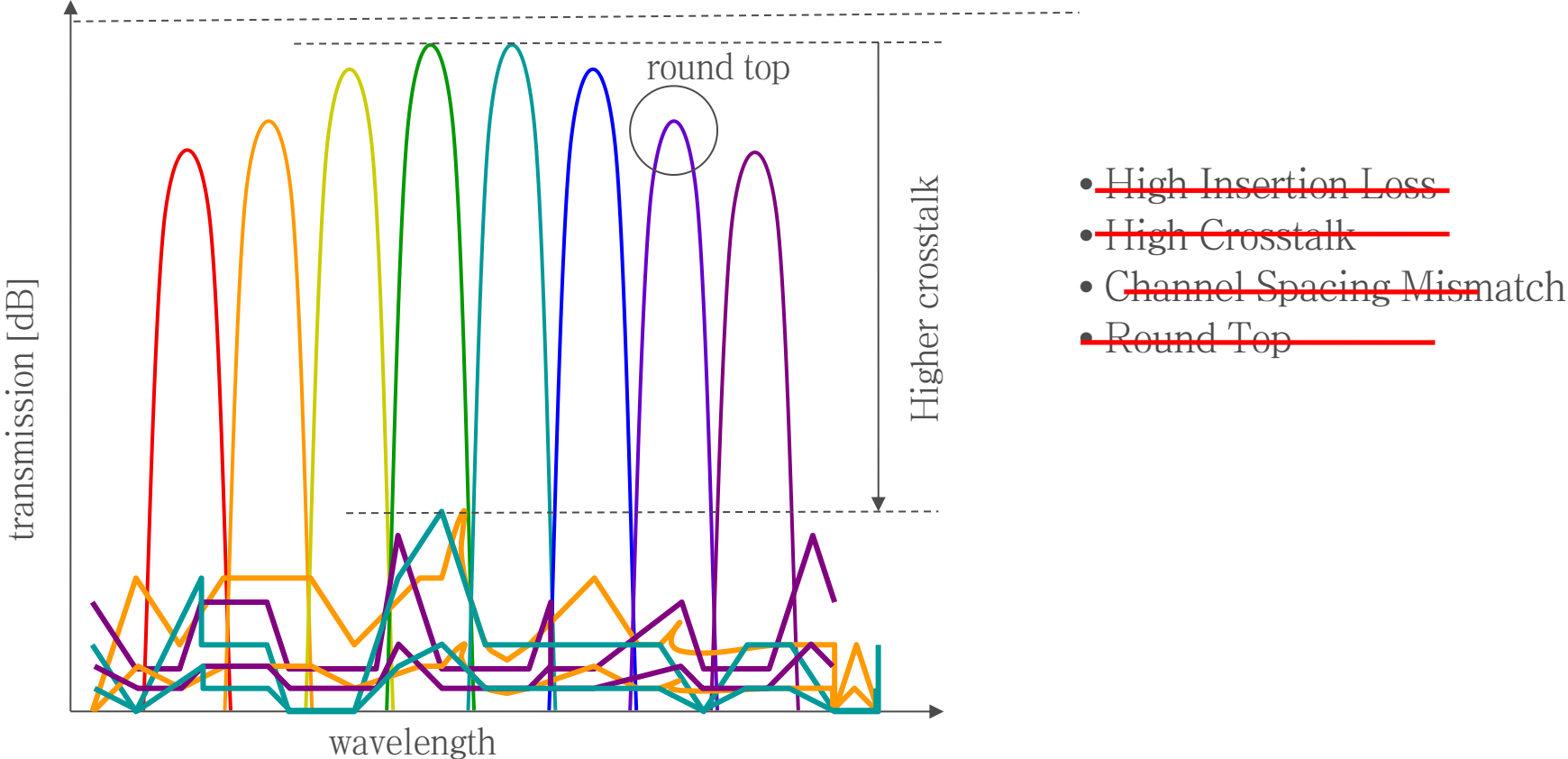
Measurement Results of MMI-AWG



Insertion loss -2.07 dB
Crosstalk -19.5 dB

Aspect ratio (1dB bandwidth/ 10 dB bandwidth)
 0.5

Problems in Silicon AWG



Structure the outline

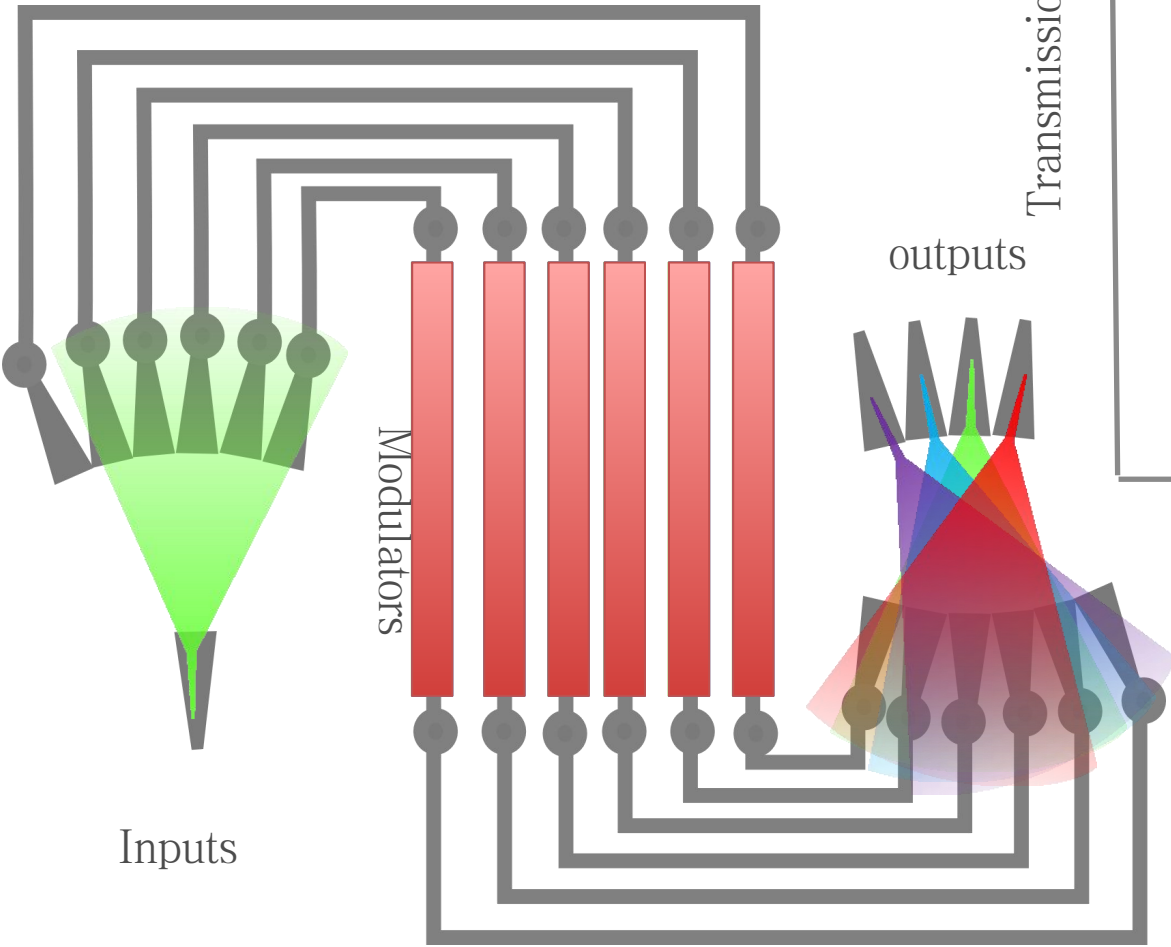
+ Our approach

– Our results

- Insertion Loss and Non–uniformity
- Crosstalk
- Channel mismatch
- Round top to flattop
- Switch

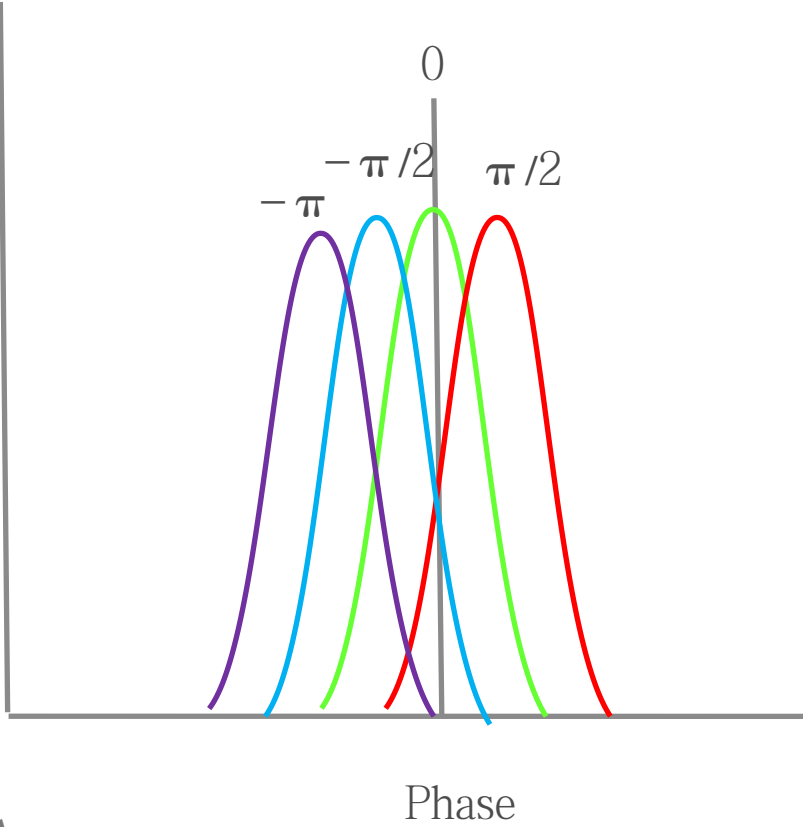
+ Conclusions

Switch

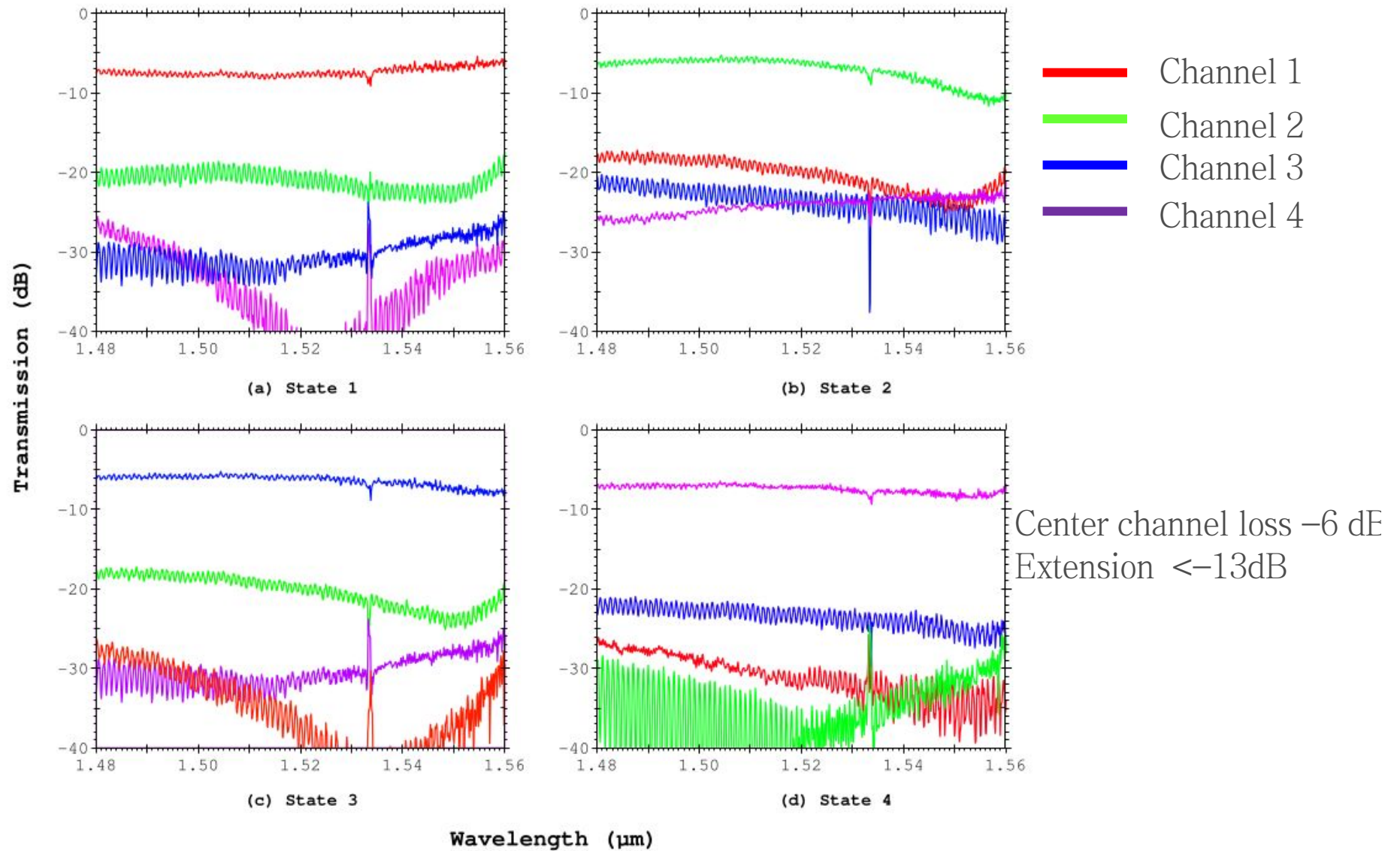


Transmission

outputs



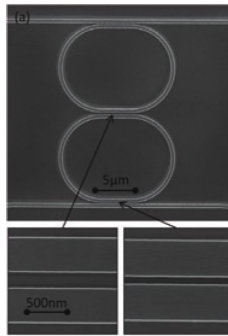
Measurement of the switching state



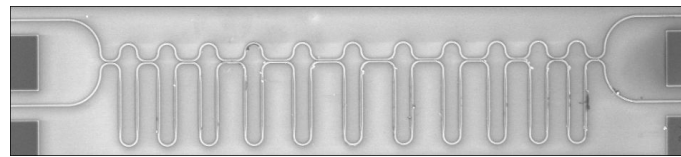
Structure the outline

- + Our approach
- + Our results
- Conclusions
 - comparison with other filters
 - comparison with the world
 - summary

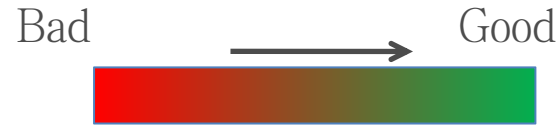
Comparison between the Filters



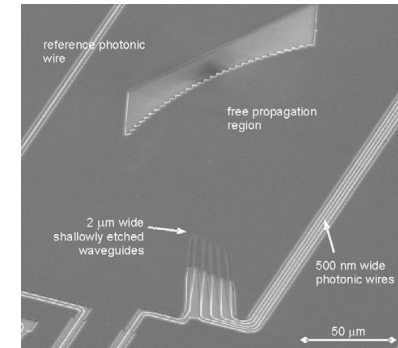
Ring filter



Lattice filter



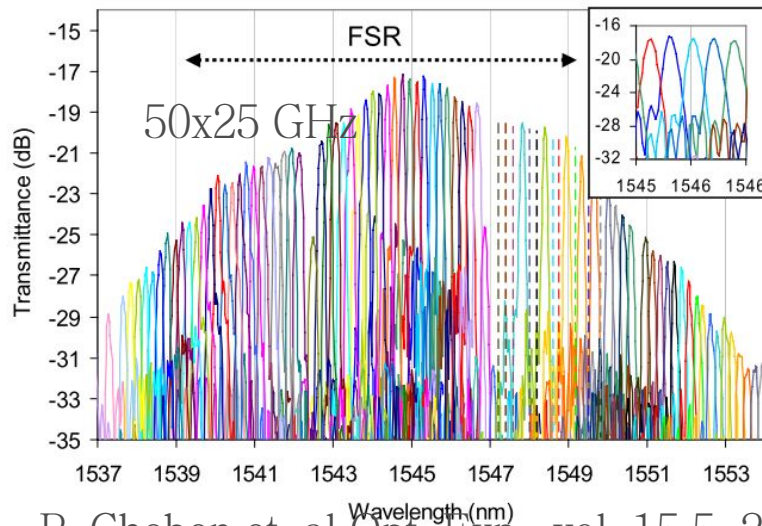
AWG



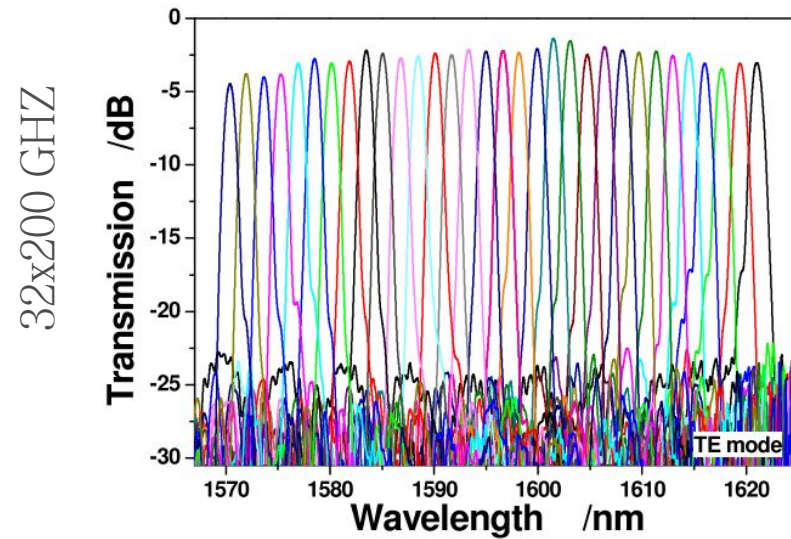
Echelle gratings

	Ring filter	Lattice filter	AWG	PCG
Fabrication Dependency				
loss				
crosstalk				
Thermal tuning				
Router				
Higher no output				

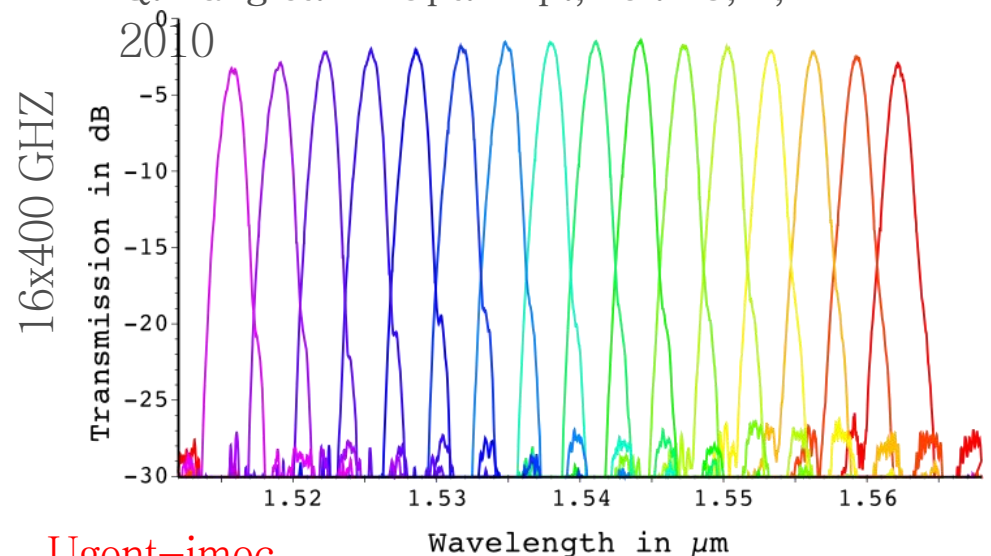
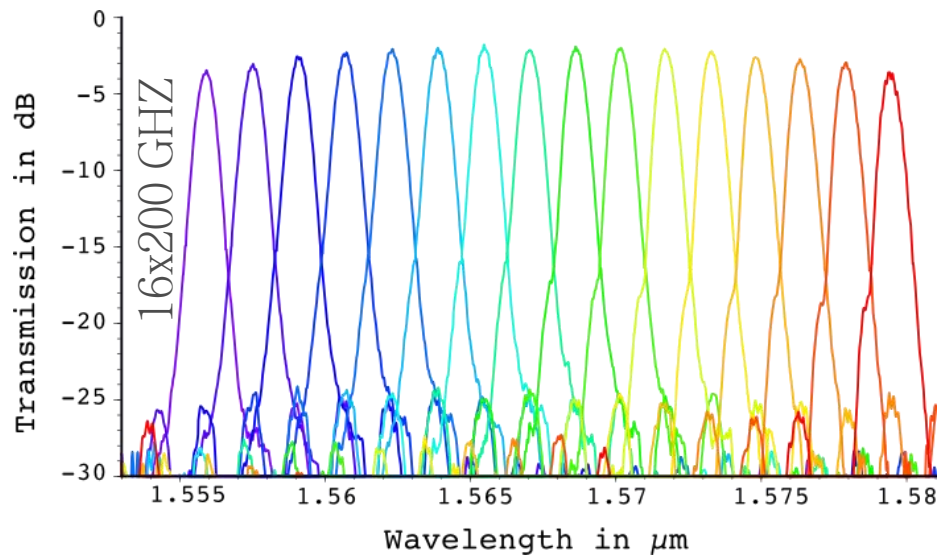
Comparison with the world



P. Cheben et. al *Opt. Exp.*, vol. 15,5, 2007



Q. Fang et. Al *Opt. Exp.*, vol. 18, 1,



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Summary

We studied AWGs on silicon

- We developed a full method for design–simulation–fabrication– characterization

We approached several problems of AWGs, with significant improvements

- loss and uniformity
- grid snapping
- flat top
- channel spacing

We made an active AWG switch in silicon

<http://photonics.intec.ugent.be>

Thank You